

Powder diffraction-based techniques



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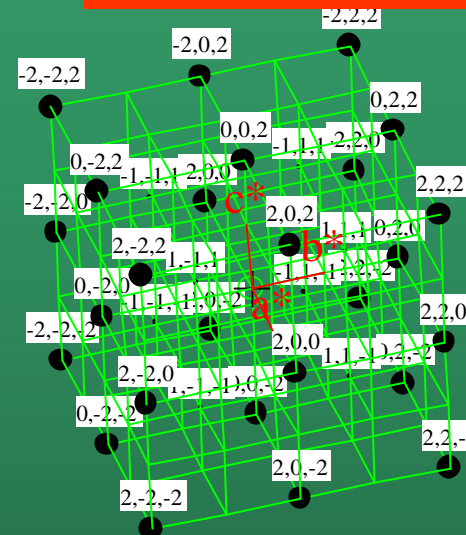
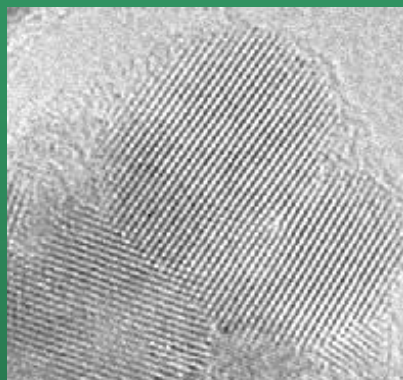
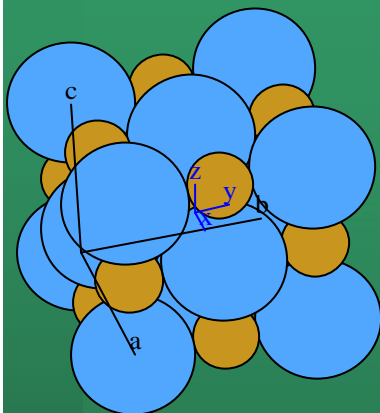
Powder diffraction and the real world

Real space (3D)

Reciprocal space (3D)

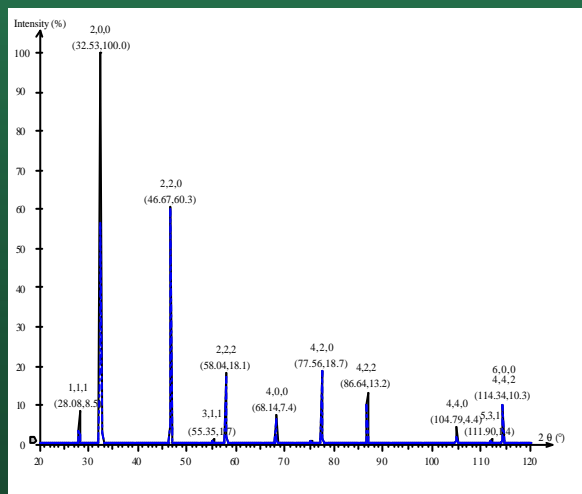
structure

microstructure



Diffraction pattern (1D)

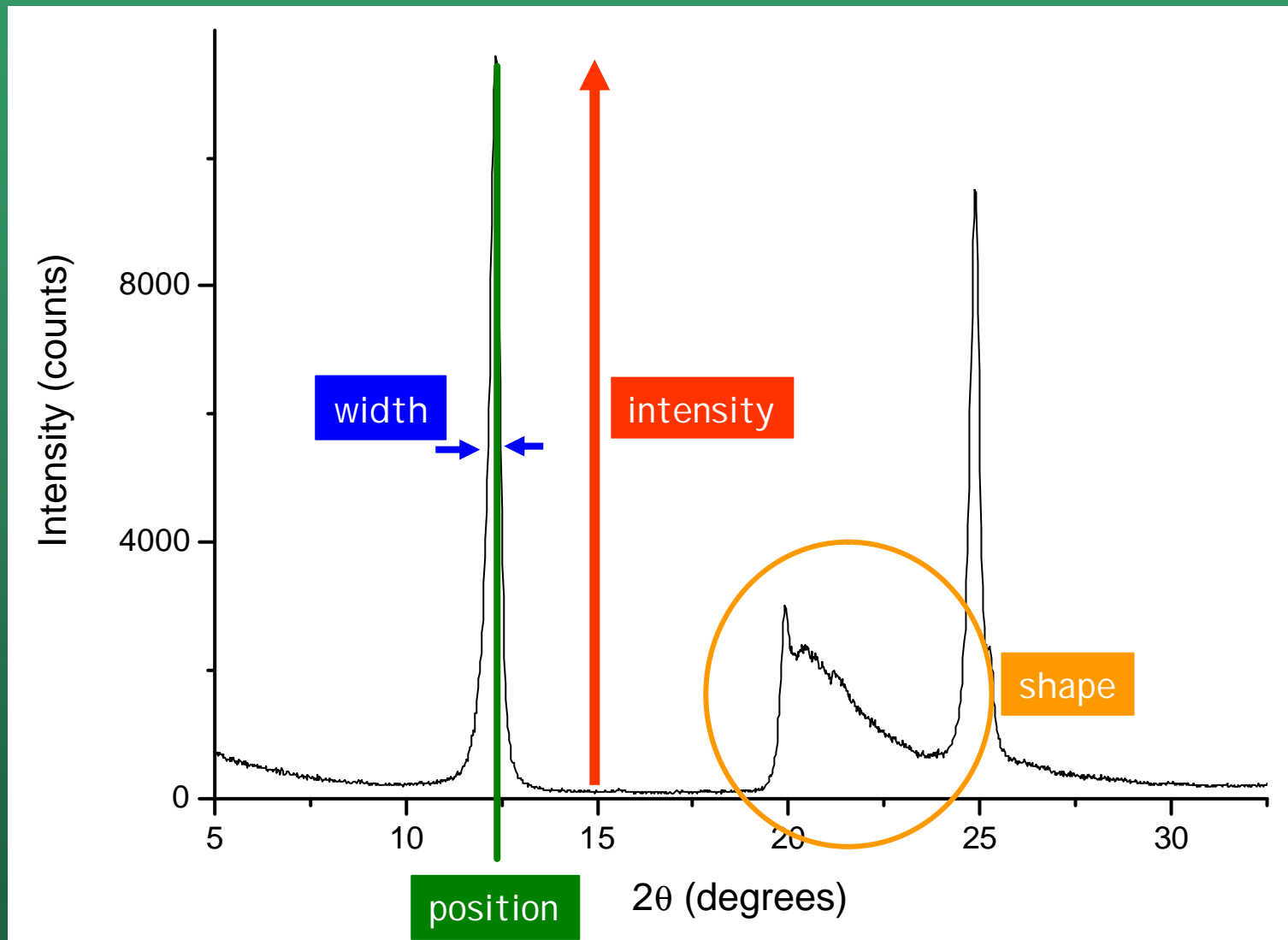
OUR PROBLEM!



Integration on spheres



Powder diffraction pattern



Information extracted from the pattern

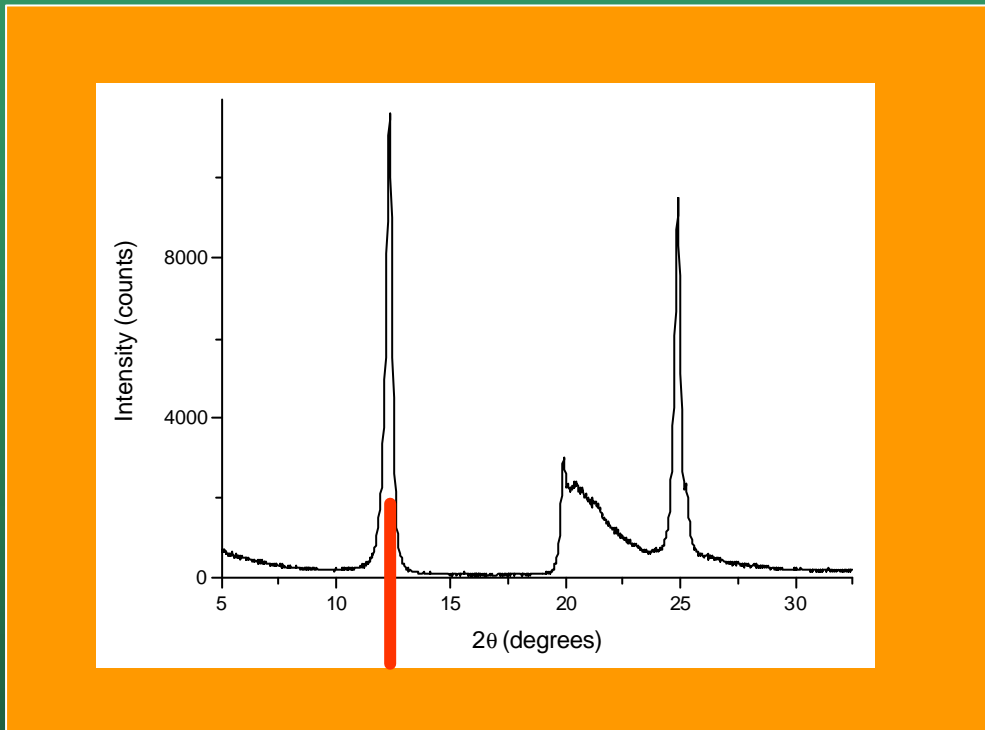
- **Peak position**
 - Interplanar spacing (Bragg equation)
 - Crystalline cell
 - Phase identification
 - Qualitative analysis
 - Residual stress
- **Peak intensity**
 - Single phase material (structure factor)
 - Structural analysis/refinement (Rietveld method)
 - Multiphase material
 - Quantitative phase analysis (with/without standard)
 - Crystallographic texture
- **Peak width/shape**
 - Microstructural information
 - Size/distribution of domains
 - Linear/planar defects



Lattice and cell identification

Interplanar spacing

Experimental pattern



Bragg's law

$$l = 2d \sin \theta$$

$$d = \frac{l}{2 \sin \theta}$$

Interplanar spacing corresponding to all reflections can be calculated



Fitting results

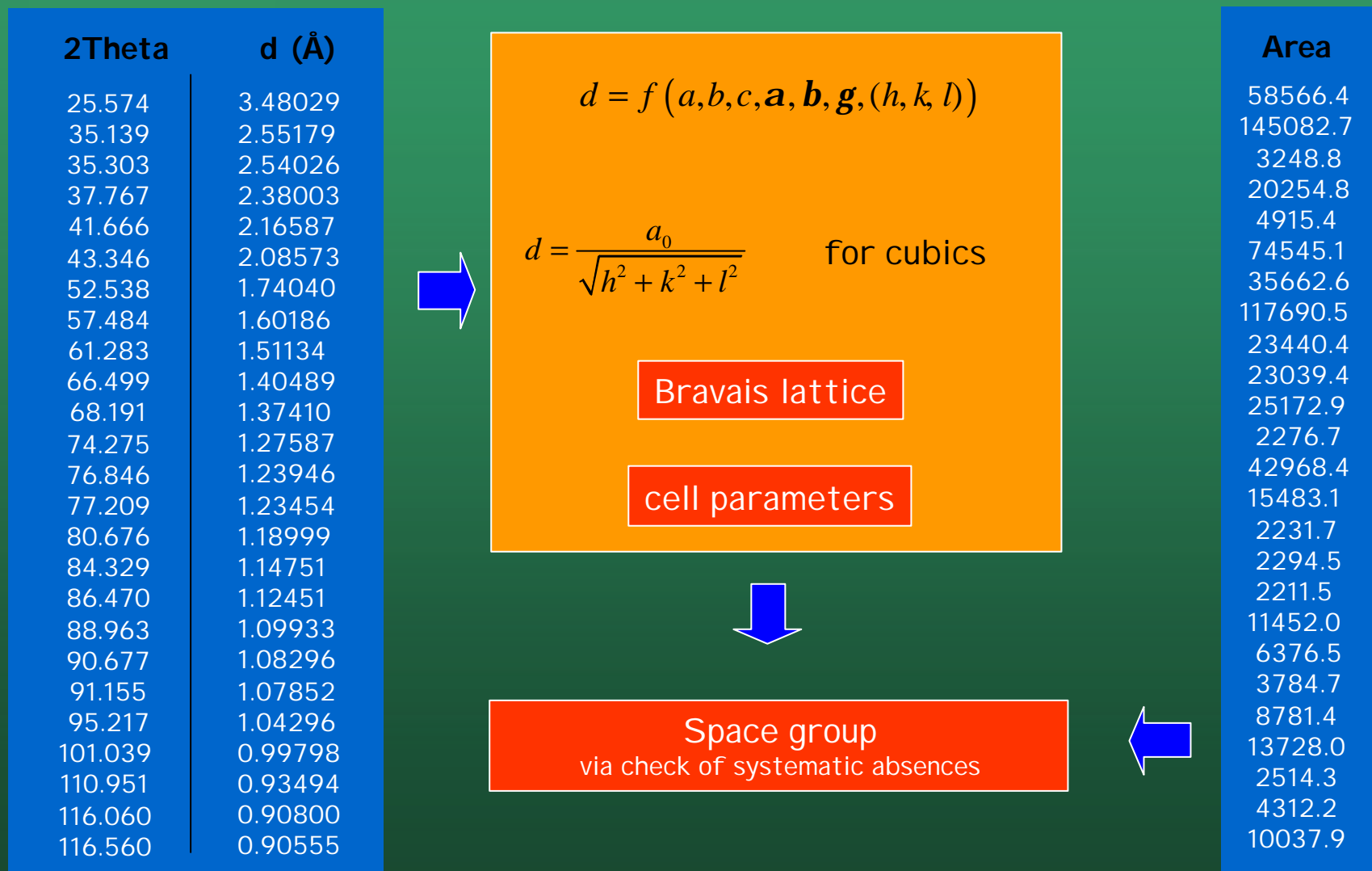
A table of profile parameters can be obtained e.g. through peak fitting

2Theta	d (Å)	Height	Area	FWHM
25.574	3.48029	5993.5	58566.4	0.1000
35.139	2.55179	18874.0	145082.7	0.0900
35.303	2.54026	374.2	3248.8	0.0900
37.767	2.38003	2469.4	20254.8	0.0900
41.666	2.16587	576.2	4915.4	0.0900
43.346	2.08573	8803.4	74545.1	0.0900
52.538	1.74040	3979.9	35662.6	0.0900
57.484	1.60186	13317.6	117690.5	0.0900
61.283	1.51134	2370.5	23440.4	0.1000
66.499	1.40489	2307.9	23039.4	0.1000
68.191	1.37410	2518.7	25172.9	0.1000
74.275	1.27587	237.7	2276.7	0.1000
76.846	1.23946	4965.6	42968.4	0.0900
77.209	1.23454	1549.5	15483.1	0.1000
80.676	1.18999	258.3	2231.7	0.0900
84.329	1.14751	229.7	2294.5	0.1000
86.470	1.12451	245.7	2211.5	0.0900
88.963	1.09933	1153.7	11452.0	0.1000
90.677	1.08296	596.0	6376.5	0.1100
91.155	1.07852	382.1	3784.7	0.1000
95.217	1.04296	880.7	8781.4	0.1000
101.039	0.99798	1374.2	13728.0	0.1000
110.951	0.93494	228.9	2514.3	0.1100
116.060	0.90800	392.1	4312.2	0.1100
116.560	0.90555	968.5	10037.9	0.1100



Indexing

Through indexing algorithms, lattice, cell and space group can be obtained

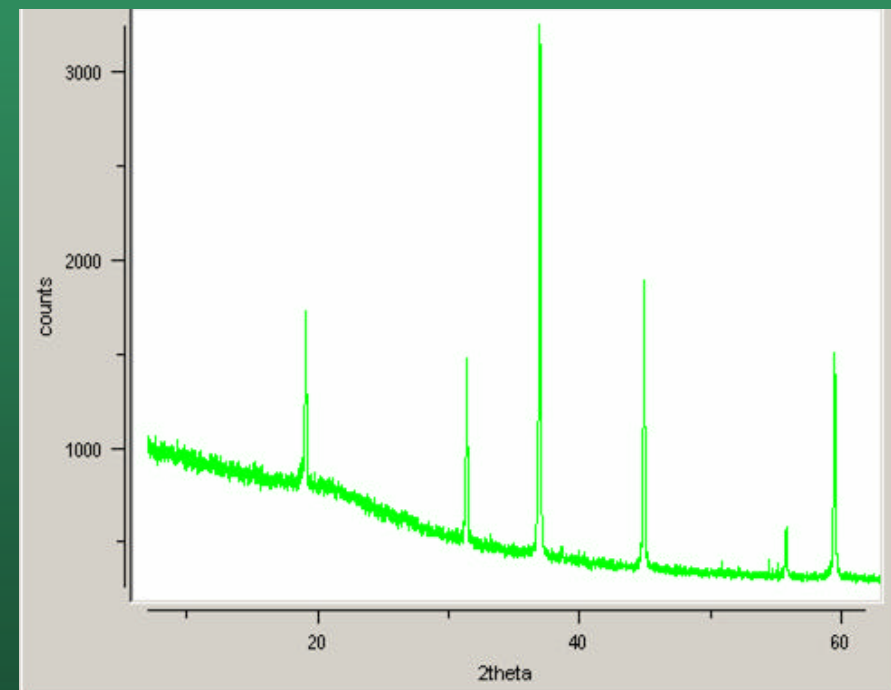
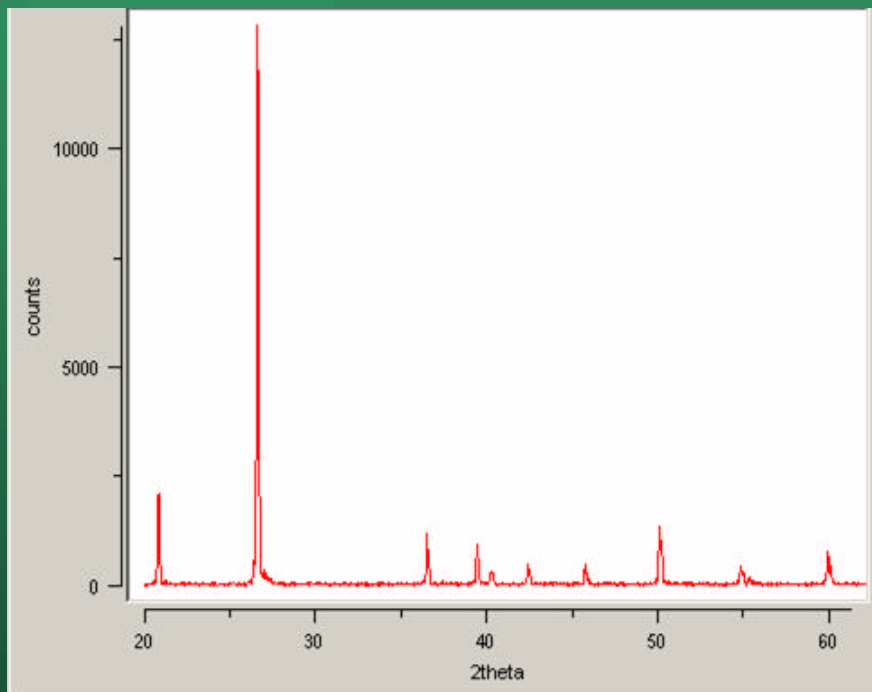


Qualitative phase analysis

Principle of operation

Phase identification is one of the first and most diffuse applications of powder diffraction (especially in industry), for research, production, quality control and diagnostics.

Each crystalline phase has its own pattern that can be used as a fingerprint.



We just need to find the fingerprint of known substances in the pattern to be analysed



Fitting results

A table of profile parameters can be obtained e.g. through peak fitting

2Theta	d (Å)	Height	Area	FWHM
25.574	3.48029	5993.5	58566.4	0.1000
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116.560	0.90555	968.5	10037.9	0.1100



Manual search

Manual matching of most intense lines

3.39 - 3.32 (± .02)								File No.	I/I _c		
i	3.38 _o	8.58 _x	3.04 _o	4.11 _o	3.18 _o	1.69 ₇	2.65 _o	1.88 ₅	(Mg,Fe) ₂ Al ₄ Si ₅ O ₁₈ /Cordierite, ferroan	9- 472	
	3.33 _x	6.72 _o	3.19 _o	8.09 ₇	3.28 ₇	5.18 ₄	3.10 ₄	4.30 ₄	C ₁₉ H ₁₉ N ₃ O ₆	29-1716	0.20
i	3.31 _o	6.40 _x	6.10 _o	3.85 ₅	2.77 ₅	6.70 ₄	3.48 ₄	2.64 ₄	C ₁₂ H ₈ Cl ₆	17-1054	
	3.38 _o	6.13 _x	8.66 _o	3.20 _o	3.29 ₅	9.70 ₃	4.57 ₃	3.46 ₃	C ₁₁ H ₁₁ N ₃ ·HCl	28-1749	
i	3.34 _x	5.93 ₂	5.19 ₁	3.77 ₁	3.65 ₁	3.51 ₁	2.94 ₁	1.67 ₁	C ₄ H ₈ N ₂ O ₂	26-1863	3.30
	3.37 _x	5.85 _o	3.86 _o	3.72 ₇	3.52 ₇	3.03 ₇	2.70 ₇	7.72 _o	C ₆ H ₉ N ₃ O ₂ ·HCl	5- 459	
*	3.31 _x	5.73 _x	3.43 ₇	3.59 _o	3.19 ₅	4.36 ₄	4.19 ₃	3.27 ₂	C ₆ H ₅ NO ₂	30-1845	1.00
	3.30 _x	5.44 ₇	5.63 ₅	3.24 ₄	4.97 ₃	6.58 ₃	4.58 ₂	3.15 ₂	(NH ₄) ₂ P ₂ O ₇	20- 102	
	3.38 _x	5.30 _x	3.49 _x	5.90 ₅	3.67 ₅	3.26 ₅	3.18 ₅	2.99 ₅	KH ₂ P ₂ O ₇	15- 509	
	3.35 _x	5.21 _o	4.86 _o	4.33 _o	4.04 _o	3.90 _o	3.55 _o	2.73 _o	β-C ₉ H ₁₁ NO ₂	22-1874	
i	3.40 _x	5.01 _o	3.09 ₇	4.10 ₄	3.00 ₄	4.03 ₃	6.74 ₂	3.45 ₂	C ₃ H ₆ N ₆	24-1654	1.10
*	3.30 _x	4.76 _o	4.18 _o	5.73 ₅	2.92 ₃	3.98 ₃	2.38 ₂	3.35 ₂	C ₈ H ₈ O ₄	37-1919	
	3.31 _x	4.71 _o	3.50 ₅	5.56 ₃	3.84 ₃	3.03 ₃	7.02 ₂	2.30 ₂	C ₆ H ₅ NO ₂ ·HCl	29-1827	
*	3.39 _x	4.48 ₅	3.43 ₅	3.01 ₅	4.09 ₄	2.98 ₄	2.78 ₄	3.18 ₃	NaHSO ₄	25- 833	
	3.34 _o	4.42 _x	10.1 _o	1.48 _o	2.56 _o	1.68 _o	1.28 ₇	1.23 ₇	Al ₂ Si ₂ O ₅ (OH) ₄ ·2H ₂ O/Halloysite-10A	9- 451	
i	3.40 _o	4.38 _x	2.88 ₇	5.76 ₄	2.61 ₄	4.09 ₄	2.76 ₄	1.76 ₄	V ₂ O ₅ /Shcherbinaite, syn	9- 387	1.60
*	3.33 _x	4.30 ₅	2.82 ₅	6.08 ₂	4.72 ₂	1.71 ₂	3.52 ₁	2.15 ₁	(NH ₄) ₂ Ca ₂ (SO ₄) ₃	22-1037	2.30
i	3.37 _x	4.28 _o	1.84 _o	1.55 _o	2.47 _o	2.31 _o	1.39 _o	2.14 _o	AlPO ₃ /Berlinite, syn	10- 423	
*	3.34 _x	4.26 ₂	1.82 ₁	1.54 ₁	2.46 ₁	2.28 ₁	1.37 ₁	1.38 ₁	SiO ₂ /Quartz, low, syn	33-1161	3.60
o	3.29 _x	4.22 ₂	3.27 ₇	3.27 ₄	3.72 ₄	4.04 ₂	3.77 ₂	7.17 ₁	C ₁₂ H ₈ Cl ₆	30-1944	
o	3.26 _x	4.22 ₂	3.25 ₇	4.43 ₄	3.67 ₄	4.22 ₂	2.87 ₂	3.26 ₂	C ₁₂ H ₈ Cl ₆	30-1944	
i	3.32 _x	4.22 ₂	3.25 ₇	4.43 ₄	3.67 ₄	4.22 ₂	2.87 ₂	3.26 ₂	C ₁₂ H ₈ Cl ₆	30-1944	
i	3.35 _x	3.28 ₇	3.28 ₇	3.28 ₇	3.28 ₇	3.28 ₇	3.28 ₇	3.28 ₇	C ₁₂ H ₈ Cl ₆	30-1944	
*	3.37 _x	3.27 ₇	3.27 ₇	3.27 ₇	3.27 ₇	3.27 ₇	3.27 ₇	3.27 ₇	C ₁₂ H ₈ Cl ₆	30-1944	
*	3.41 _o	3.34 _x	3.34 _x	3.34 _x	3.34 _x	3.34 _x	3.34 _x	3.34 _x	KHSO ₄ /Marcasite, syn	11- 649	
*	3.31 _x	3.77 _o	4.22 ₂	3.24 ₇	3.29 ₅	2.99 ₅	3.47 ₂	3.92 ₁	KAlSi ₃ O ₈ /Orthoclase	31- 956	
*	3.34 _x	3.52 ₇	7.65 _x	6.16 ₅	3.34 ₄	3.14 ₄	3.75 ₁	3.09 ₁	C ₁₂ H ₈ (CO ₂ C ₂ H ₅) ₂ /Nocilite, syn	20-2002	
*	3.35 _x	3.50 ₇	3.54 ₇	3.54 ₇	4.02 ₂	2.15 ₂	5.58 ₁	2.42 ₁	(NH ₄) ₂ P ₂ O ₇	31- 69	
*	3.36 _x	3.47 ₇	6.32 ₄	2.59 ₅	3.02 ₅	3.23 ₅	3.56 ₂	2.61 ₂	BaAl ₂ Si ₂ O ₇ /Celsite, syn	30-1450	
*	3.34 _x	3.47 ₇	6.32 ₄	2.59 ₅	3.02 ₅	3.23 ₅	3.56 ₂	2.61 ₂	BaAl ₂ Si ₂ O ₇ /Celsite, syn	30-1450	
*	3.30 _x	3.47 ₇	3.44 ₇	4.37 ₄	3.06 ₃	3.03 ₃	2.62 ₂	2.36 ₂	K ₂ Cr ₂ O ₇ /Aluminate, syn	27- 300	0.63
*	3.29 _x	3.46 ₇	3.79 ₇	3.26 ₇	3.01 ₅	2.93 ₅	2.91 ₅	2.77 ₅	Ca ₂ B ₂ (Si ₂ Al ₂ O ₇ /Orthoclase, barite)	19- 3	
*	3.33 _x	3.45 ₇	3.44 ₇	2.26 ₇	6.30 ₂	2.22 ₂	2.75 ₂	5.37 ₁	KPO ₃ /Potassium metaphosphate	30- 519	
i	3.39 _x	3.46 ₇	2.21 ₇	3.39 ₇	2.34 ₇	2.69 ₄	1.32 ₄	2.12 ₄	Al ₂ Si ₂ O ₇ /Nocilite, syn	15- 776	
i	3.39 _x	3.41 _o	2.31 ₇	2.34 ₇	3.82 ₂	2.14 ₂	2.03 ₂	2.00 ₂	NaBF ₄ /Ferrocite, syn	11- 671	
i	3.41 _o	3.39 _x	2.31 ₇	2.34 ₇	3.82 ₂	2.14 ₂	2.03 ₂	2.00 ₂	NaBF ₄ /Ferrocite, syn	11- 671	
i	3.33 _x	3.37 ₇	2.59 ₅	3.11 ₅	2.39 ₅	3.57 ₂	2.41 ₂	2.37 ₂	Gd ₂ S ₃	20-1006	
i	3.39 _x	3.36 ₇	2.53 ₅	3.11 ₅	2.39 ₅	3.57 ₂	2.41 ₂	2.37 ₂	Gd ₂ S ₃	20-1006	
i	3.39 _x	3.39 _x	4.76 ₂	4.18 ₂	5.73 ₂	2.92 ₂	3.94 ₂	2.39 ₂	C ₂ H ₄ O ₂	37-1919	
*	3.33 _x	3.25 ₇	2.97 ₇	3.93 ₄	2.36 ₄	2.34 ₄	2.36 ₄	2.31 ₄	CaSO ₄	14- 352	

Intense lines

Candidate

PDF-2

I/I_c



The Powder Diffraction File (PDF)

Information on known substances are collected into the PDF



PDF-2

lattice info



PDF-4

lattice info
atomic positions
relational database



PDF-4 organics



PDF-4 minerals



database browser



The Powder Diffraction File (PDF)

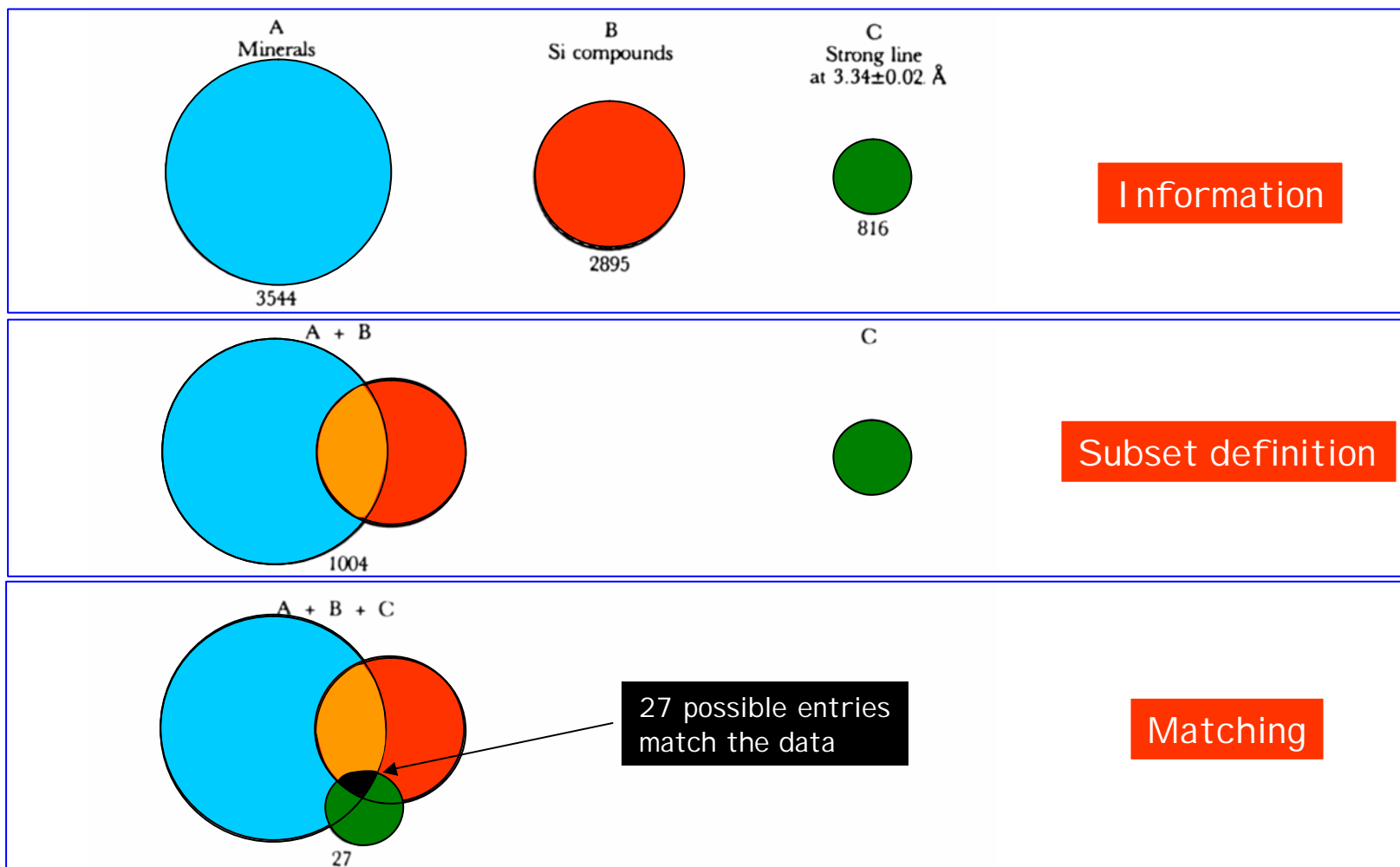
Information on known substances are collected into the PDF

6- 2				JCPDS-ICDD Copyright (c) 2000				Radiation:				Quality: i				(14/100)			
												d Å		Int.		h k l			
Ca Mg (Si,Al) O (OH) !6H O																			
0.3 3 4 10 2 2																			
Magnesium Aluminum Silicate Hydroxide Hydrate												18.8		100		0 0 1			
Saponite-18A, glycerol												9.1		50		0 0 2			
												6.06		10		0 0 3			
												4.55		50		1 0 0			
												3.61		50		0 0 5			
Rad: CuKα				Lambda: 1.5418				Filter: Ni				d-sp:							
Cutoff:				Int: Visual				I/Icor:											
Ref: Midgley, Mineral. Mag., 29 526 (1951)												3.01		40		0 0 6			
												2.61		60		1 1 1			
												2.48		30					
												2.26		20		0 0 8			
Sys: Hexagonal												2.00		10		0 0 9			
S.G.: P																			
a: 5.291(7)				b:				c: 18.05(5)				A: C: 3.4115							
A:				B:				C:				Z: 1 mp:							
Ref: Bayliss, P., Howie, R., Zussman, J., Powder Diffraction, 4 19 (1989)												1.736		40		2 1 0			
												1.536		70		3 0 0			
												1.321		40		2 2 0			
Dx: 2.10 Dm: 2.24 SS/FOM: F(13)=1.5(0.113,76)												1.271		20		3 1 0			
ea:				nwB: 1.555				ey:				Sign: - 2V: 0 deg.							
Ref: Deer, W., Howie, R., Zussman, J., Rock Forming Minerals, 3 226 (1962)																			
Color: White, reddish white																			
Specimen from Lizard, Cornwall, England, UK. CAS no.: 12173-47-6. Glycerol treated. Smectite group, trioctahedral subgroup. PSC: hp39.30. Volume[CD]: 437.61.																			



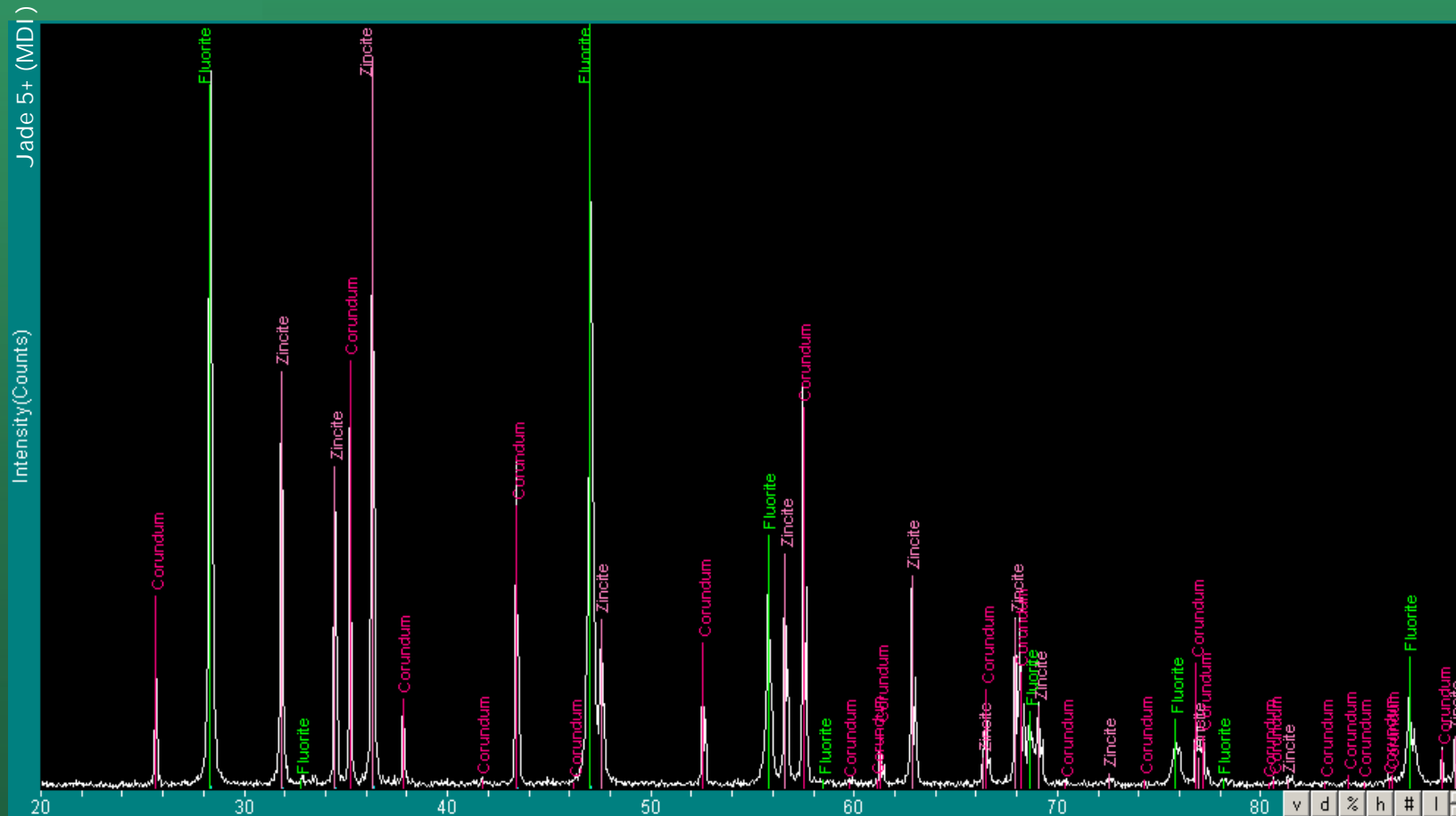
Boolean search

Line position matched against database entries of known substances



Automatic search match

Modern software does boolean search automatically on multiple peaks.
Example of search match done by using the MDI Jade 5.0 software on an unknown specimen (mixture of Al_2O_3 , CaF_2 and ZnO)



Quantitative Phase Analysis (QPA)

Quantitative Phase Analysis (QPA)

The pattern of a mixture is the **WEIGHTED** sum of the patterns corresponding to the constituent phases.

Qualitative analysis via **SEARCH-MATCH**

Must we stick to qualitative results only???

NOT ALWAYS! Several techniques based on XRD exist for a quantitative determination of the phase content:

- QPA with **internal standard**
- QPA "**standardless**" (RI Rs, Reference Intensity Ratios)
- QPA via **Rietveld method**



Quantitative Phase Analysis (QPA)

Mass absorption coefficient for a mixture of n phases:

$$\left(\frac{m}{r}\right)_m = w_1 \left(\frac{m}{r}\right)_1 + w_2 \left(\frac{m}{r}\right)_2 + \dots + w_n \left(\frac{m}{r}\right)_n = \sum_{i=1}^n w_i \left(\frac{m}{r}\right)_i$$

Intensity for the i -th reflection in a single-phase pattern

$$I_i = k_i \frac{|F_i|^2}{m_i} LP = \frac{k'_i}{m_i}$$

Intensity for the i -th reflection and j -th phase in a multi-phase pattern

$$I_{i,j} = \frac{k'_{i,j} v_j}{\left(\frac{m}{r}\right)_m r_m} = \frac{k'_{i,j} v_j}{m_m}$$

volume fraction j -th phase

linear absorption mixture



Quantitative Phase Analysis (QPA)

We can conveniently introduce the weight fractions

$$\mathbf{r}_j = \frac{w_j}{v_j} \mathbf{r}_m \quad I_{i,j} = \frac{k'_{i,j} v_j}{m_m} = \frac{k'_{i,j} w_j}{\mathbf{r}_j (\mathbf{m}/\mathbf{r})_m} = \frac{k''_{i,j} w_j}{(\mathbf{m}/\mathbf{r})_m}$$

mass absorption coefficient
for the mixture

For two phases, the formula for the i-th reflection reduces to:

$$I_{i,1} = \frac{k''_{i,1} w_1}{(\mathbf{m}/\mathbf{r})_m} = \frac{k''_{i,1} w_1}{\left[(\mathbf{m}/\mathbf{r})_1 - (\mathbf{m}/\mathbf{r})_2 \right] w_1 + (\mathbf{m}/\mathbf{r})_2} \quad w_1 = 1 - w_2, v_1 = 1 - v_2$$

The mass absorption coefficient is however unknown!

What is therefore all of this useful for?



Internal standard

We can solve the problem by adding a known amount of a standard material.

Assuming that the amount of phase to be determined is w_j , we can add a known amount of an extra phase (spiking) w_s

By effect of the extra phase, we have:

$$w'_j = (1 - w_s)w_j$$

and, therefore the ratio of the intensities of two peaks for the j and s phases read:

$$\frac{I'_{i,j}}{I_{l,s}} = \frac{k_{i,j}w'_j}{k_{l,s}w_s} = f_{j,s} \frac{w'_j}{w_s} = f_{j,s} \frac{w_j(1-w_s)}{w_s}$$

from which, if we know the structure of the phases and therefore $f_{j,s}$:

$$w_j = \frac{I_{i,j}}{I_{r,s}} \cdot \frac{w_s}{f_{j,s}(1-w_s)}$$



RIR formula

There is a possible elegant alternative.

For a 1:1 mixture of our phase and a corundum standard the f reads:

$$f_{j,s} = \frac{I_{i,j}}{I_{l,c}} \cdot \frac{w_c}{w_j (1 - w_c)} = 2 \frac{I_{i,j}}{I_{l,c}}$$

The ratio between the most intense peaks of our phase and of corundum is defined as Reference Intensity Ratio (RIR) with corundum:

$$RIR_{j,corundum} = I_j / I_c = \frac{I_{i,j}}{I_{l,c}} \frac{I_{l,c}^{rel}}{I_{i,j}^{rel}} \frac{w_c}{w_j}$$

For a peak i and phase j with relative intensity $I_{i,j}^{rel}$ we have:

$$w_j = \frac{I_{i,j} / I_{i,j}^{rel}}{I_j / I_c} \left[\sum_{k=1}^n \frac{I_{l,k} / I_{l,k}^{rel}}{I_k / I_c} \right]^{-1}$$



The Rietveld method

Rietveld method

Definition: page 2 R.A. Young 1993:

In the Rietveld method the least-squares refinements are carried out until the best fit is obtained between the entire observed powder diffraction pattern taken as a whole and the entire calculated pattern based on the simultaneously refined models for the crystal structure(s), diffraction optics effects, instrumental factors, and other specimen characteristics

It is a minimization procedure (Nonlinear Least Squares refinement) of the residual:

$$S_y = \sum_i w_i (y_i - y_{ci})^2$$

The diagram shows the equation $S_y = \sum_i w_i (y_i - y_{ci})^2$ with three terms highlighted by colored circles: w_i is in a blue circle, y_i is in a pink circle, and y_{ci} is in a yellow circle. Below the equation, three colored boxes with arrows point to these terms: a blue box labeled 'weight' points to w_i , a pink box labeled 'observed' points to y_i , and a yellow box labeled 'calculated' points to y_{ci} .



Rietveld method: basic equation

Intensity of the i-th point in the pattern

$$y_{ci} = S \sum_k L_k |F_k|^2 f(2q_i - 2q_k) P_k A + y_{bi}$$

Diagram illustrating the Rietveld method basic equation with components labeled:

- scale factor (S)
- Structure factor ($|F_k|^2$)
- Profile function ($f(2q_i - 2q_k)$)
- Background term (y_{bi})

Using the normalization condition: $\sum_k x_k = 1$

it is possible to calculate the weight fraction x_α of the phase α in a polyphasic mixture:

$$x_j = \frac{S_j r_j v_j}{\sum_l S_l r_l v_l}$$



Is the fit good?

Statistical indices

$$R_F = \frac{\sum |I_K(\text{'obs'})^{1/2} - I_K(\text{calc})^{1/2}|}{\sum (I_K(\text{'obs'}))^{1/2}} \quad (\text{'R-structure factor'})$$

$$R_B = \frac{\sum |I_K(\text{'obs'}) - I_K(\text{calc})|}{\sum I_K(\text{'obs'})} \quad (\text{'R-Bragg factor'})$$

$$R_p = \frac{\sum |y_i(\text{obs}) - y_i(\text{calc})|}{\sum y_i(\text{obs})} \quad (\text{'R-pattern'})$$

$$R_{wp} = \left\{ \frac{\sum w_i (y_i(\text{obs}) - y_i(\text{calc}))^2}{\sum w_i (y_i(\text{obs}))^2} \right\}^{1/2} \quad (\text{'R-weighted pattern'})$$

Here I_K is the intensity assigned to the K th Bragg reflection at the end of the refinement cycles. In the expressions for R_F and R_B the 'obs' (for observed) is put in quotation marks because the Bragg intensity, I_K , is rarely observed directly; instead the I_K values are obtained from programmatic allocation of the total observed intensity in a 'scramble' of overlapped reflections to the individual reflections, according to the ratios of those reflection intensities in the calculated pattern.

The 'Goodness-of-fit' indicator, S , is

$$S = [S_y / (N - P)]^{1/2} = R_{wp} / R_e$$

where

$$R_e = \text{'R-expected'} = [(N - P) / \sum w_i y_{oi}^2]^{1/2}.$$

The Durbin-Watson statistic, 'd', is

$$\text{'d'} = \frac{\sum_{i=2}^N (\Delta y_i - \Delta y_{i-1})^2}{\sum_{i=1}^N \Delta y_i^2}$$

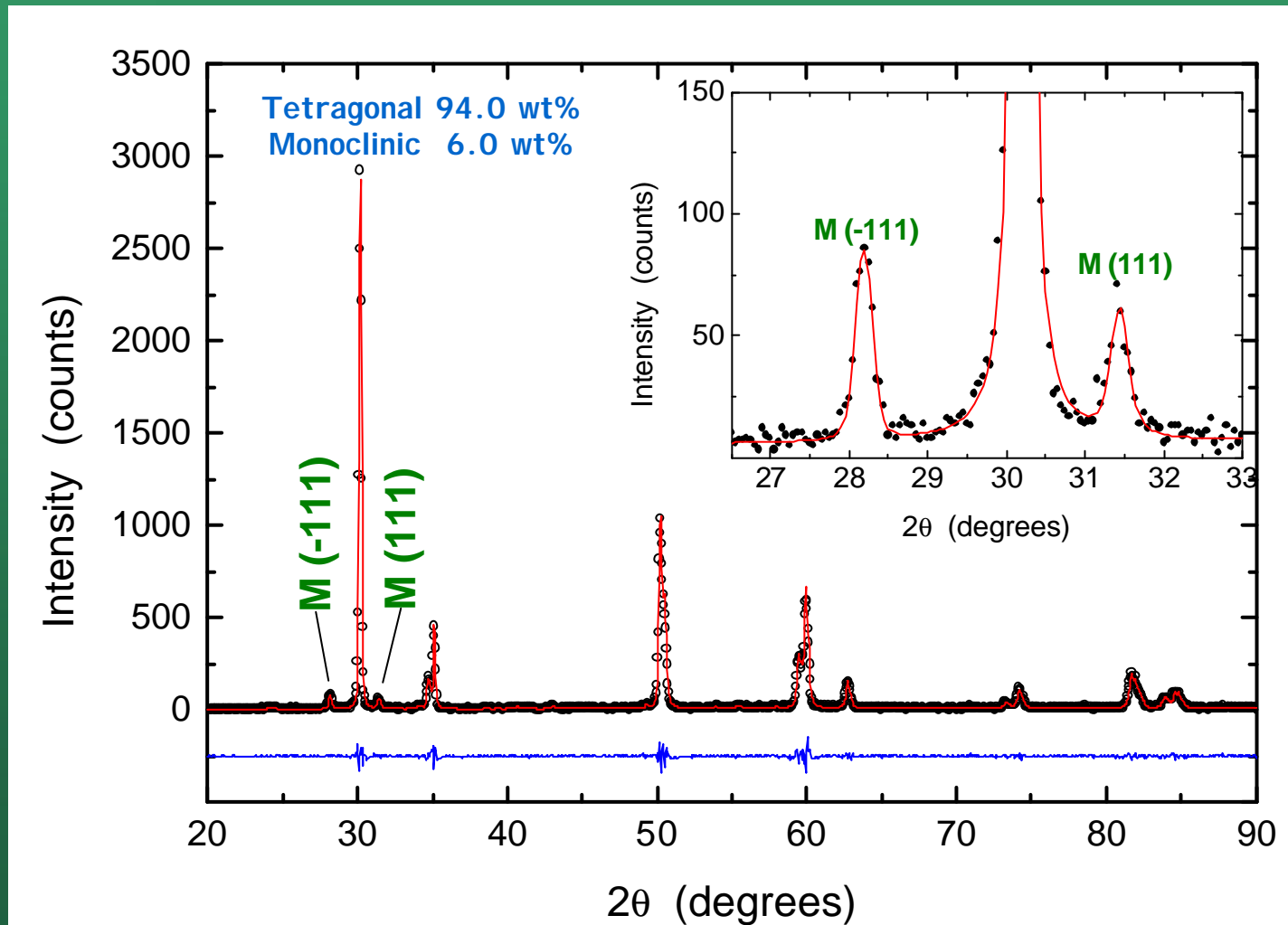
where

$$\Delta y_i = y_{oi} - y_{ci}.$$



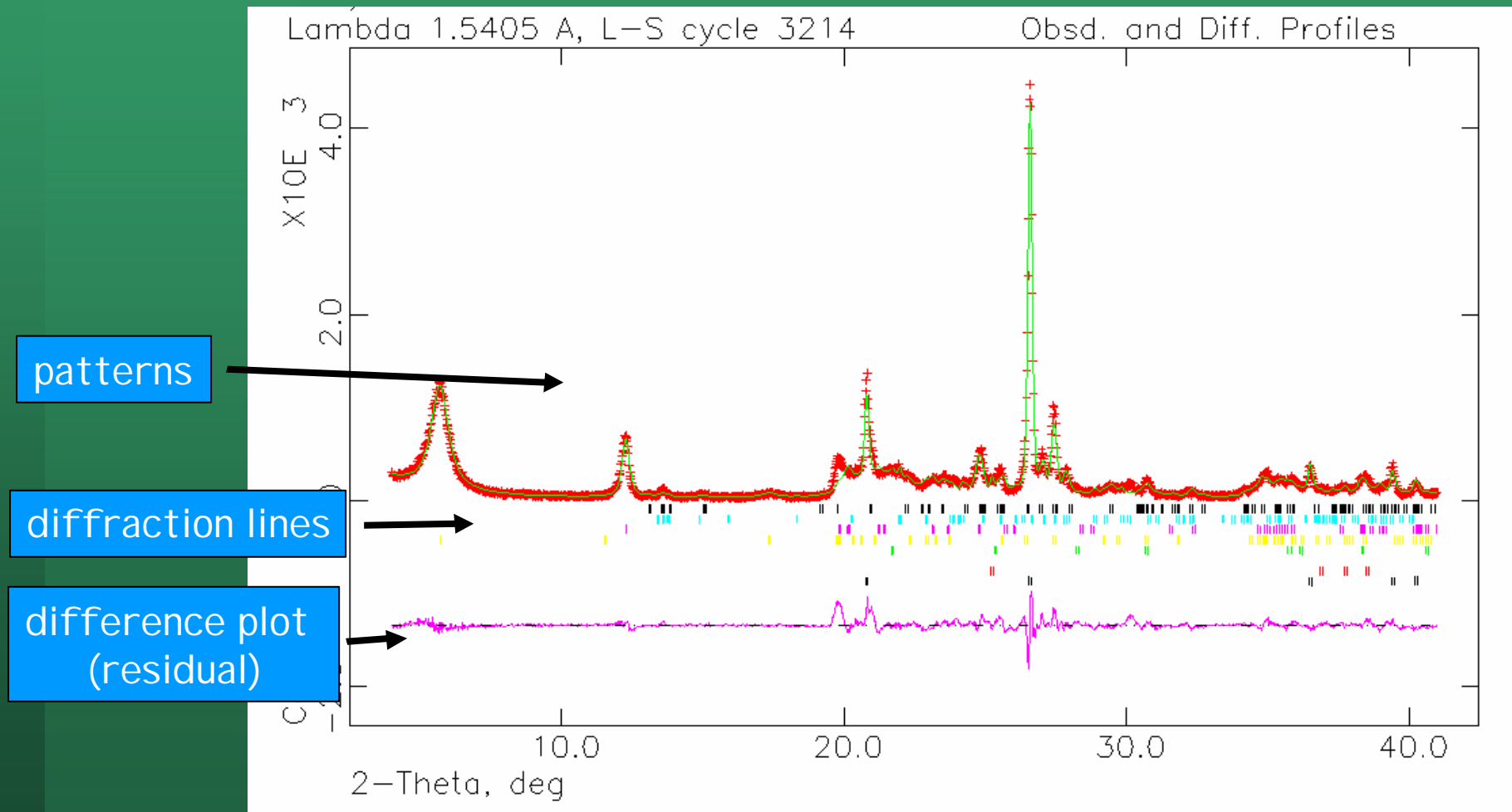
Example of Rietveld-based QPA

QPA of zirconia polymorphs in Partially-Stabilised Zirconia TBCs (Thermal Barrier Coatings)



Example: GSAS

The same elements are always present to allow visual feeling for the fit quality



Structure solution/refinement

Structure solution/refinement

Structure solution of heptamethylene-1,7-bis(diphenylphosphane oxide)

Structural formula
 $\text{Ph}_2\text{P}(\text{O})(\text{CH}_2)_7\text{P}(\text{O})\text{Ph}_2$

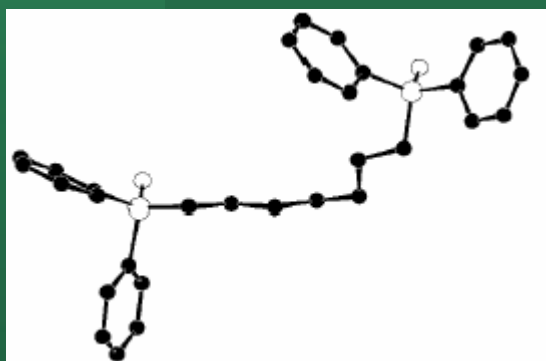
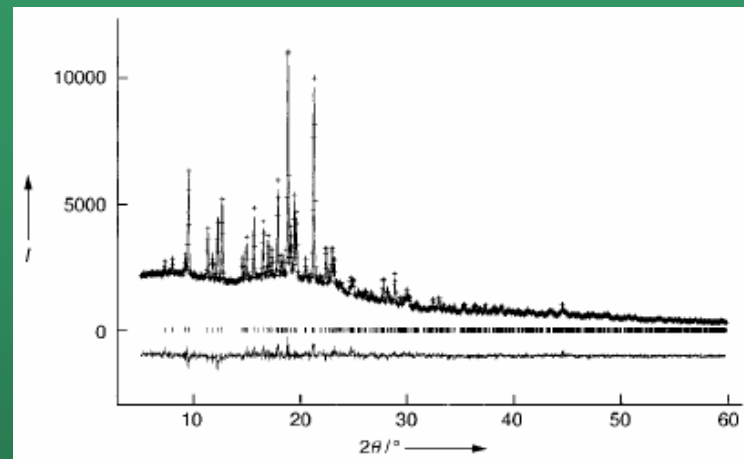
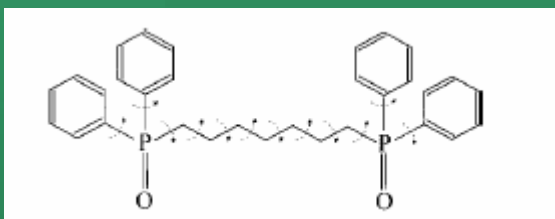


Table 1. Fractional coordinates for the non-hydrogen atoms in the final refined crystal structure of $\text{Ph}_2\text{P}(\text{O})(\text{CH}_2)_7\text{P}(\text{O})\text{Ph}_2$ ($P2_1/n$; $a = 12.560(1)$, $b = 10.203(1)$, $c = 22.889(2)$ Å, $\beta = 105.53(1)^\circ$).

Atom	<i>x/a</i>	<i>y/b</i>	<i>z/c</i>
C(1)	0.224(2)	0.949(2)	0.630(5)
C(2)	0.299(3)	0.988(4)	0.683(6)
C(3)	0.290(3)	0.953(4)	0.740(5)
C(4)	0.209(3)	0.862(4)	0.745(7)
C(5)	0.137(3)	0.809(4)	0.694(1)
C(6)	0.146(3)	0.846(3)	0.636(1)
C(7)	0.205(1)	1.175(1)	0.558(1)
C(8)	0.097(1)	1.223(1)	0.549(2)
C(9)	0.080(2)	1.356(2)	0.557(2)
C(10)	0.171(2)	1.442(1)	0.573(3)
C(11)	0.277(2)	1.394(1)	0.577(2)
C(12)	0.294(1)	1.261(1)	0.570(2)
P(1)	0.227(1)	0.998(1)	0.555(6)
O(1)	0.144(2)	0.932(2)	0.506(7)
C(13)	0.366(2)	0.977(1)	0.553(1)
C(14)	0.413(2)	0.844(2)	0.573(1)
C(15)	0.486(2)	0.790(2)	0.536(1)
C(16)	0.509(3)	0.645(2)	0.545(7)
C(17)	0.562(5)	0.610(2)	0.611(1)
C(18)	0.568(5)	0.464(2)	0.623(1)
C(19)	0.612(3)	0.418(1)	0.687(1)
P(2)	0.628(1)	0.245(1)	0.695(5)
O(2)	0.542(1)	0.170(2)	0.650(7)
C(20)	0.766(1)	0.209(3)	0.688(7)
C(21)	0.782(2)	0.164(4)	0.634(1)
C(22)	0.889(2)	0.147(5)	0.628(1)
C(23)	0.980(1)	0.166(5)	0.677(1)
C(24)	0.965(1)	0.208(5)	0.733(1)
C(25)	0.858(1)	0.226(5)	0.739(1)
C(26)	0.631(2)	0.207(1)	0.772(6)
C(27)	0.663(4)	0.303(2)	0.817(6)
C(28)	0.668(4)	0.275(2)	0.873(6)
C(29)	0.635(4)	0.149(2)	0.893(7)
C(30)	0.597(4)	0.055(2)	0.847(1)
C(31)	0.596(5)	0.084(2)	0.787(1)

B.M. Kariuki, P. Calcagno, K. D. M. Harris, D. Philp and R.L. Johnston, *Angew. Chem. Int. Ed.* 1999, 38, No. 6, 831-835.



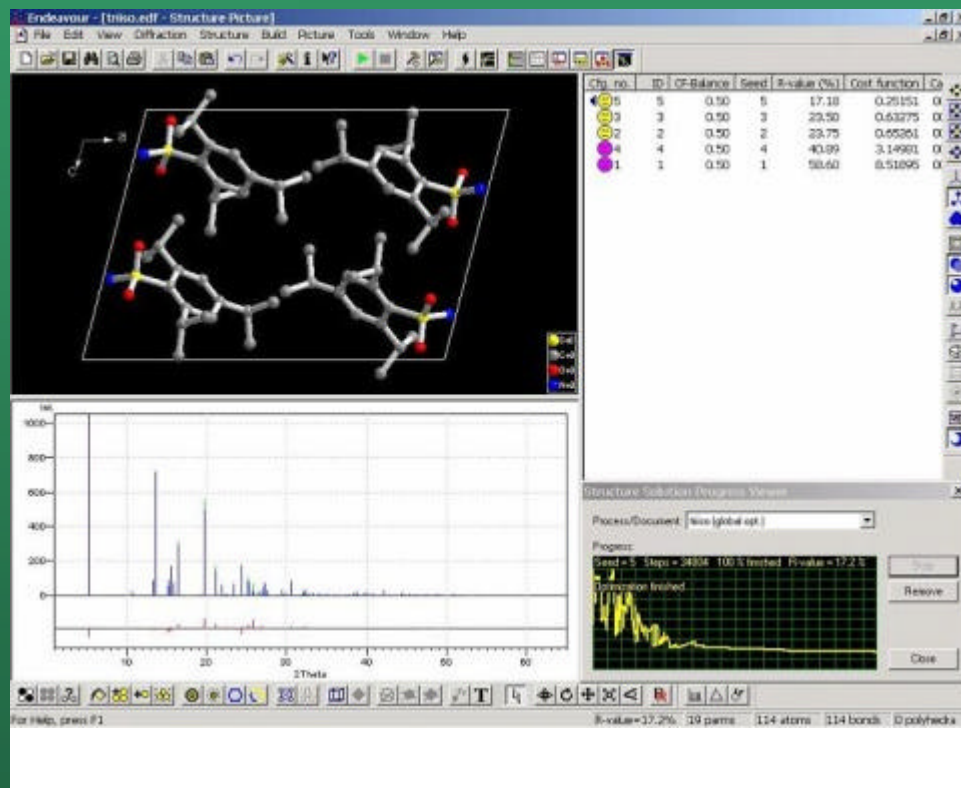
Structural solution

- Direct methods
 - Pattern decomposition and extraction of integrated intensities
 - Trying to reconstruct the missing information (phase) directly from the pattern
- “Two steps” method:
 - Pattern decomposition and extraction of integrated intensities
 - Determination of the structure by matching measured and calculated intensities
- Rietveld method:
 - Matching between the whole experimental pattern and the pattern built on the basis of a trial structure. Refinement of the structure by least square fitting



Structure solution/refinement

Commercial and free (shareware) software for structure solution and refinement



Structural parameters

- Cell symmetry (S.G.)
- Lattice parameters
- Atomic coordinates
- Bond angles and distances
- Site occupancy
- Thermal factors

Rietveld method can be used:
parameters of a synthetic pattern are refined against measured data

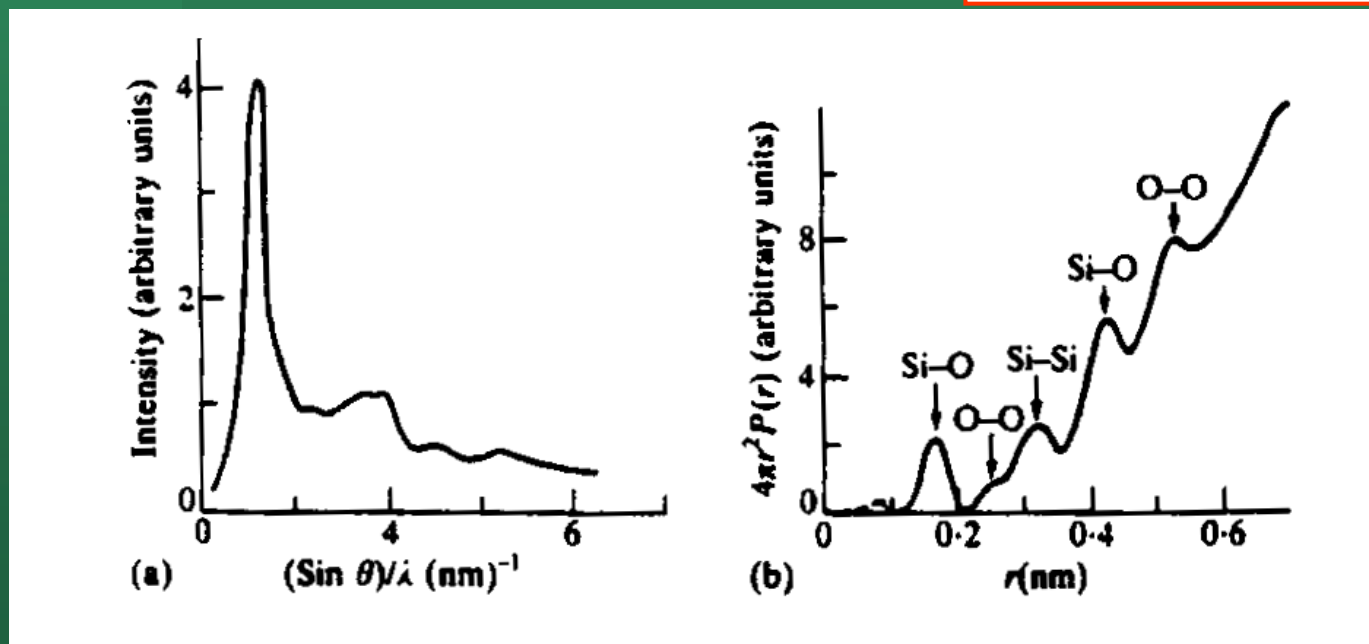
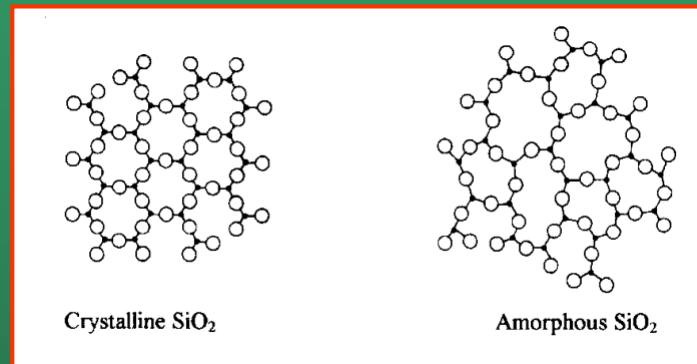


Amorphous materials

Radial distribution function

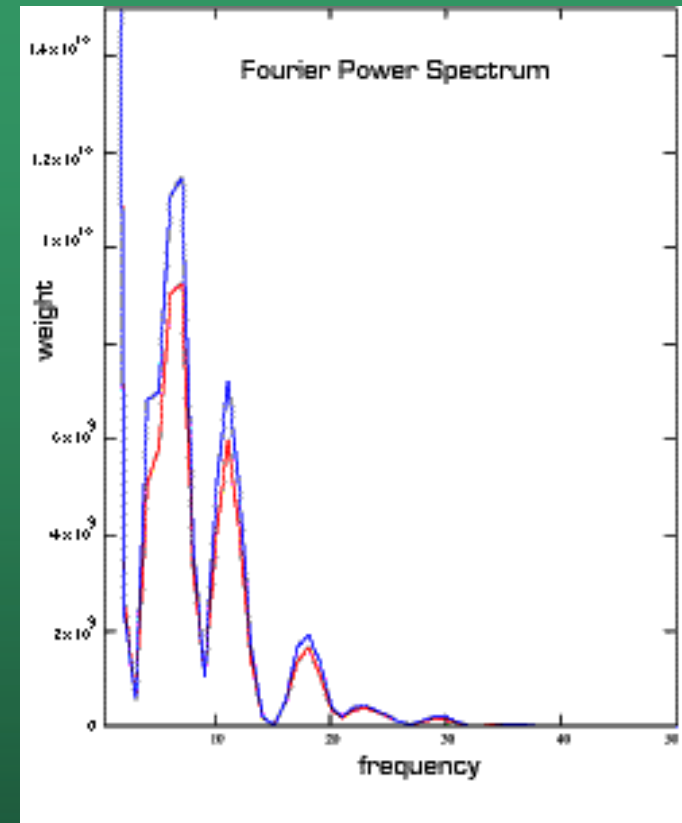
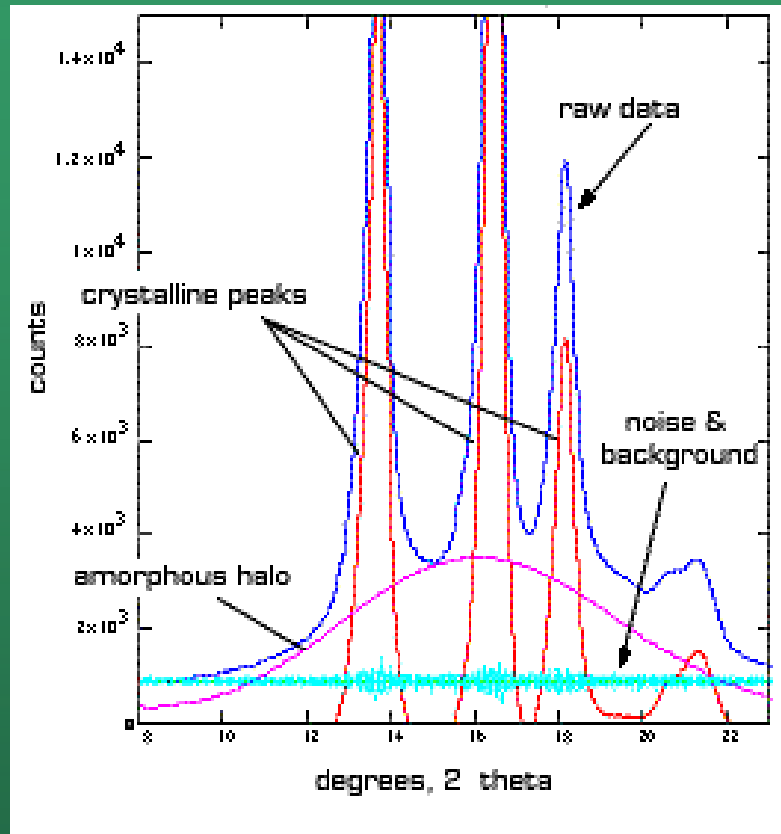
The long-range order typical of crystalline structures is absent in amorphous materials. However, a certain degree of short-range order is always present.

Diffraction can be used to measure the **radial distribution function**, i.e., the probability distribution to find an atom at a distance between r and $r+dr$ taken from a reference atom.



Amorphous content

Amorphous content

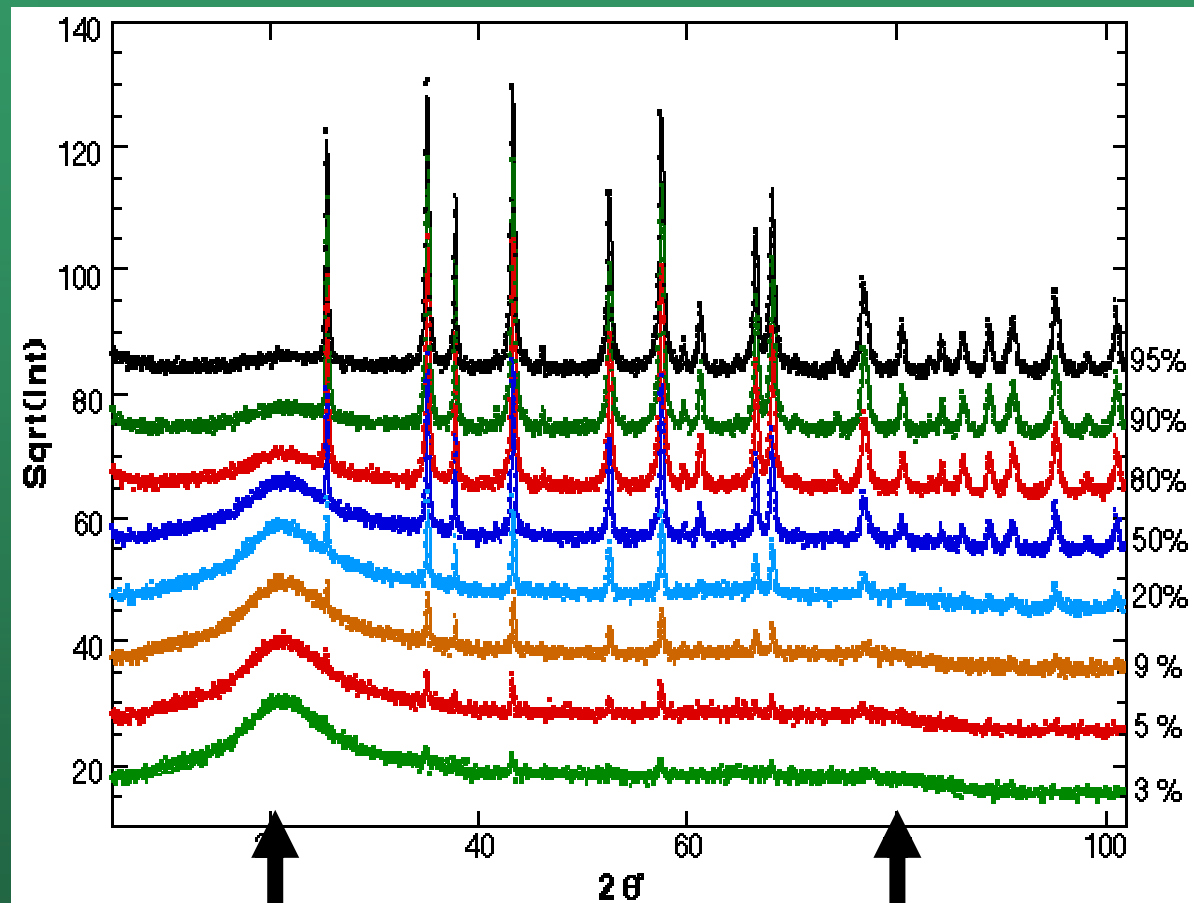


In a diffraction pattern both the amorphous halo and the crystalline peaks can be simultaneously present above the background (50% crystalline polymeric material).

Fourier Power Spectrum of two samples with different percentage crystallinity showing the amorphous and crystalline frequency bands.



Corundum + amorphous silica



amorphous bands typical of a glassy phase



Amorphous phases: QPA and crystallinity

Modeling of amorphous and crystalline peaks allows obtaining the **fraction of amorphous phase** in mixtures.

Diffraction can also measure the **degree of crystallinity** in partly-crystalline materials, like polymers or glass-ceramics.

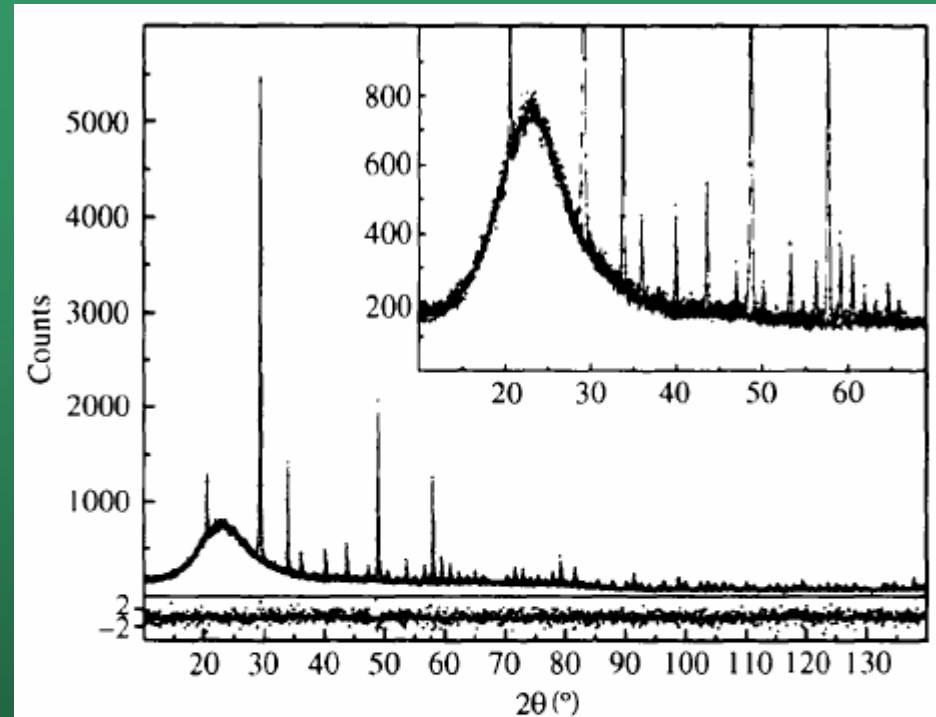


Fig. 1. Rietveld analysis of sample C (Y_2O_3 /amorphous silica with weight ratio 10:90) with air scattering subtracted. In the inset, which shows an enlargement, the experimental noise of the amorphous scattering used in the fitting is evident. At the bottom, the weighted residuals are reported. Because of the noise in the amorphous pattern, the normalized residuals are defined as $\Delta Y_i(\text{weighted}) = (Y_{oi} - Y_{ci})/[Y_{oi} + (K^{\text{am}})^2 Y^{\text{am}}]^{1/2}$ and consequently the goodness of fit is $S^2 = \{\sum[\Delta Y_i(\text{weighted})]^2\}/(N - P) = 1.3$.

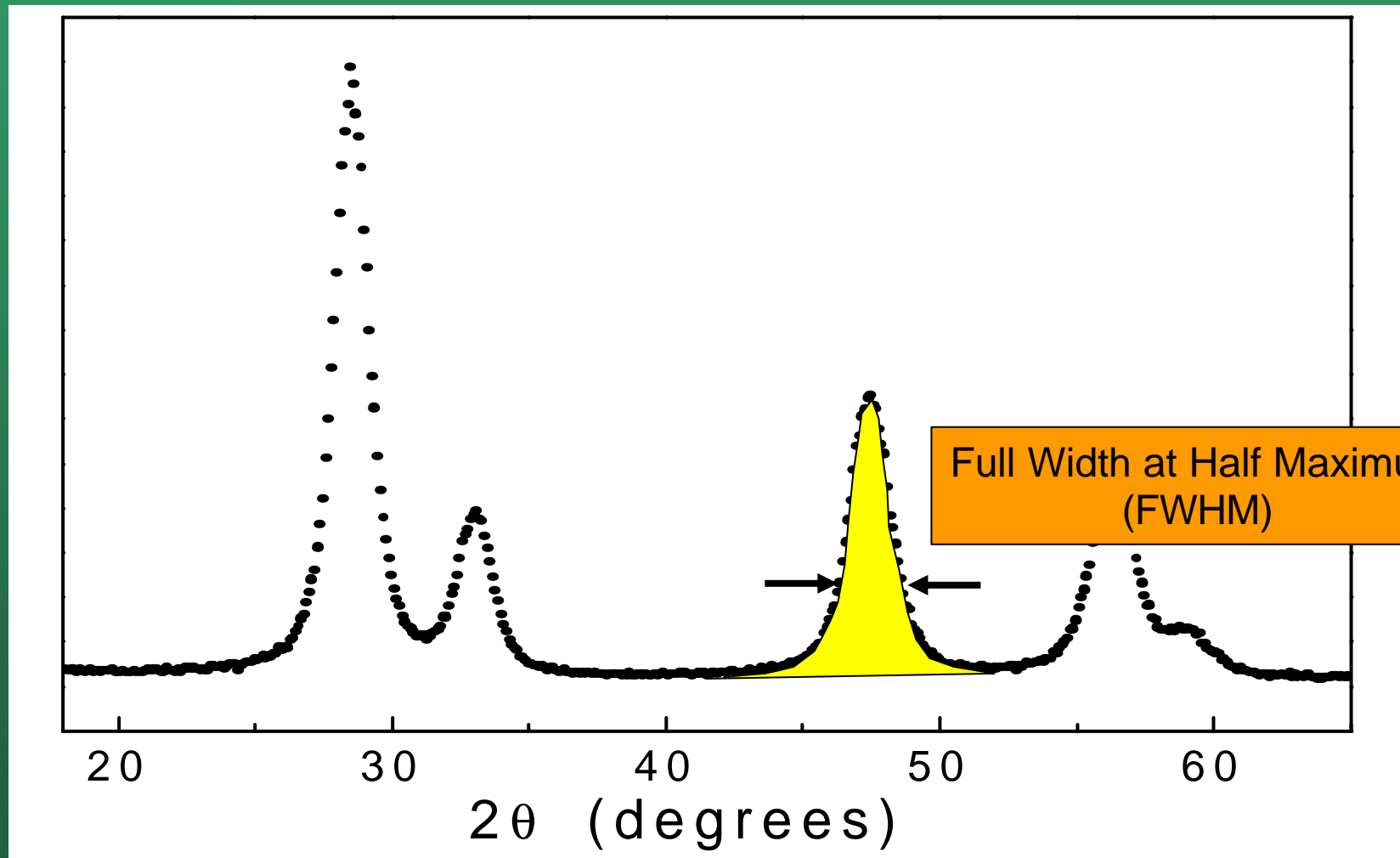
P. Riello, P. Canton, G. Fagherazzi, J. Appl. Cryst. 1998, 31, 78-82.



Microstructural analysis

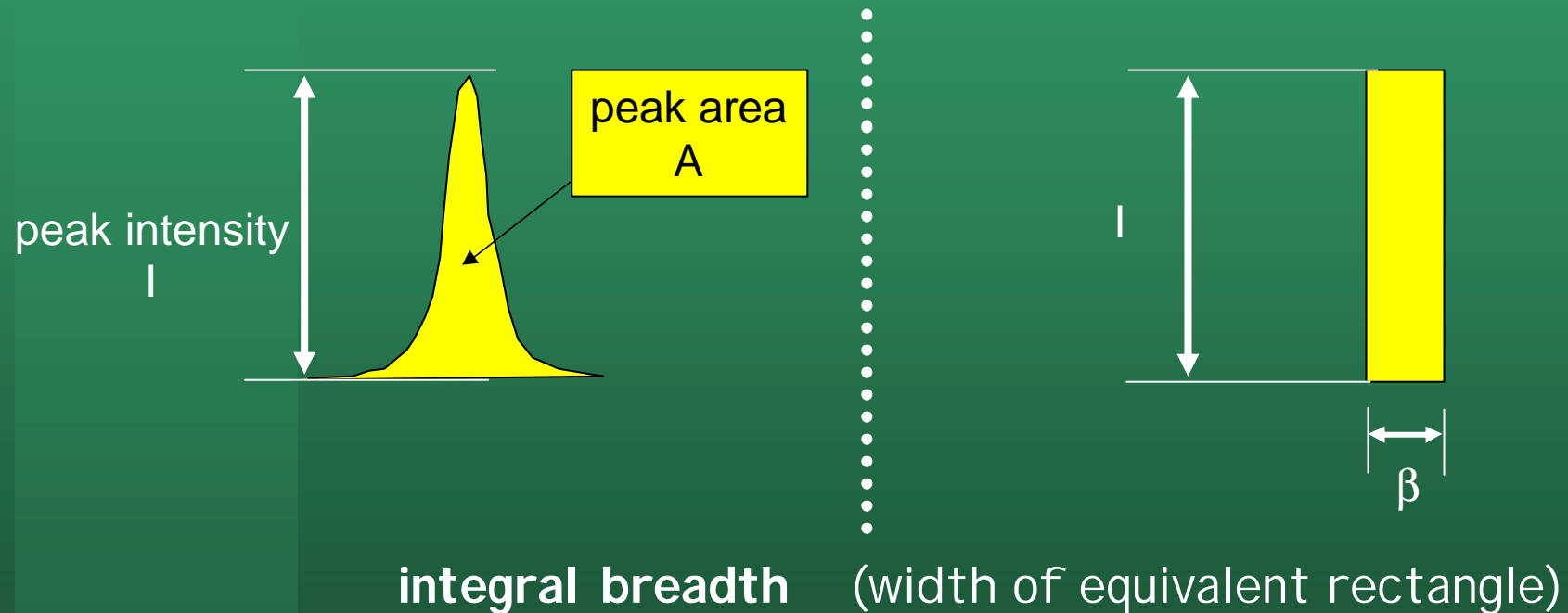
Line profile analysis

Profile information extracted as FWHM or Integral Breadth (β)



Line profile analysis

Traditional methods are based on the study of the integral breadth of X-ray peaks:



$$b = \frac{A}{I}$$



Line profile analysis

It is possible to correlate the integral breadth with the size L of the coherently diffracting domains (Scherrer formula):

reciprocal space

$$b(d^*) = \frac{K_b}{L}$$



2q space

$$b(2q) = \frac{K_b l}{\cos q \cdot L}$$

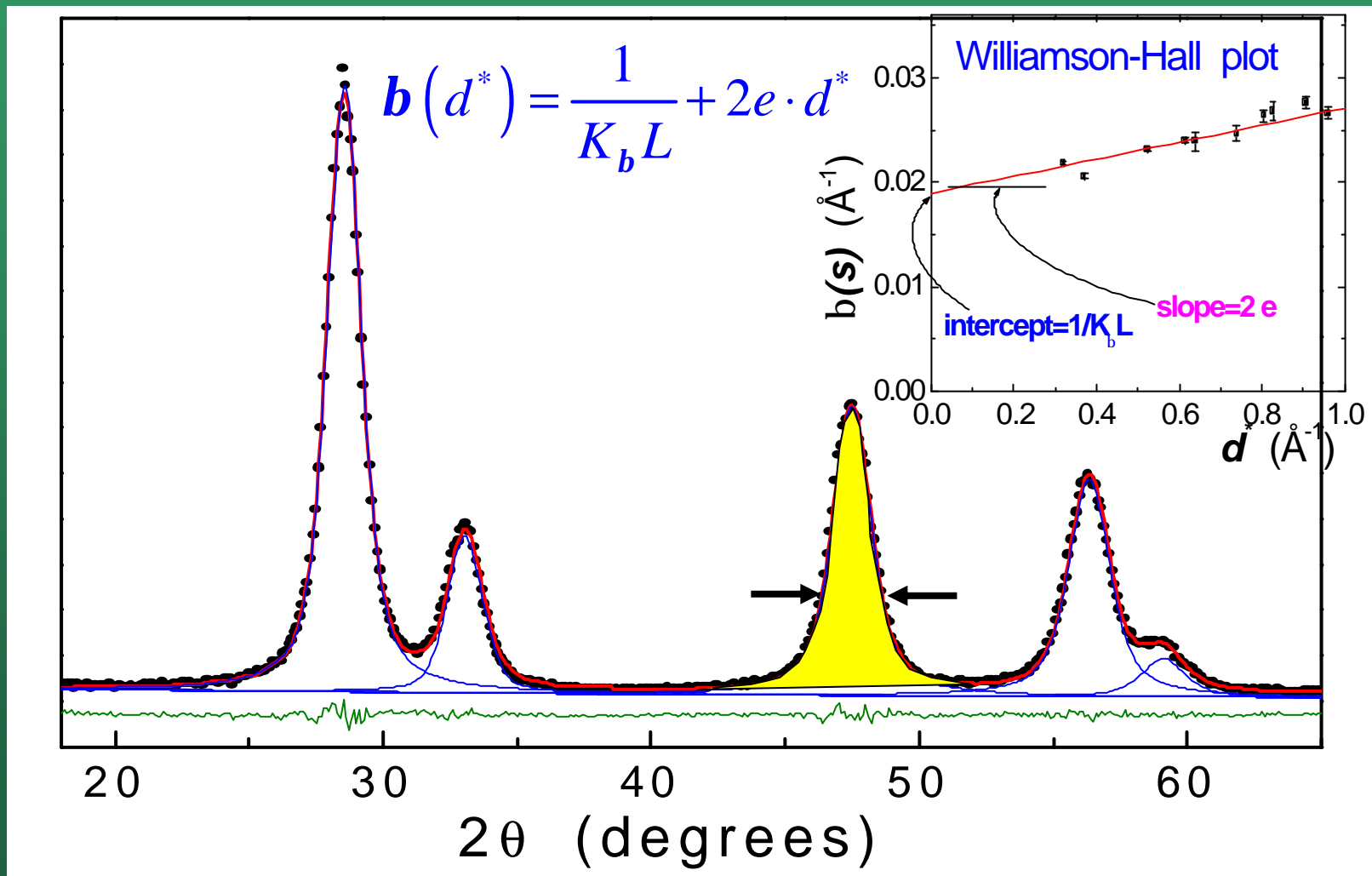
$$\frac{l}{d^*} = 2 \sin q \quad \Rightarrow \quad dd^* = \frac{\cos q}{l} d2q \quad \Rightarrow \quad d2q = \frac{l}{\cos q} dd^*$$

The constant K_b is related to the shape of the domains and is of the order of magnitude of 1



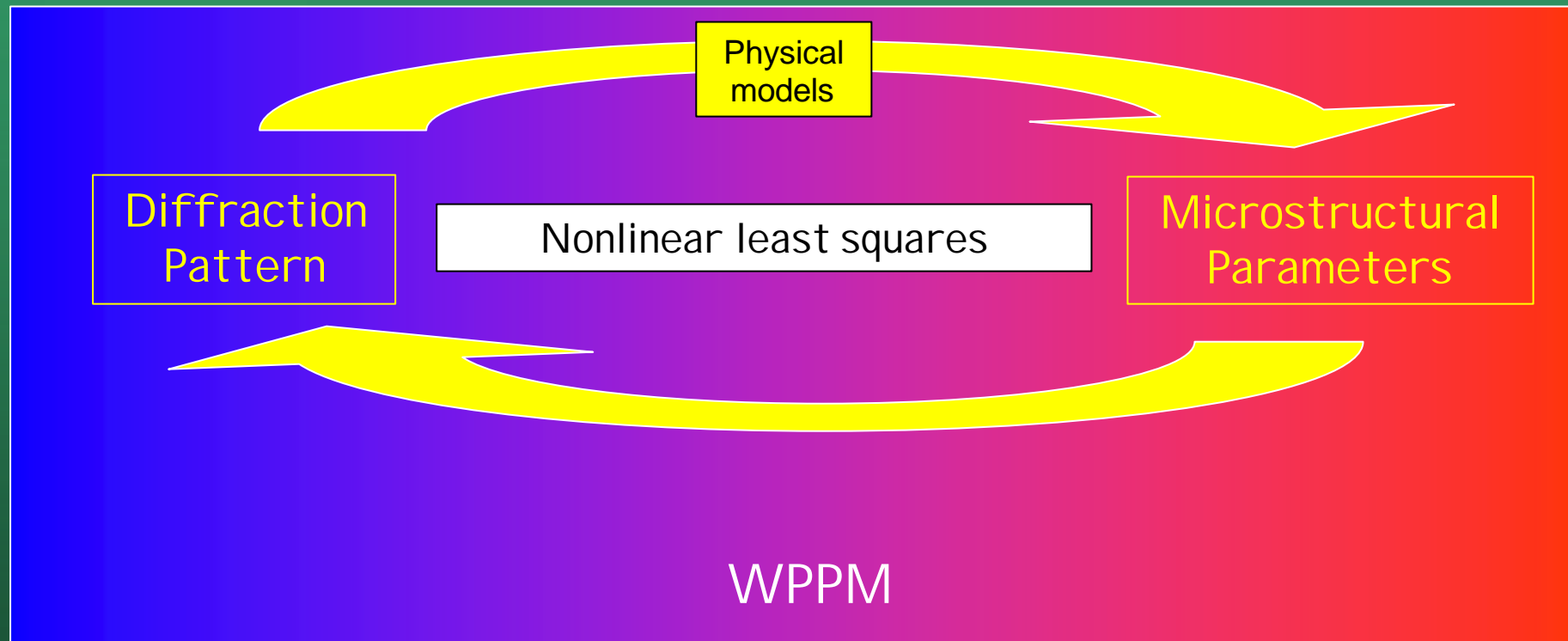
Line profile analysis: traditional methods

Considering multiple peaks, a trend can be found



Alternative advanced methods: WPPM

Alternative exists where the whole X-ray diffraction pattern is analysed in terms of physical models of the microstructure



It is a self-consistent one-step procedure: fine details in the pattern can be unveiled



Alternative advanced methods: WPPM

$$I_{\{hkl\}}(d^*, d_{\{hkl\}}^*) = k(d^*) \cdot \sum_{hkl} w_{hkl} \int_{-\infty}^{\infty} C_{hkl}(L) \exp(2\pi i L \cdot s_{hkl}) dL$$

Diffraction profiles result from a convolution of effects.

Therefore, Fourier Transforms of the various effects are multiplied:

$$T_{pV}^{IP} \cdot A_{\{hkl\}}^S \cdot A_{\{hkl\}}^D \cdot (A_{hkl}^F + iB_{hkl}^F) \cdot A_{\{hkl\}}^{APB} \cdot (A_{hkl}^{GSR} + iB_{hkl}^{GSR}) \cdot (A_{hkl}^{CF} + iB_{hkl}^{CF}) \cdot \dots$$

Instrumental Profile

Faulting

APB

Stoichiometry fluctuations

Domain size

Dislocations

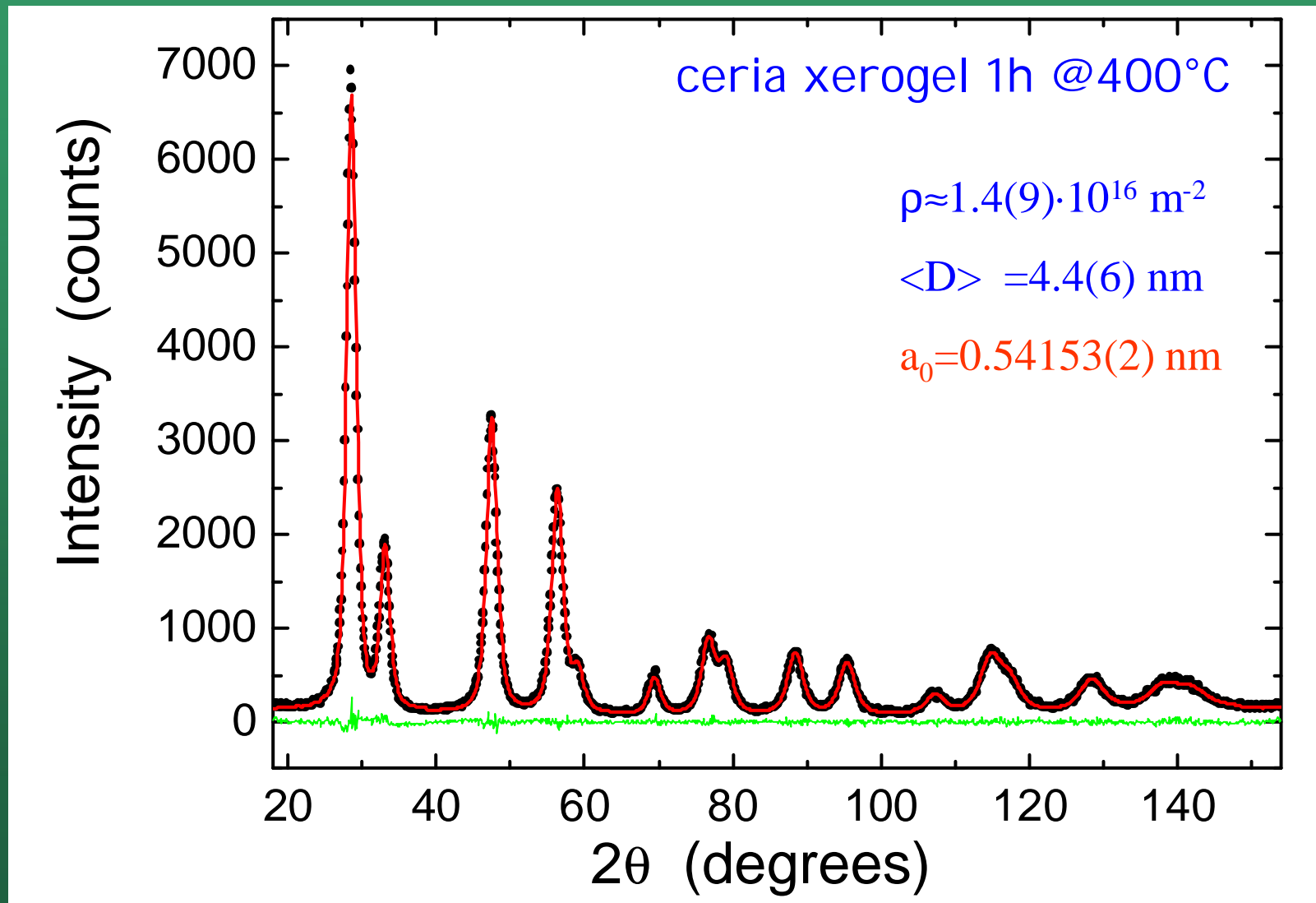
Grain surface relaxation

Instrumental Profile, Domain Size, Dislocations, Anti-Phase Domain terms are real functions of L (Fourier length), whereas Faulting, Grain Surface Relaxation and fluctuations in the composition give complex (A+iB) contributions

Additional line broadening sources can be included by adding (multiplying) corresponding FTs

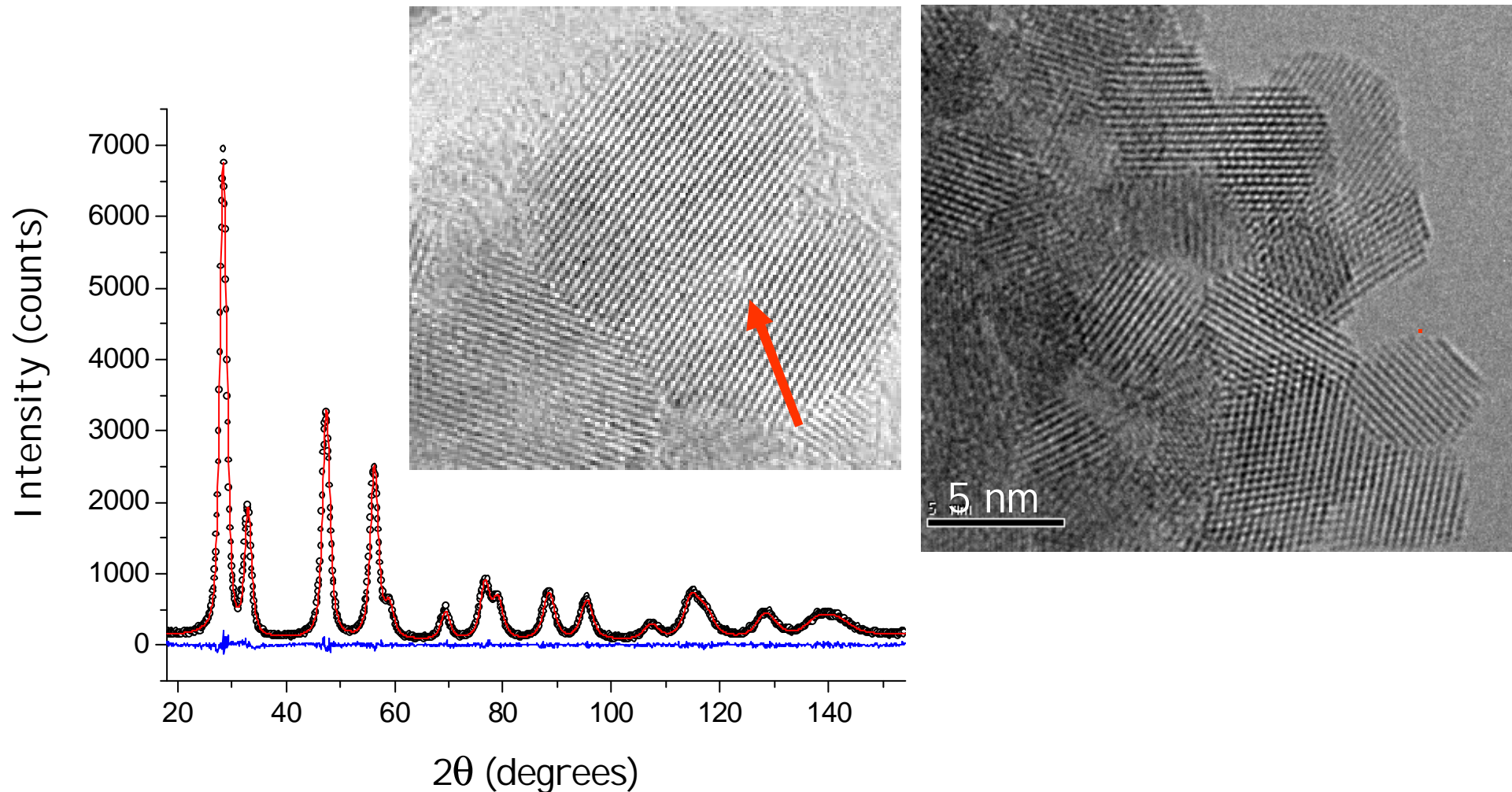


WPPM application: nanocrystalline ceria



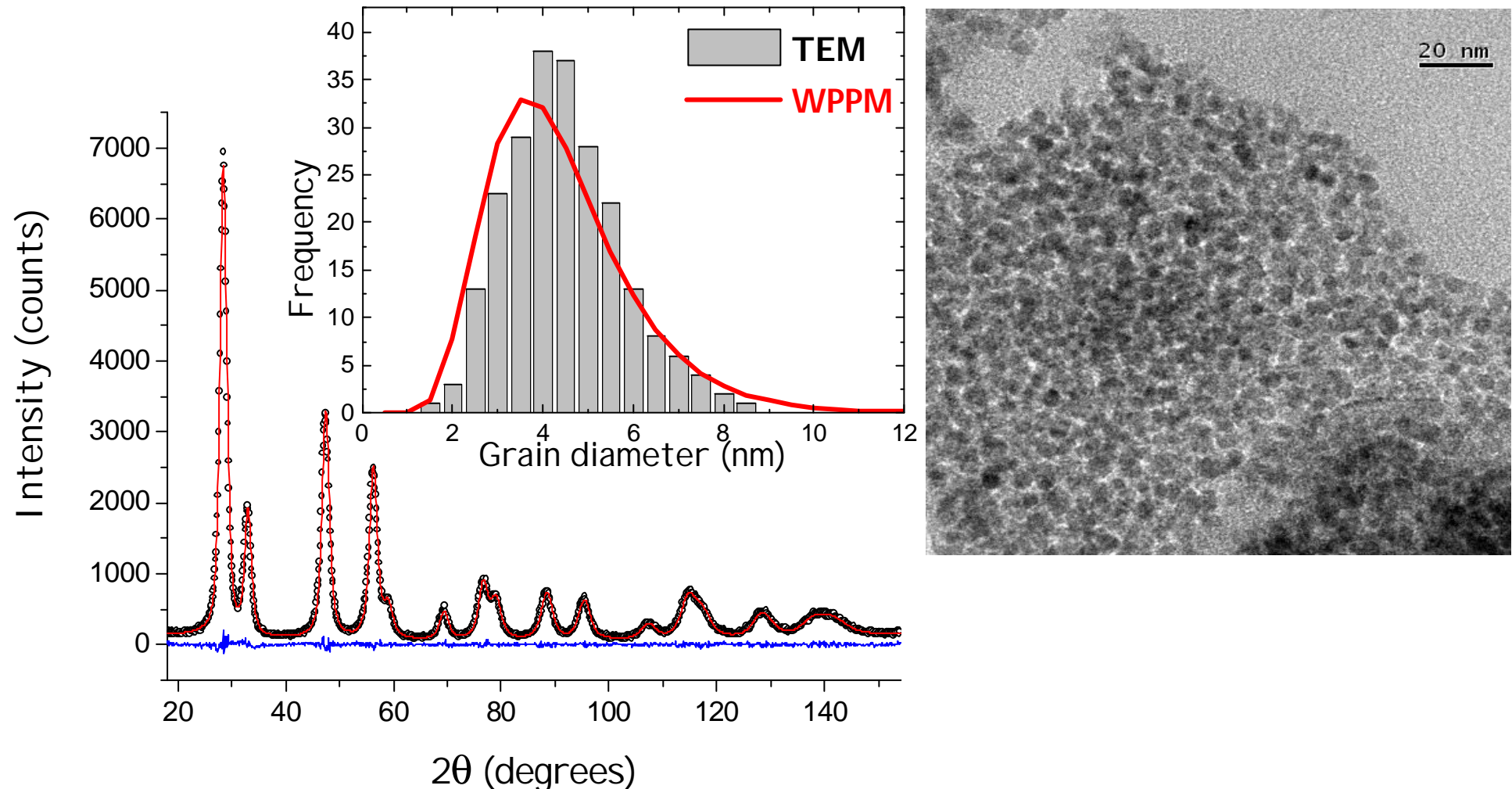
WPPM application: nanocrystalline ceria

Nanocrystalline cerium oxide from sol-gel route



WPPM application: nanocrystalline ceria

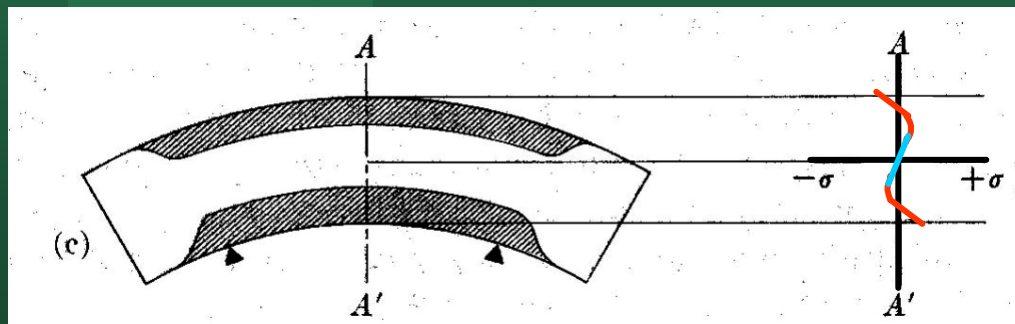
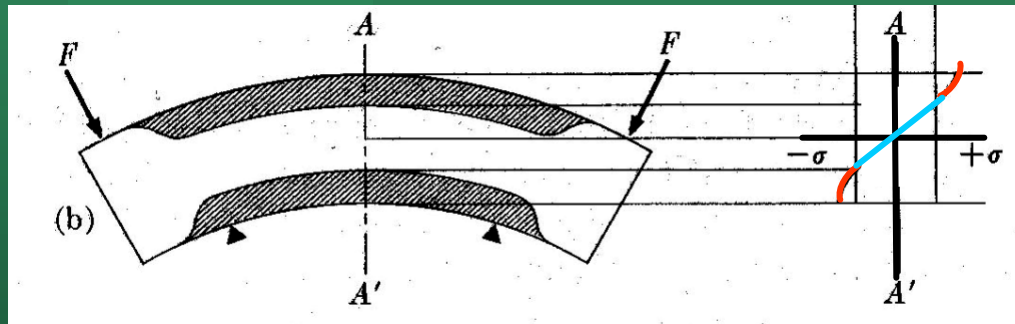
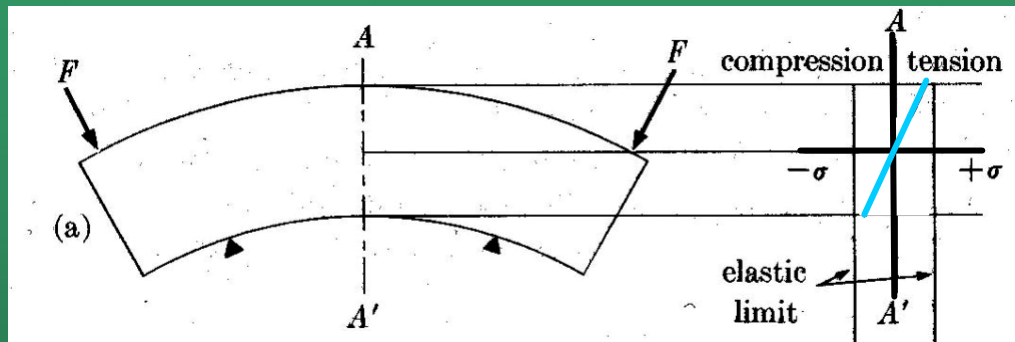
Nanocrystalline cerium oxide from sol-gel route



Residual stress analysis

Residual stresses

Why residual stresses?



Residual stress by plastic flow in bending:

(a) loaded **below** elastic limit

(b) loaded **above** elastic limit

(c) unloaded

Shaded regions have been plastically deformed

Source: B.D. Cullity "Elements of X-ray diffraction" II Edition. Addison-Wesley. Reading (1978)

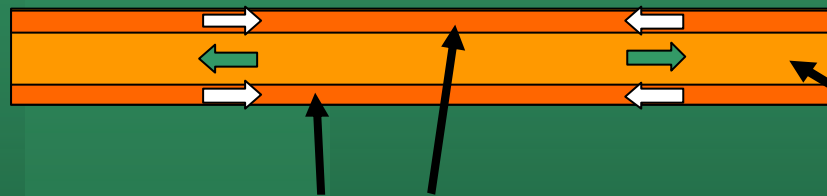


Residual stress

Tempered glass

glass sheet

rapid cooling



Surface under compression



Core under tension

The cold surface is drawn into compression by the core ("trapped" and slowly cooling)

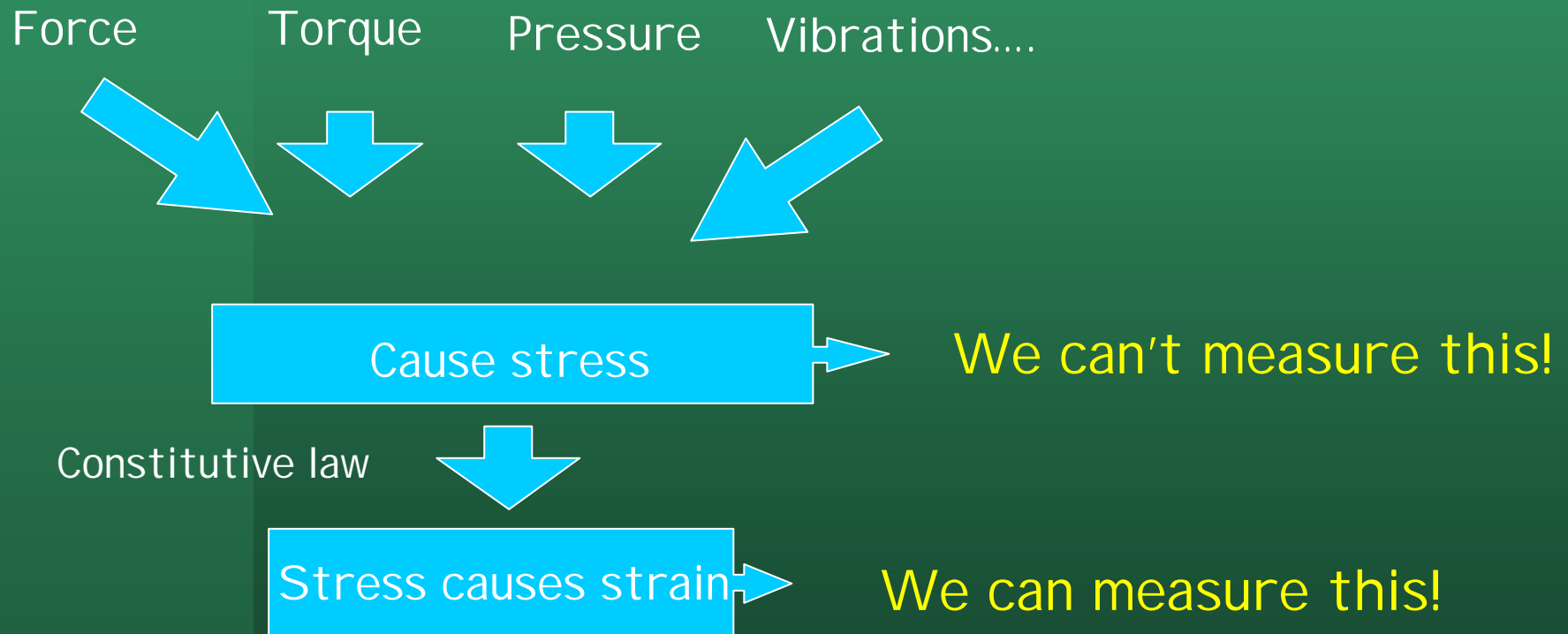
Stress is present without external load

Residual stresses induced by tempering contributes to enhance the resistance of glass to cracking



Load - stress - strain

In most cases we cannot measure stress directly (unless we are in simple cases where a known force is applied to a known surface area). How we can solve the problem?



Residual stress analysis

Crystalline domains can be used as strain gauges

grain deformation

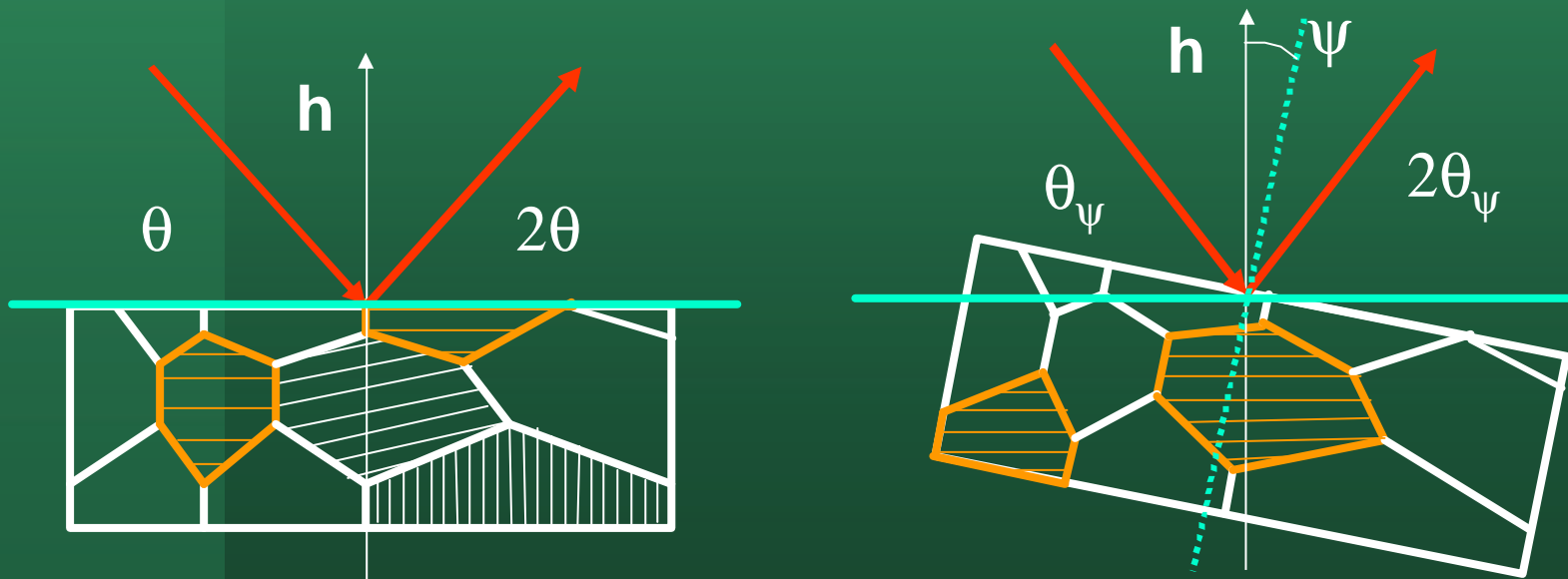
$$e = \frac{\Delta l}{l}$$



lattice deformation

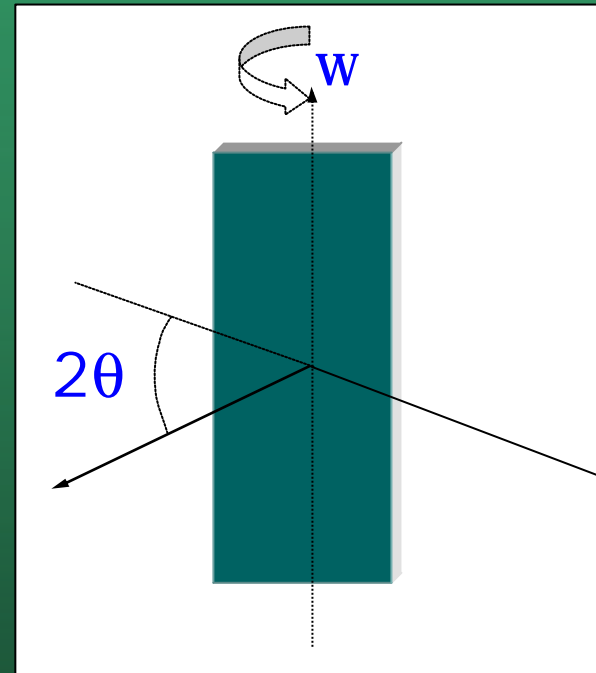
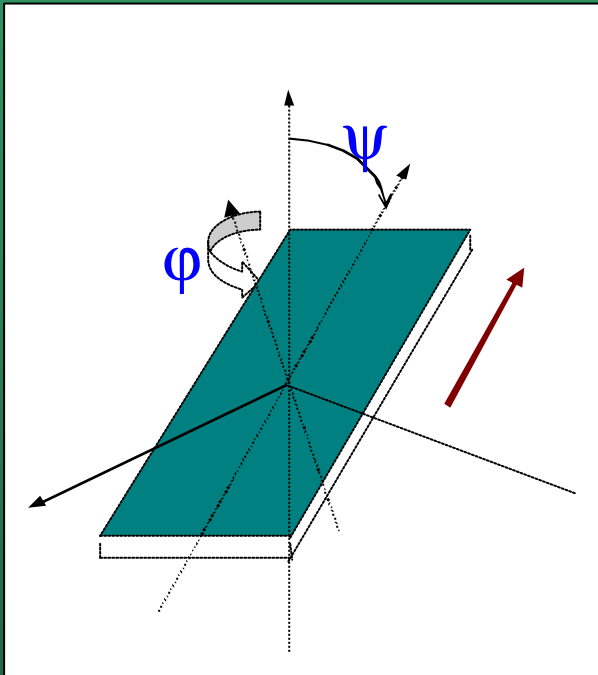
$$e = \frac{\Delta d}{d}$$

The deformation is measured along different directions, by tilting the sample. The in-plane strain is obtained by measuring d along off-plane directions.



Measurement principle

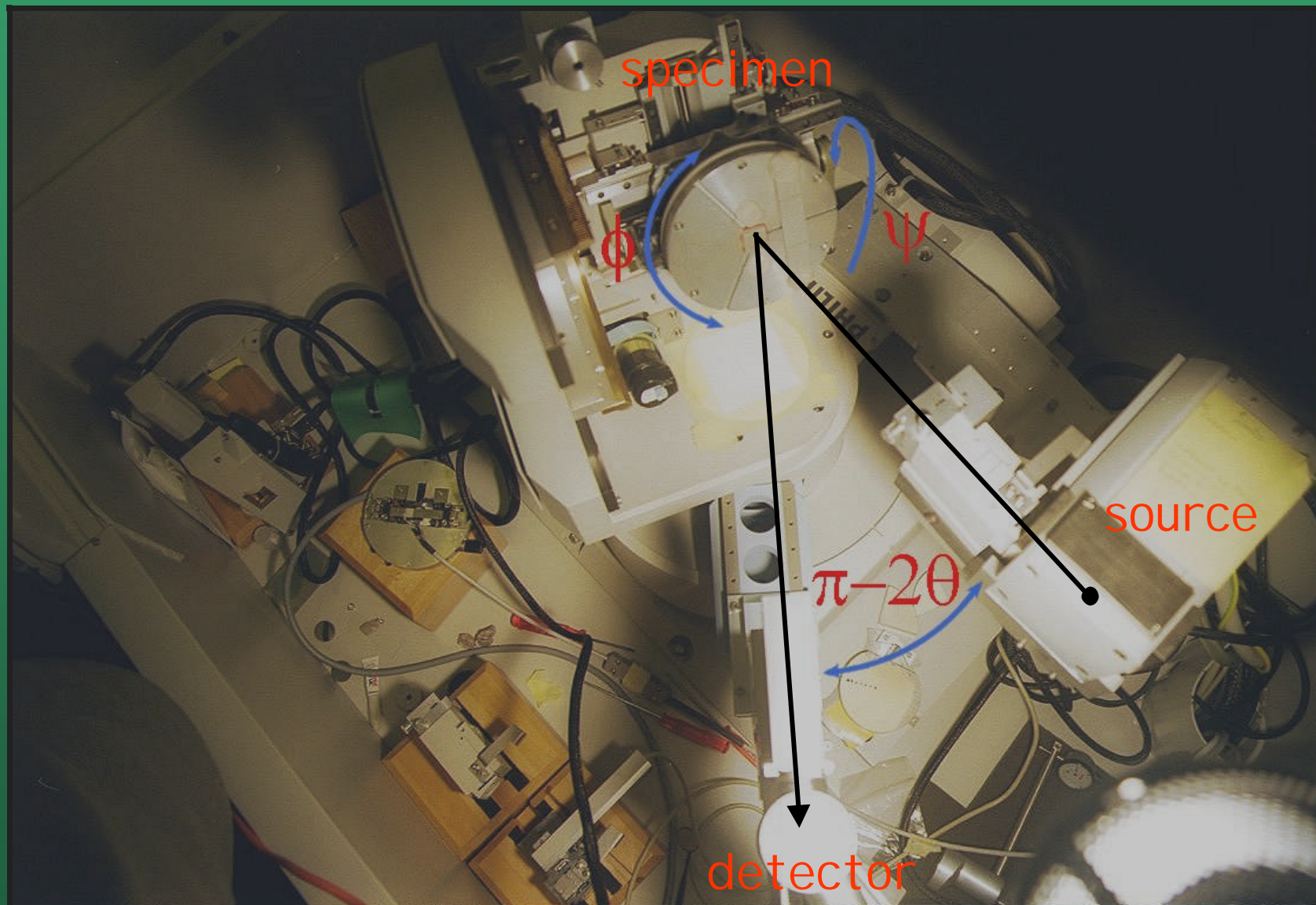
We need therefore additional movements for the specimen, with respect to the traditional Bragg-Brentano setup



The sample should be tilted/rotated along its three axes.



XRSA diffractometer



Residual stress analysis

If the stress field is plane and rotationally symmetric:

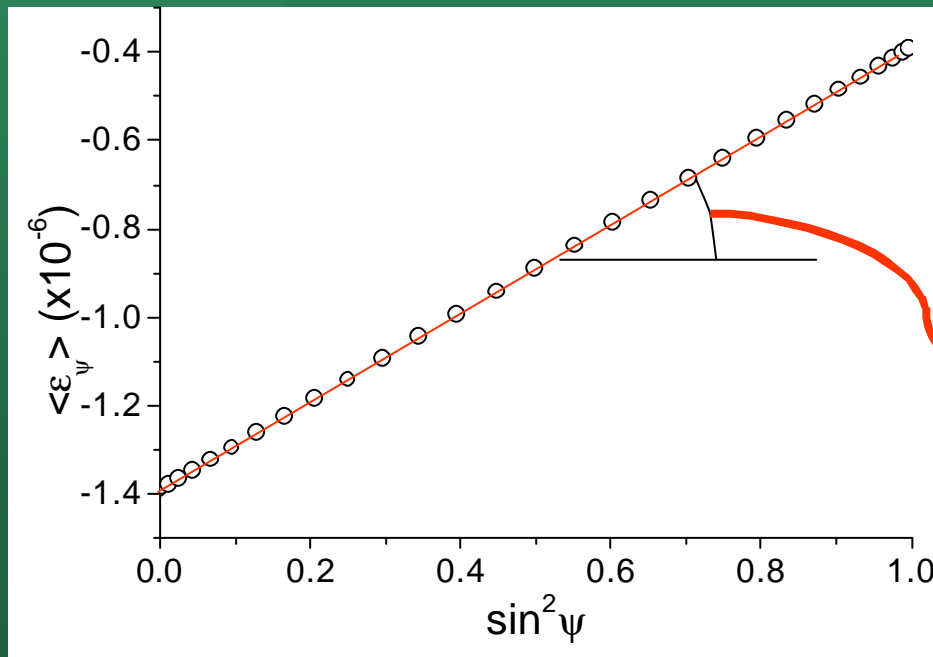
$$\sigma_{11} = \sigma_{22} = \sigma_{\parallel}, \quad \sigma_{12} = \sigma_{13} = \sigma_{23} = \sigma_{33} = 0$$



and if no gradient and no texture are present, then:

$$\langle \mathbf{e}_y^{hkl} \rangle = \left(2S_1^{hkl} + \frac{1}{2}S_2^{hkl} \sin^2 \psi \right) \mathbf{s}_{\parallel}^S$$

"sin²ψ formula"



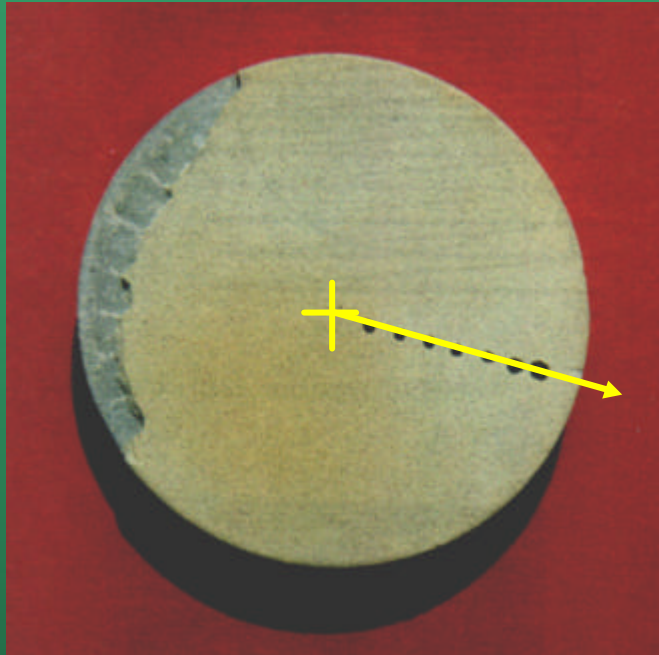
$$S_1^{hkl}, \frac{1}{2}S_2^{hkl}$$

X-ray elastic constants (XECs)

slope related to the average *in-plane* stress

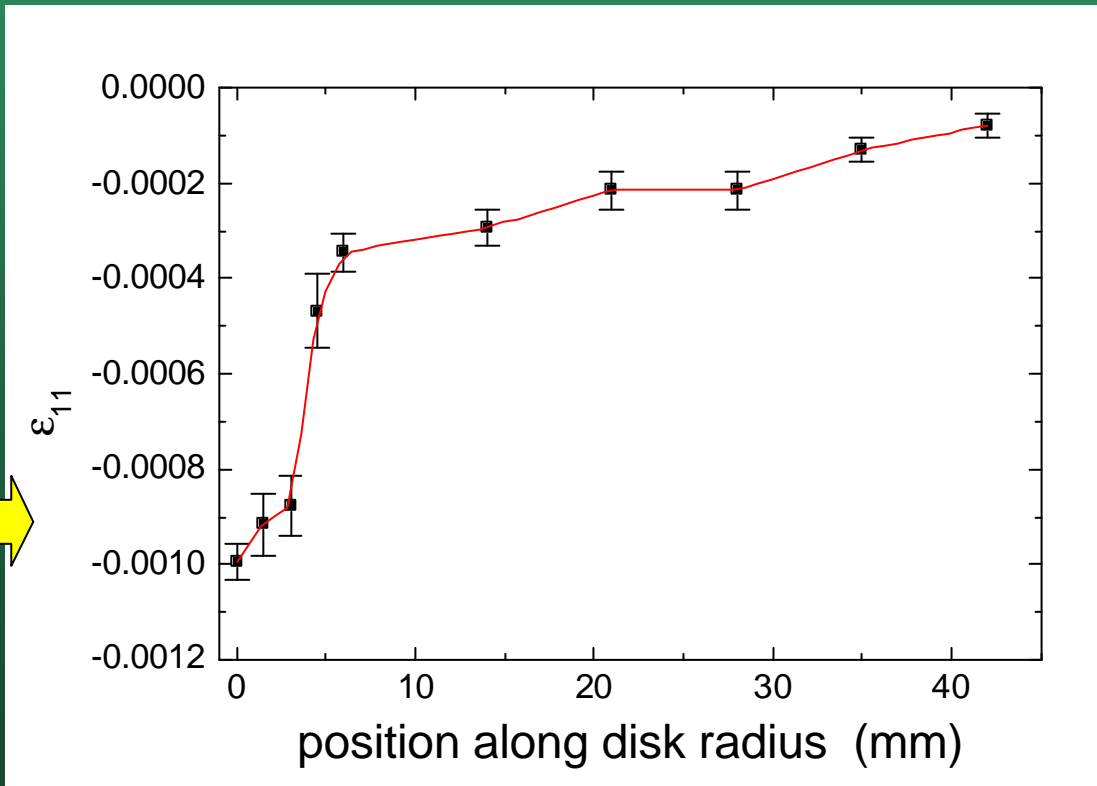


Coated piston head



After the burner rig test the component failed starting from the rim.
How does failure occur?

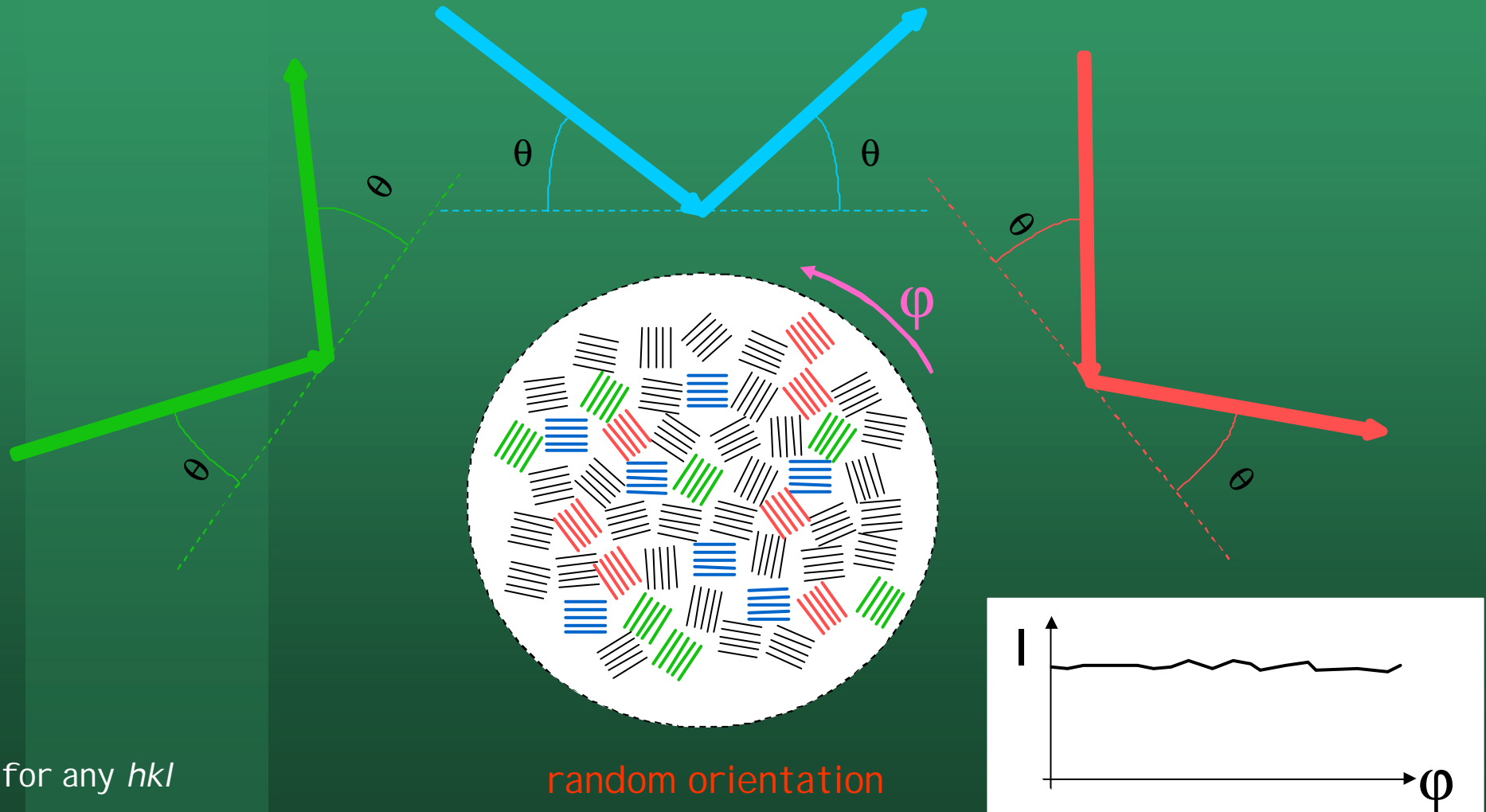
measurement conducted along the yellow line on a laboratory diffractometer



Texture analysis

Crystallographic texture

A 'true' powder has randomly oriented crystalline domains.
The diffracted intensity does not depend on the probing direction.



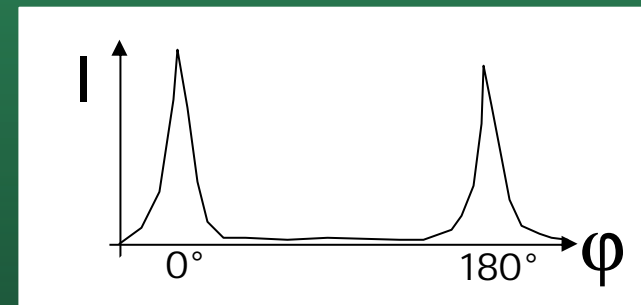
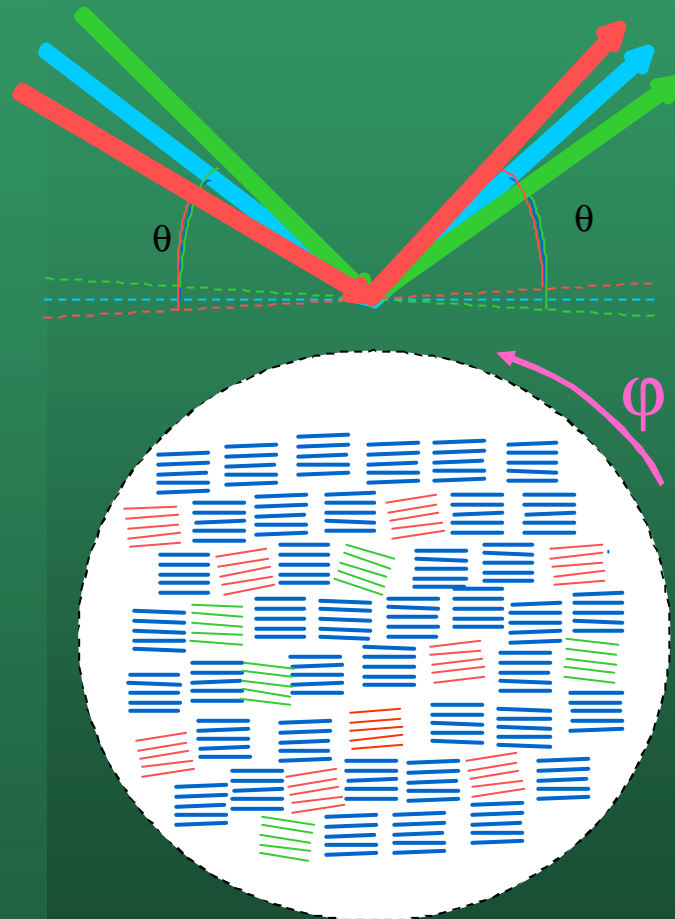
for any hkl

random orientation



Crystallographic texture

If crystalline orientation is not random, the diffracted signal depends on the incident angle.

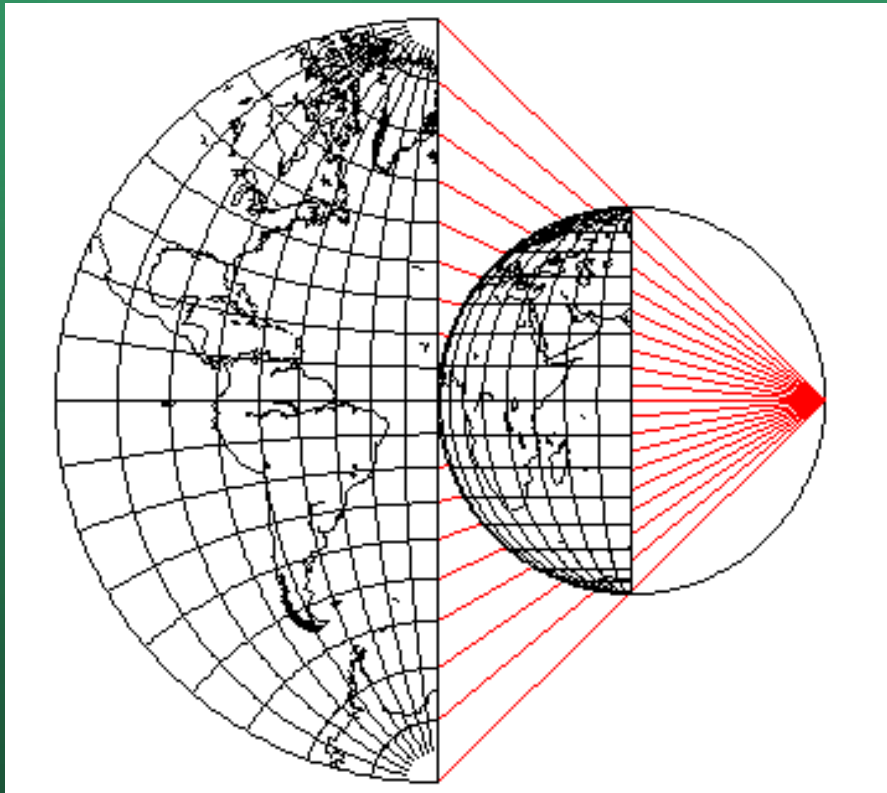


preferred orientation

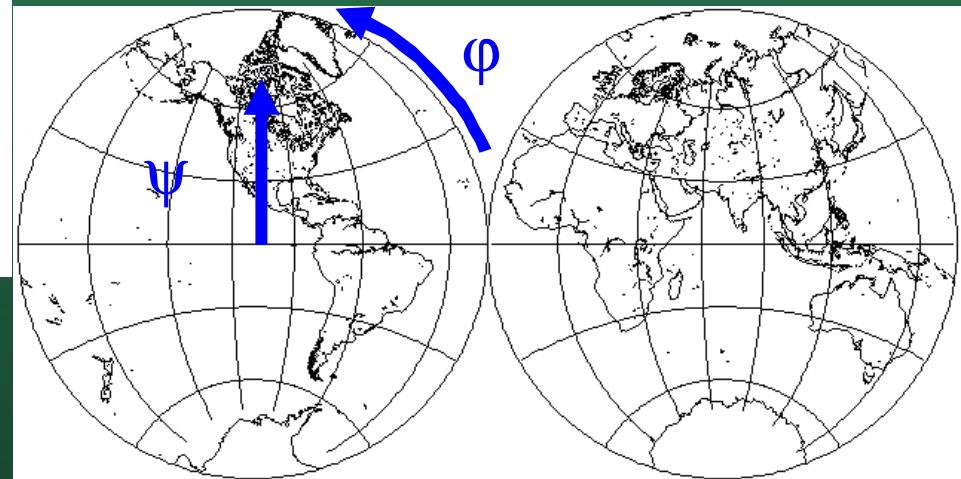


Stereographic projection: old cartography

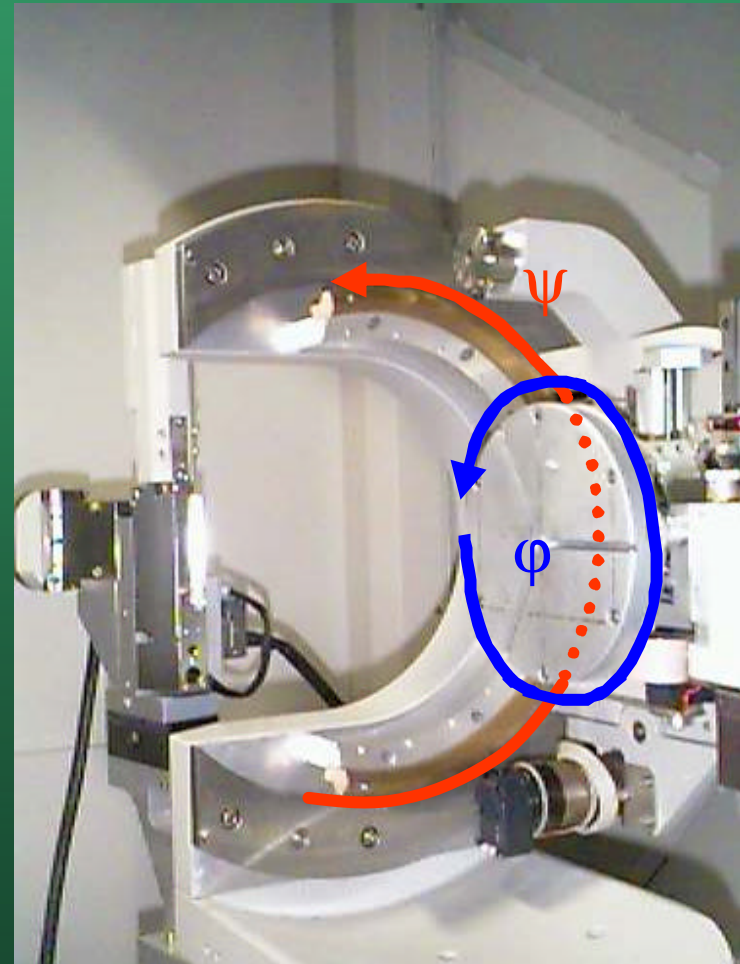
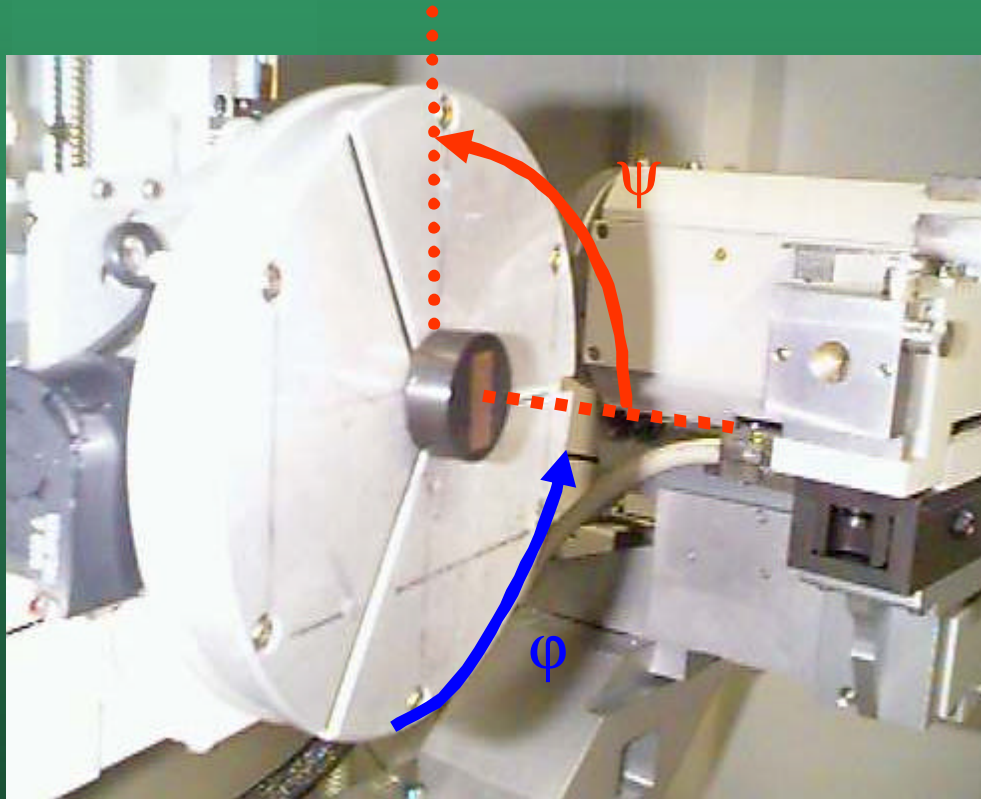
The information can be reported on suitable maps: pole figures.
The stereographic projection is adopted



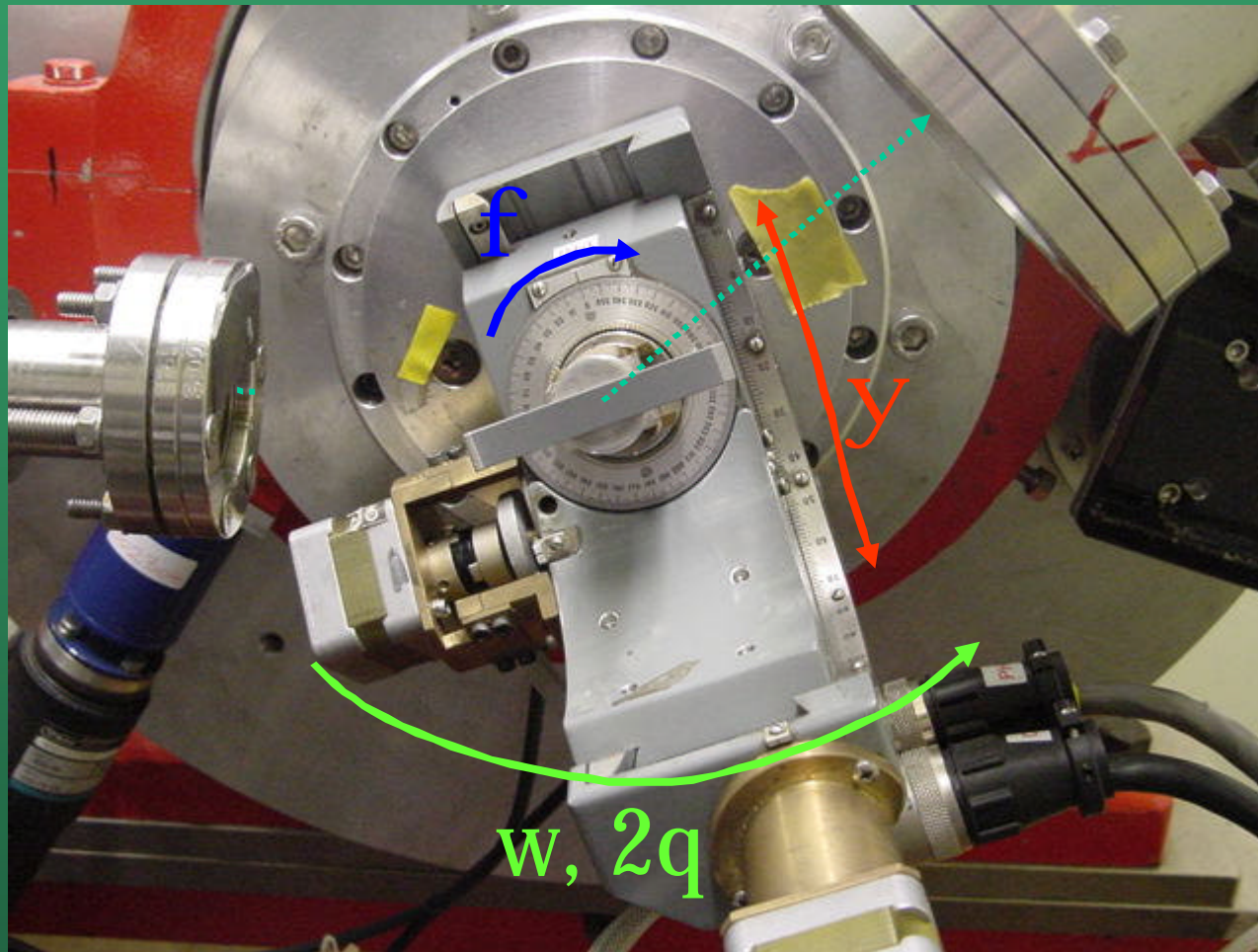
Two angles are used in the projection



Laboratory instrument: PANalytical X'Pert MRD



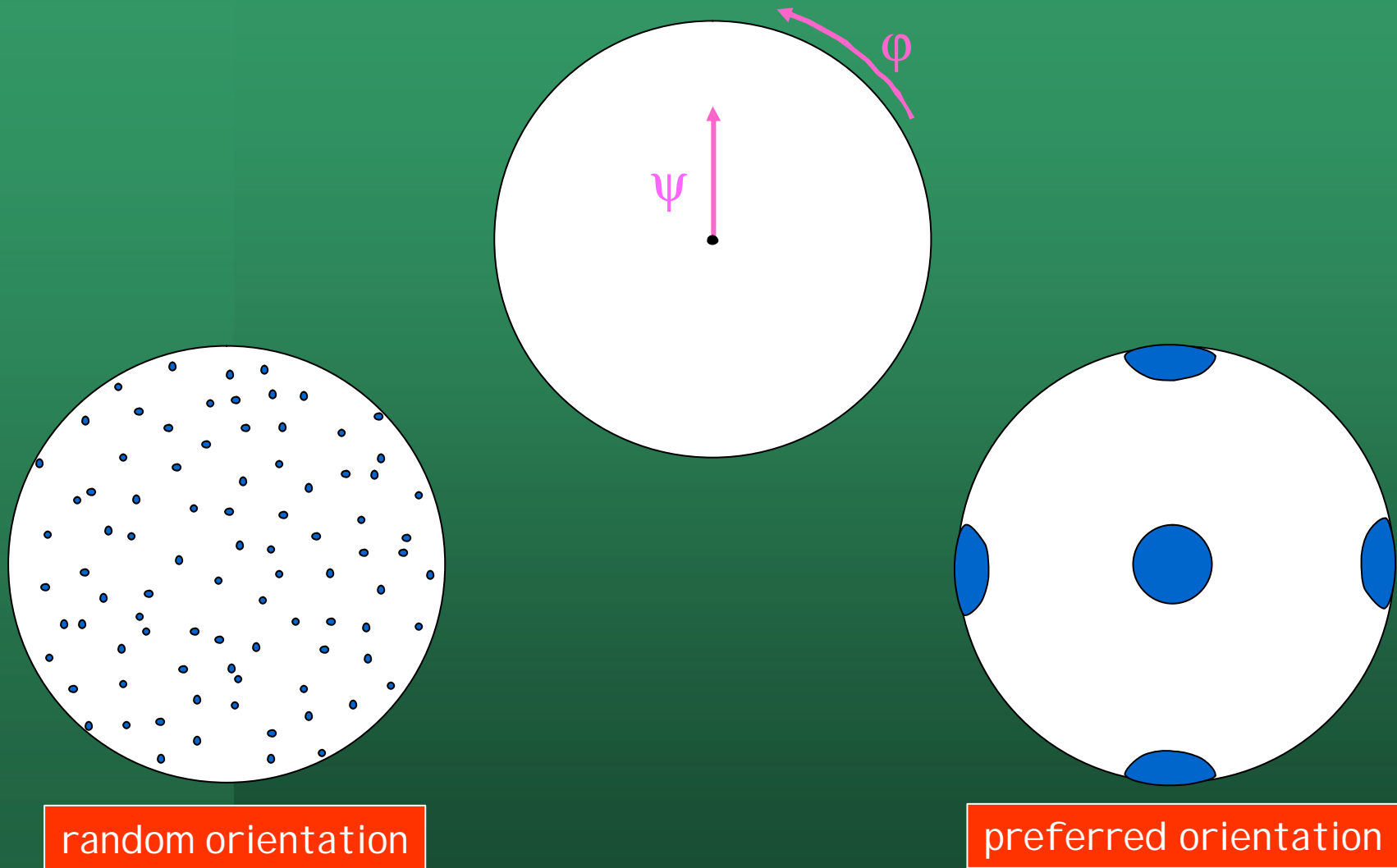
Synchrotron instrument: SRS station 2.3



Eulerian cradle for stress/texture measurement

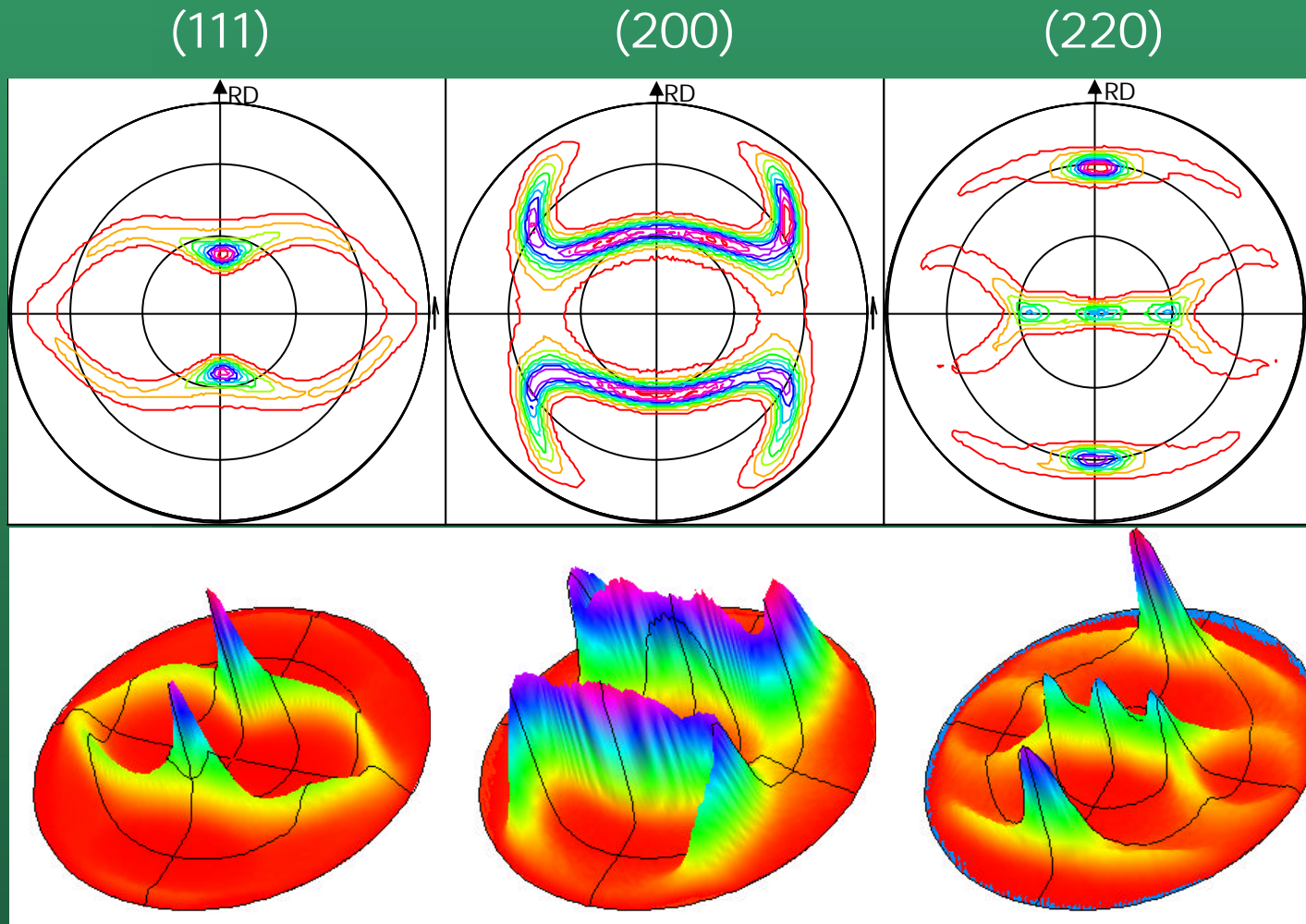


Crystallographic texture: pole figures



Crystallographic texture: pole figures

In general, texture can be quite complex. Several pole figures, for different (hkl), may be required to understand the orientation

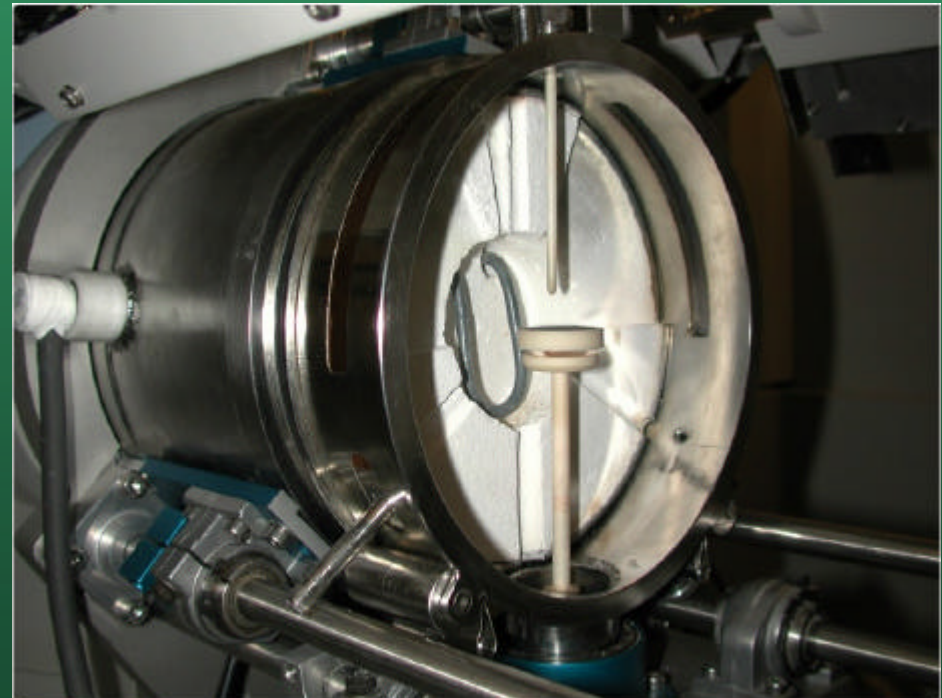


High temperature studies

Laboratory equipment



(a)

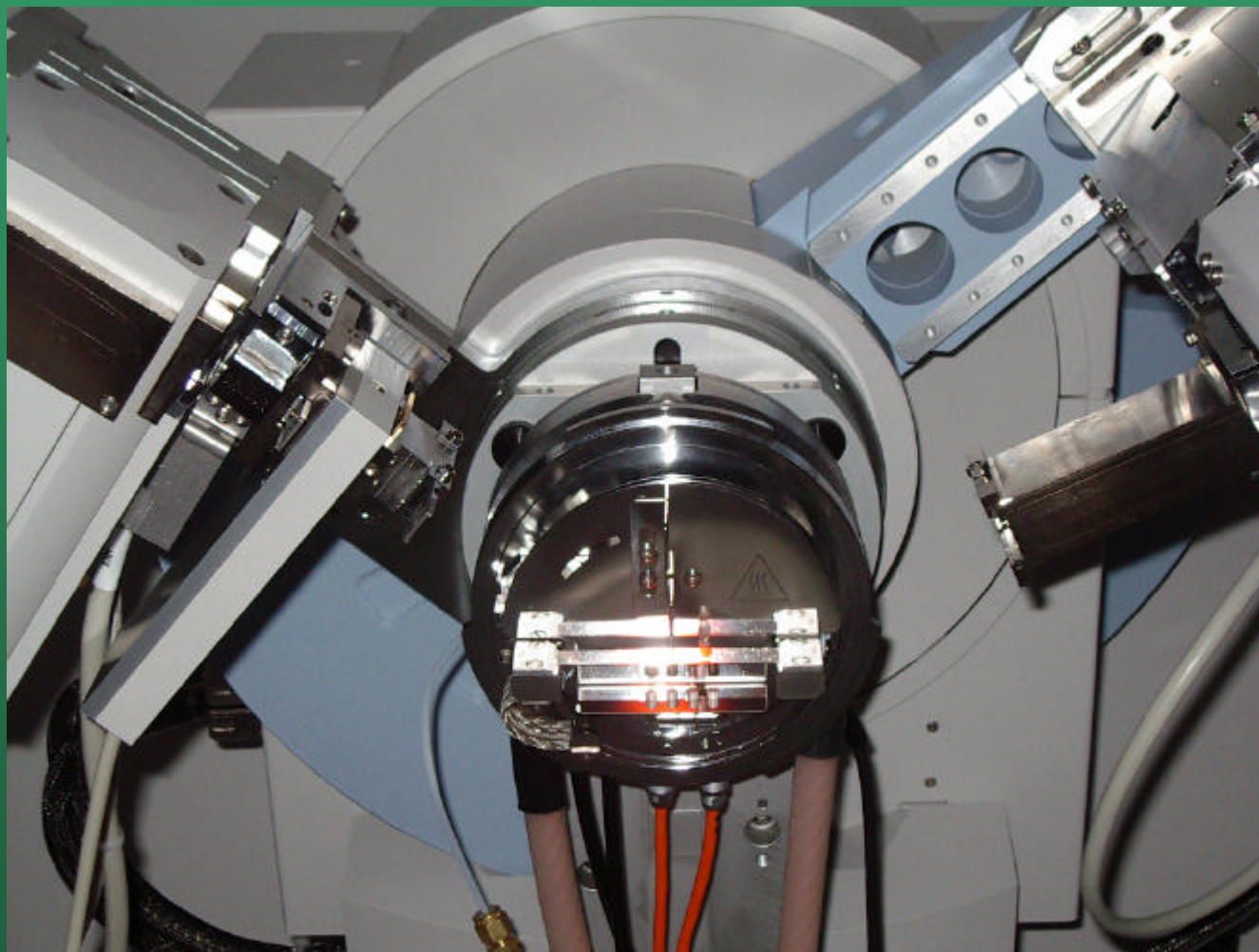


(b)

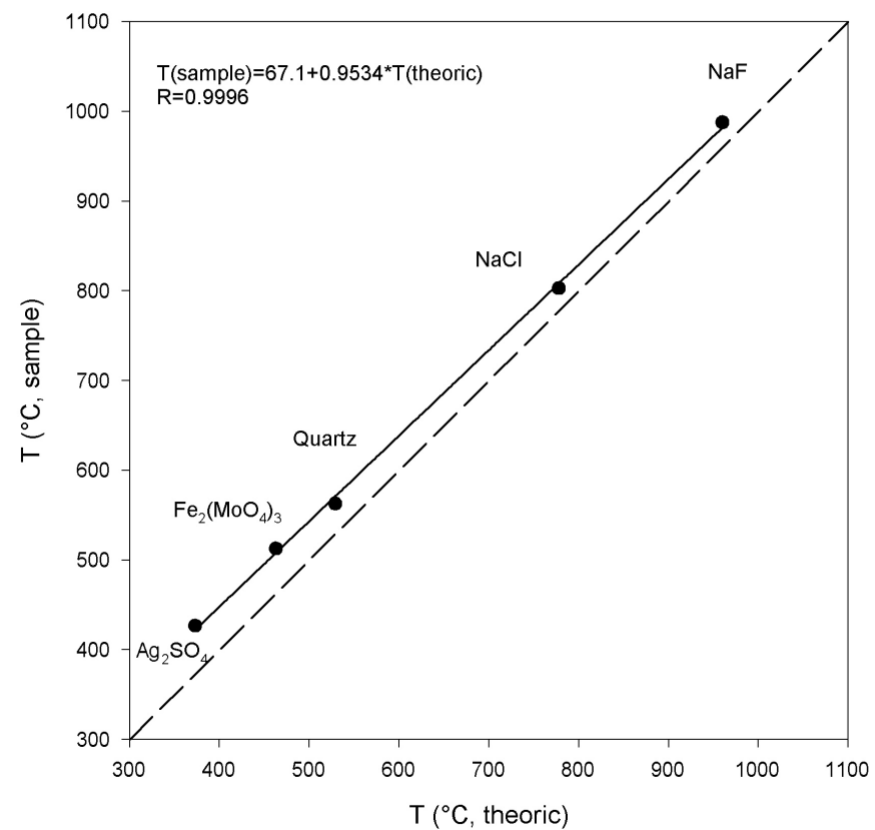
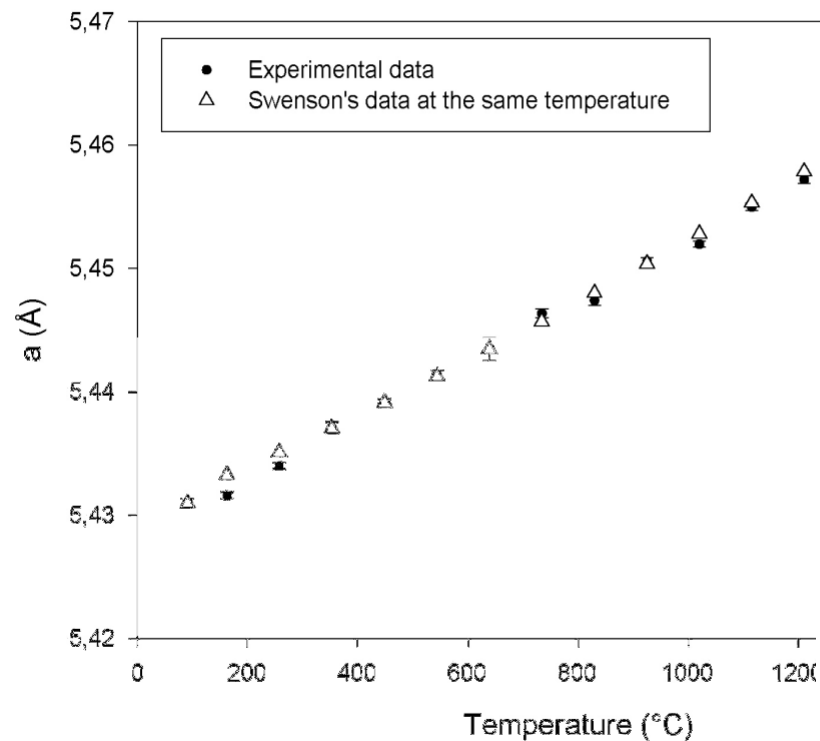


High temperature diffractometer setup

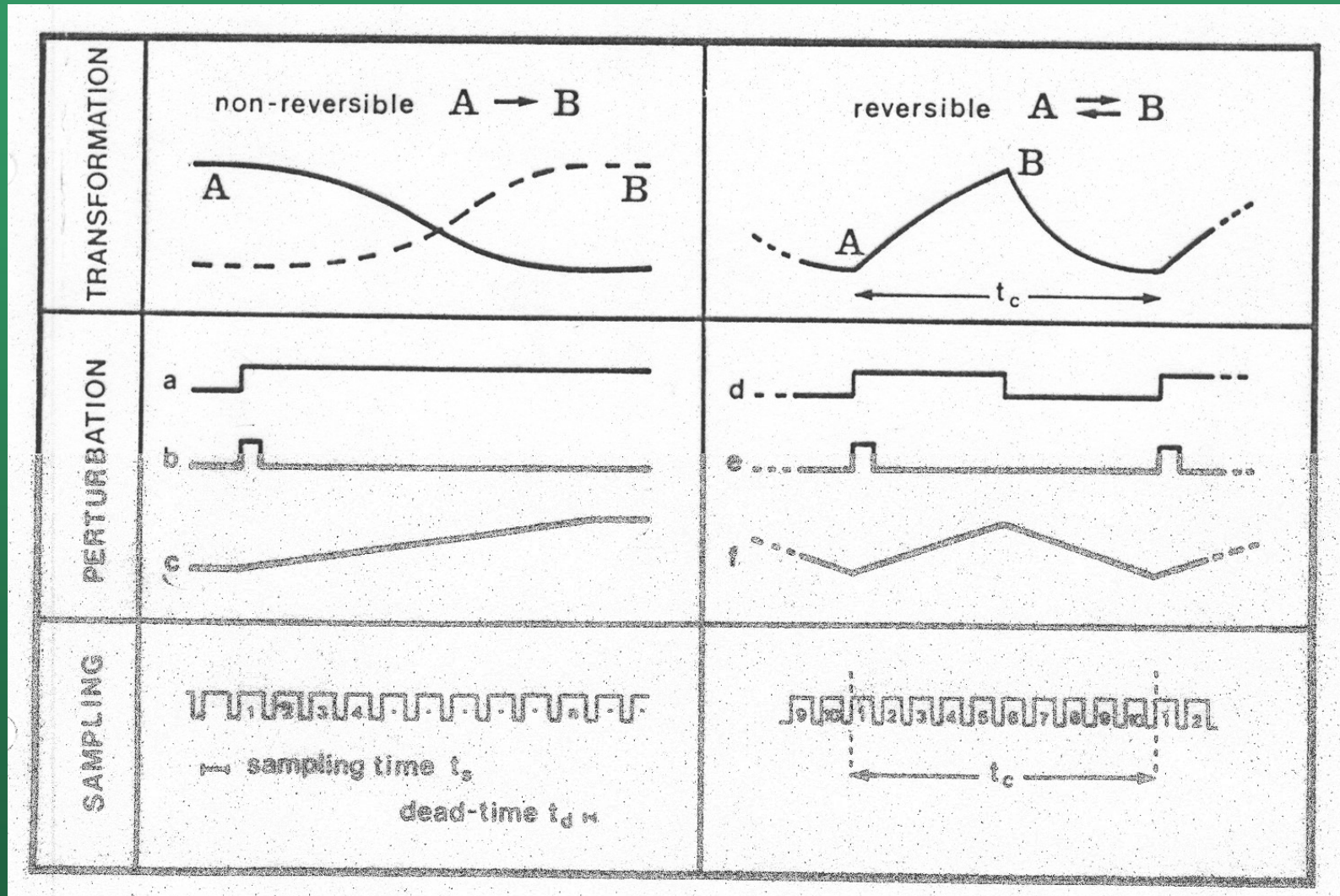
Laboratory instrument with strip heater



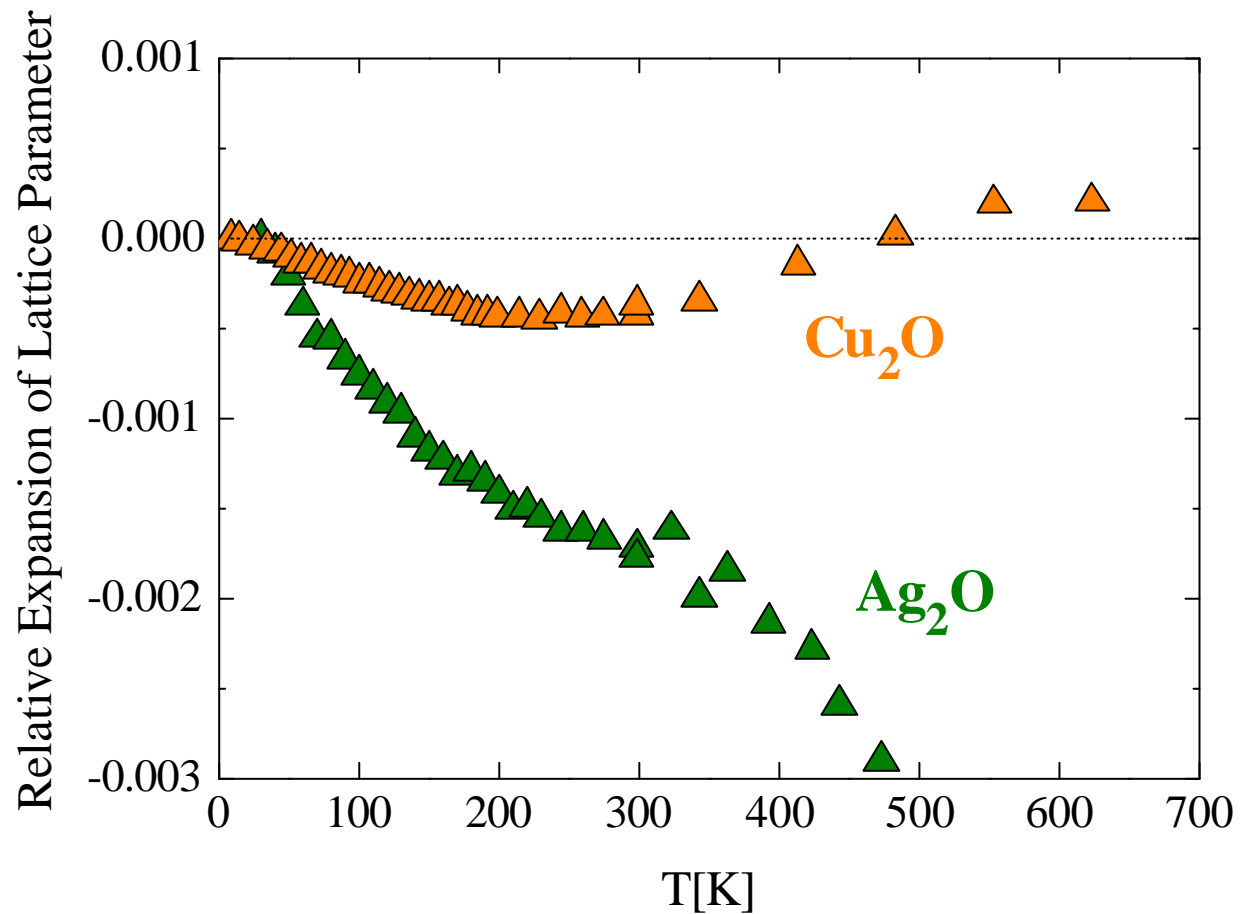
Temperature calibration



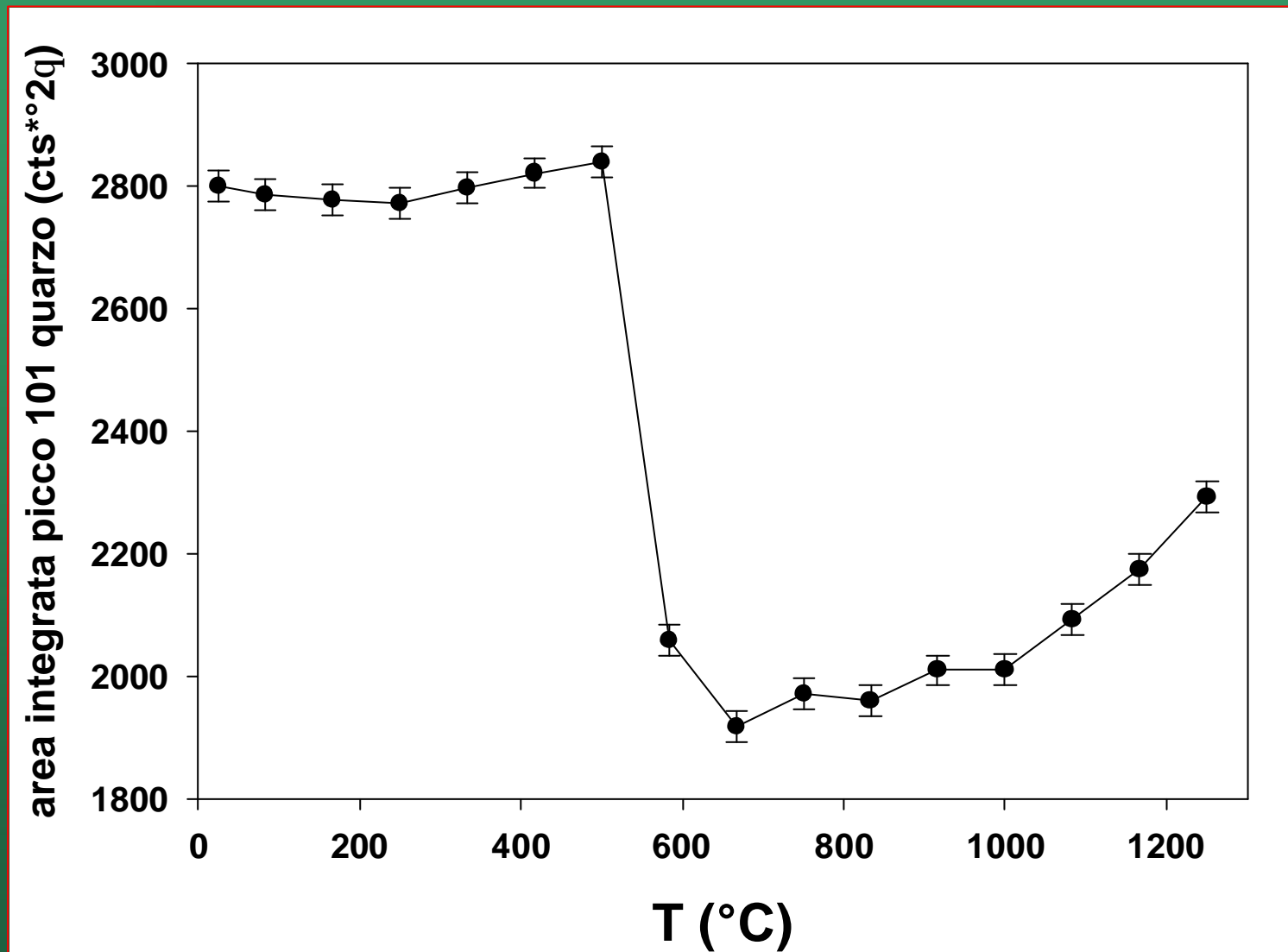
Possible studies



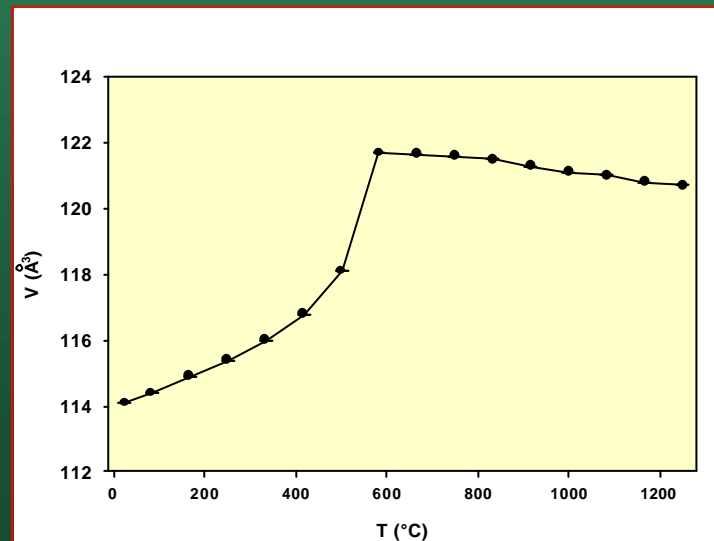
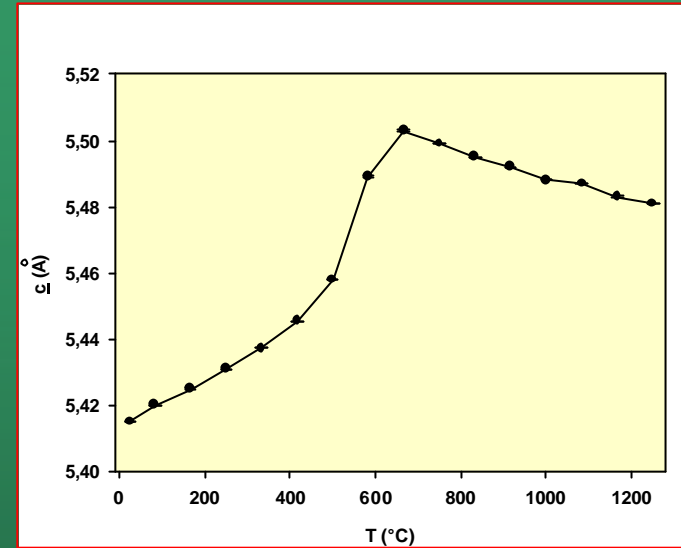
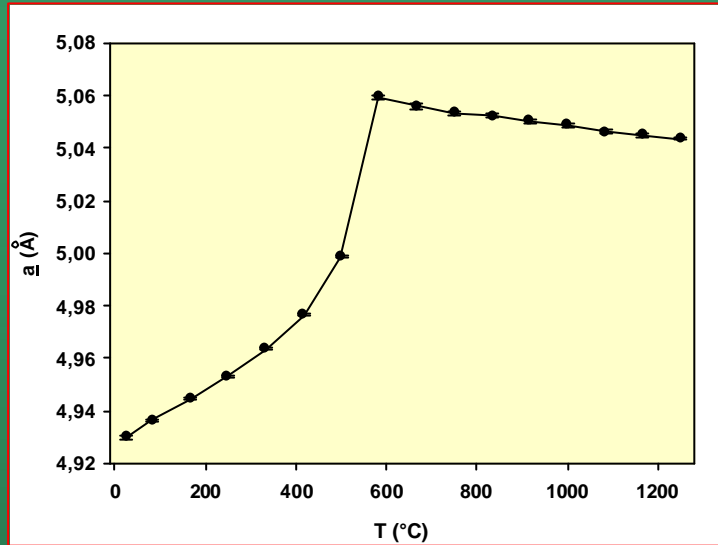
Unusual thermal expansion data



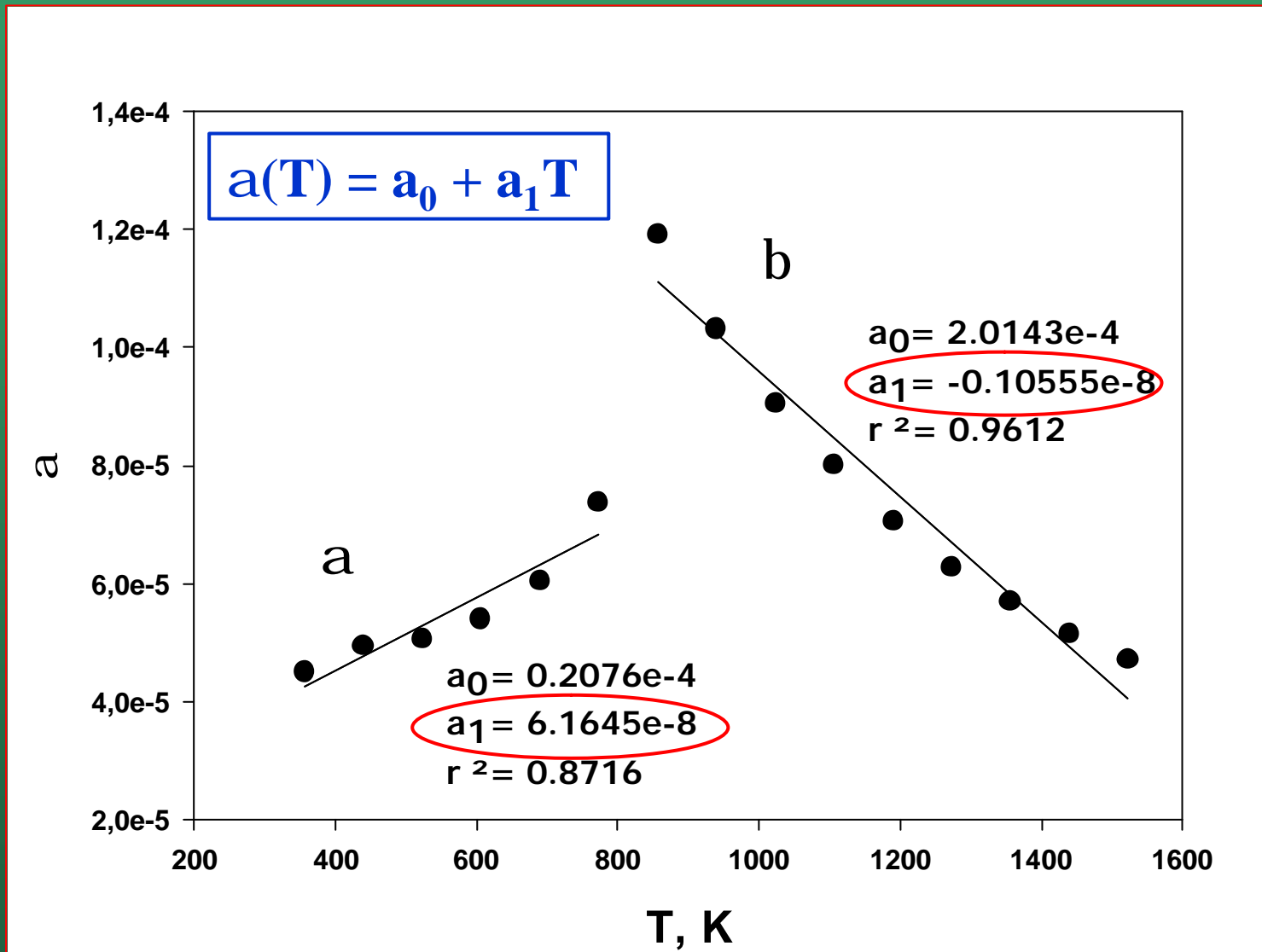
Transformation of quartz



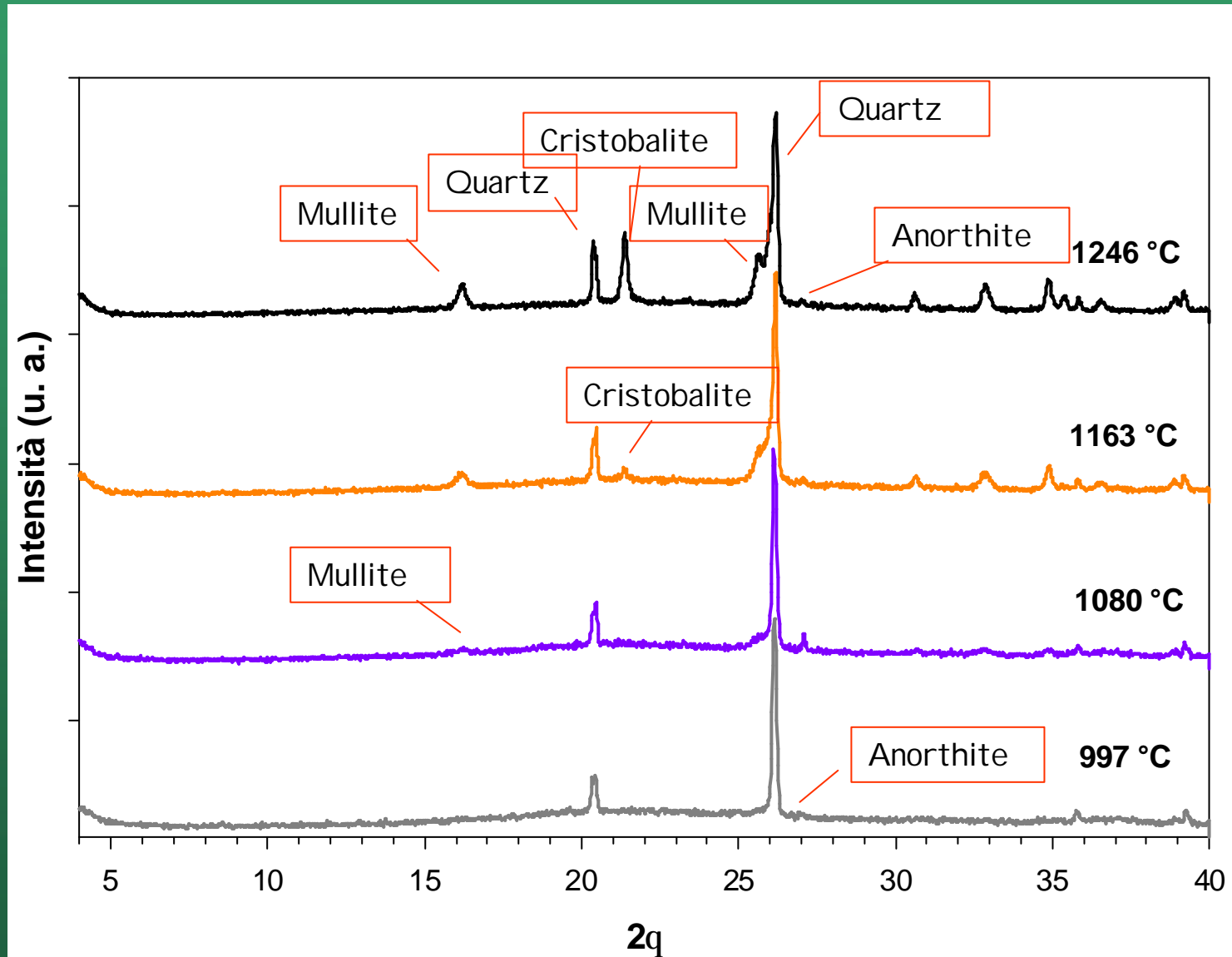
Transformation of quartz



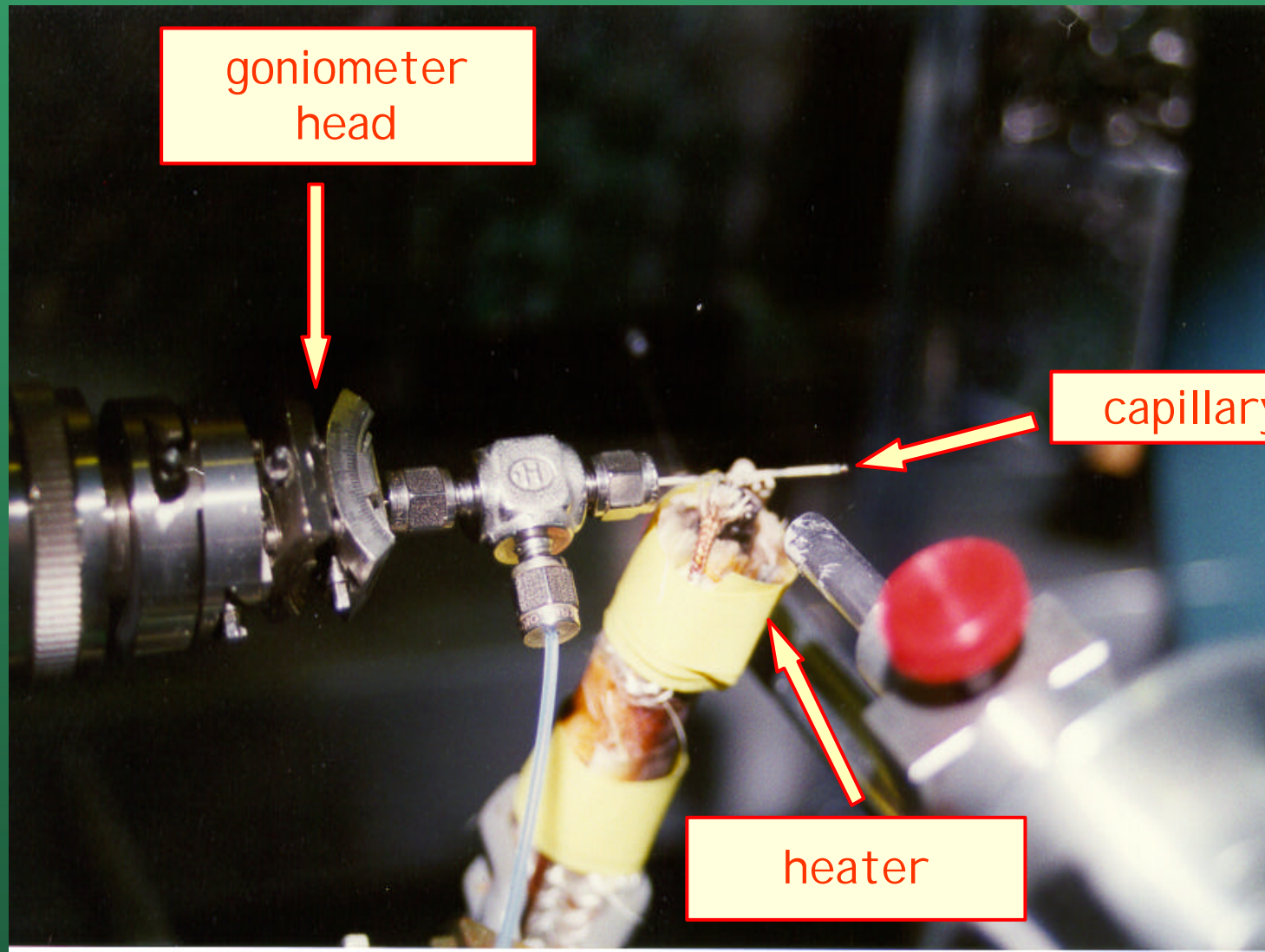
Thermal expansion of α and β quartz



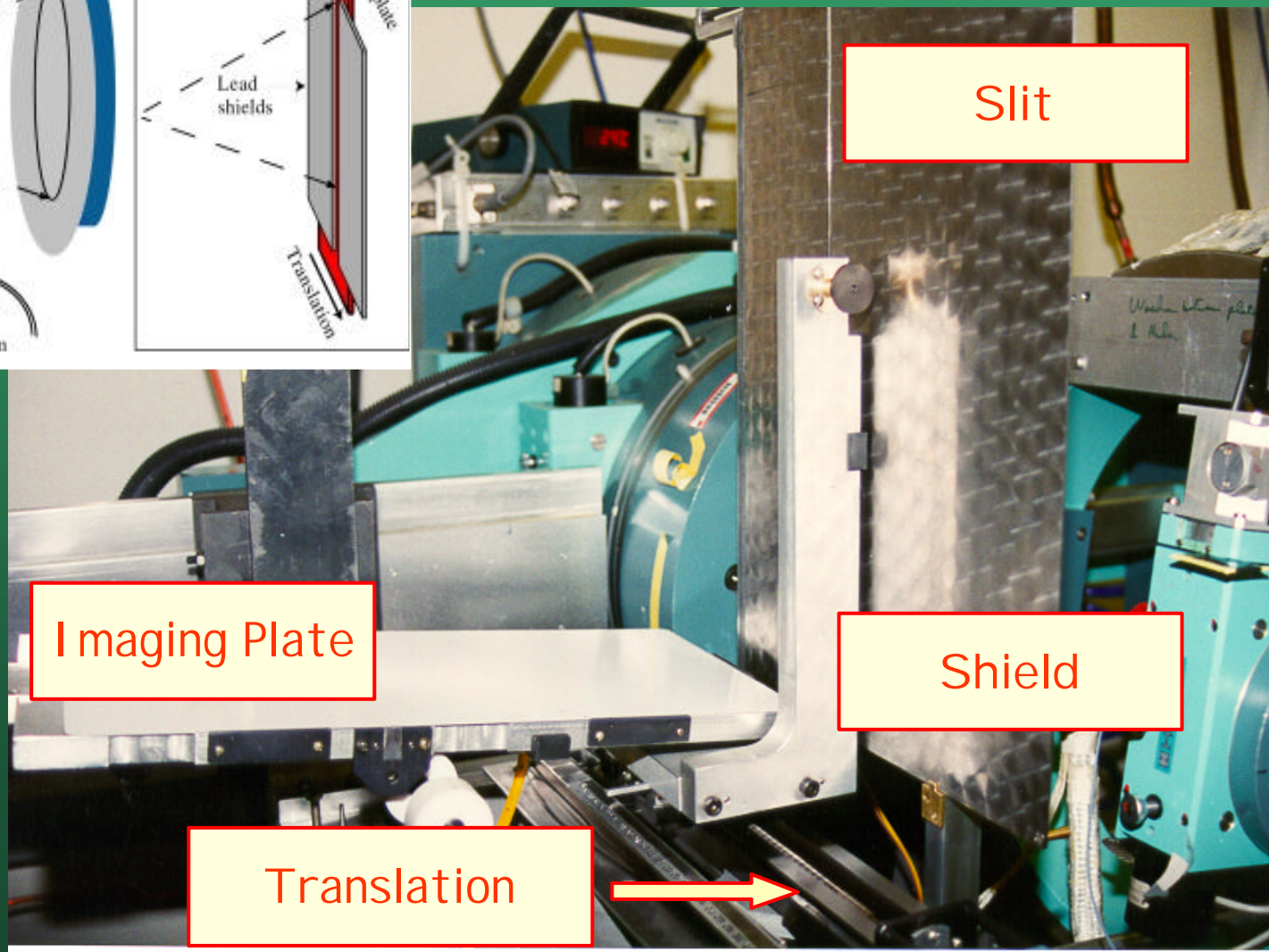
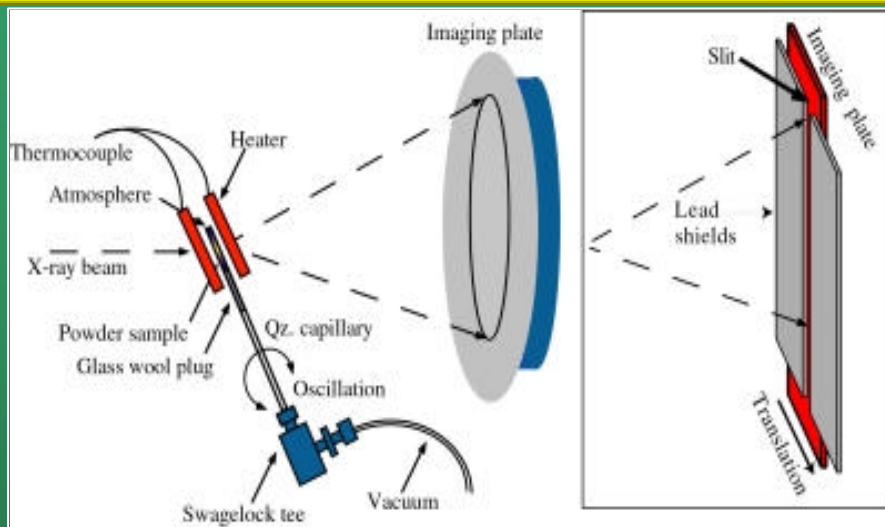
High temperature illite decomposition



Synchrotron case: specimen heating setup



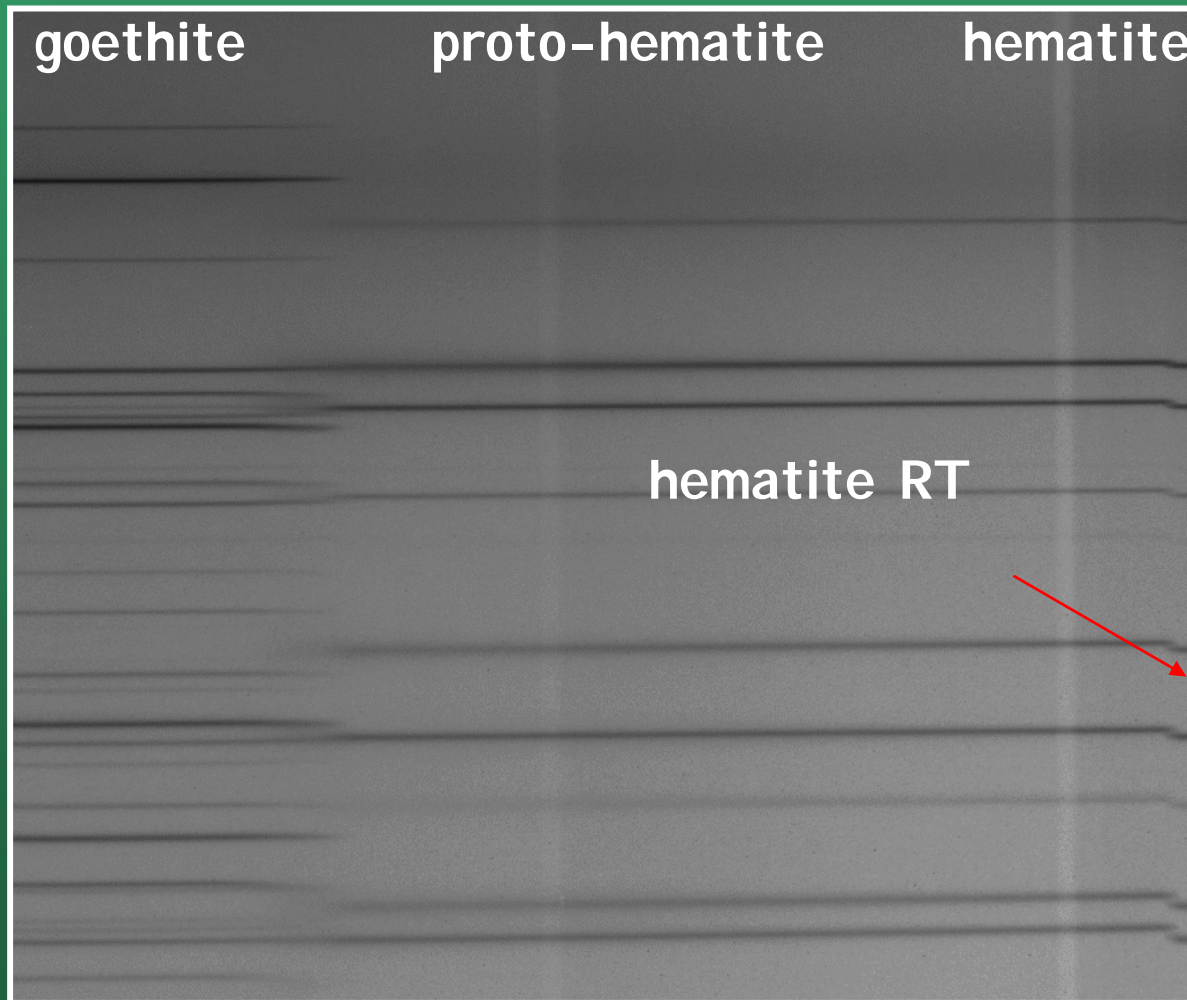
Measurement setup



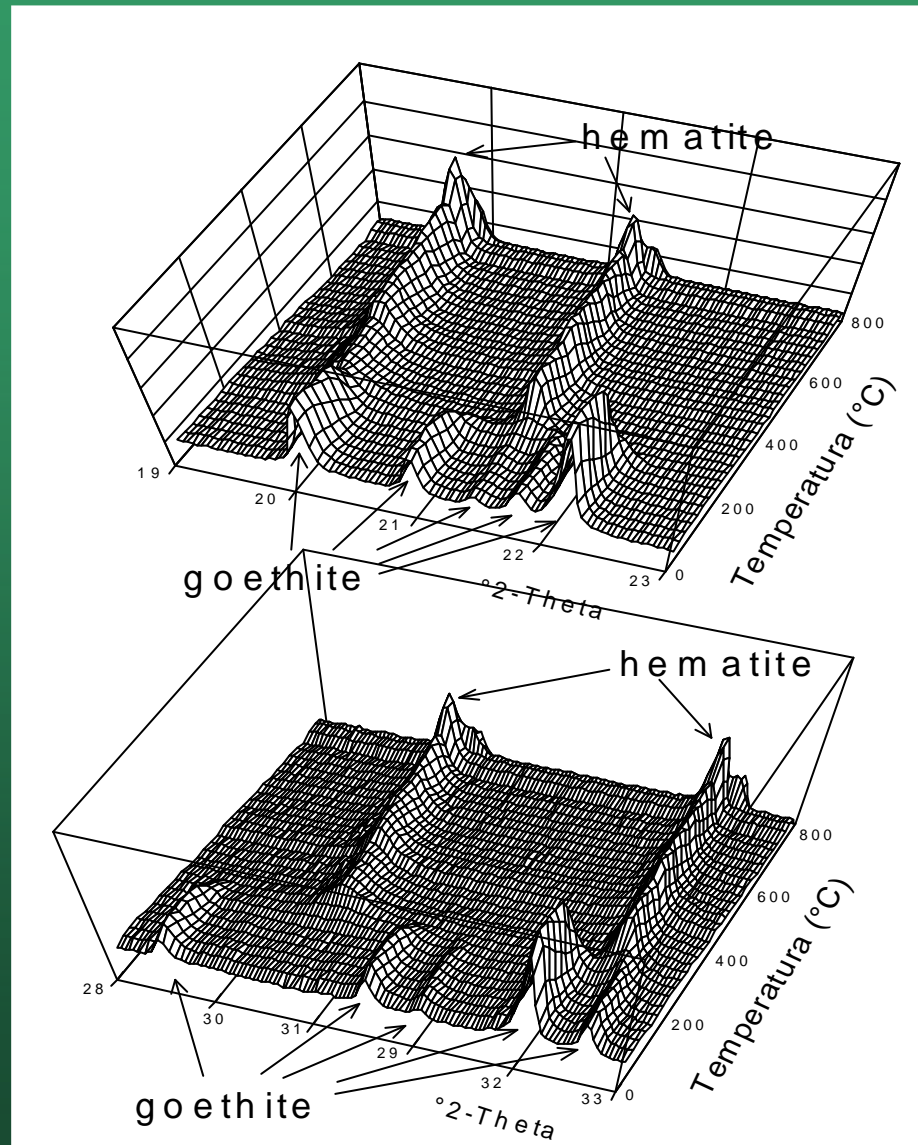
Example: transformation of FeOOH

Temperature increase →

← Image Plate translation



Data after readout



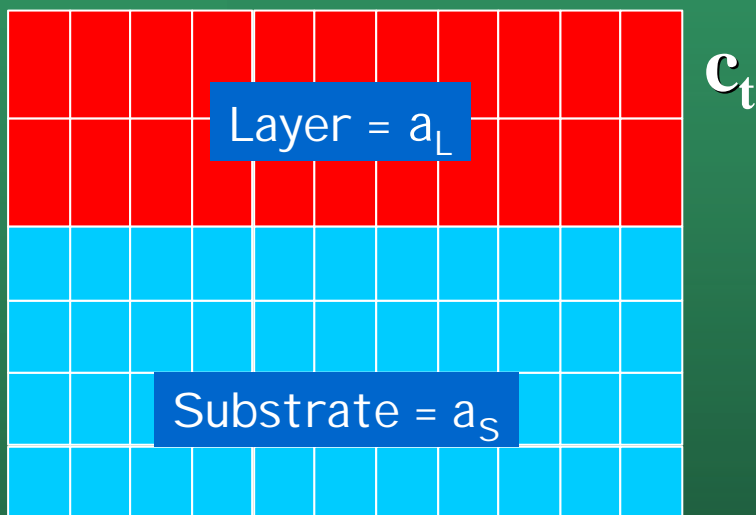
Thin film analysis

Growing a film: lattice mismatch

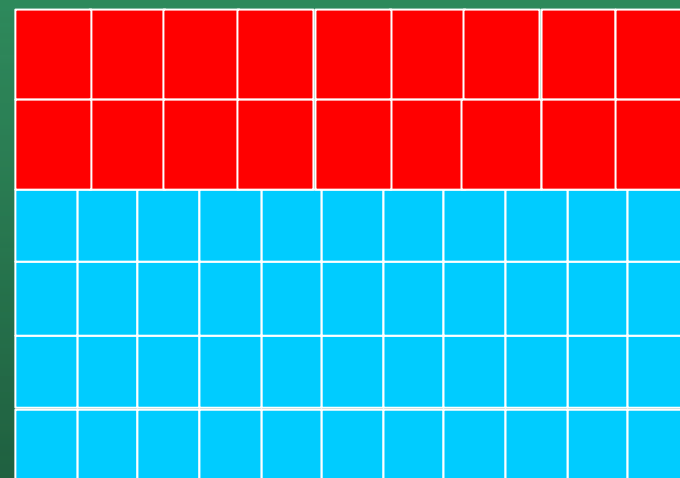
$$c_t > a_L$$
$$a_t = a_S$$

mismatch

$$m = \frac{(a_L - a_S)}{a_S}$$



Strained layer



Relaxed layer



Types of thin films

Pseudomorphic epitaxial layers. "No" defects. Strain may be present

Example : AlGaAs/GaAs, SiGe/Si
Applications: Lasers, High-frequency IC's

Lattice mismatched epitaxial layers. Layers are partly (or fully) relaxed

Example: ZnSe/GaAs, InAsSb/GaSb
Applications: Blue LED's, IR optoelectronic

Layers with large lattice mismatch and/or dissimilar crystal structures

Example: GaN/Sapphire, YBaCuO/SrTiO₃, BST, PZT
Applications: Blue Lasers and LED's, High T_c Superconductors, Ferro electrics

Layers where the epitaxial relationship is weak. Highly textured

Example: AuCo multilayers on Si
Applications: Thin film media, heads



XRD for thin films and layers

Reflectivity Measurements

- Thickness, Density, Surface Roughness
- Lateral and Depth Correlation
- Curvature

In-plane Scattering

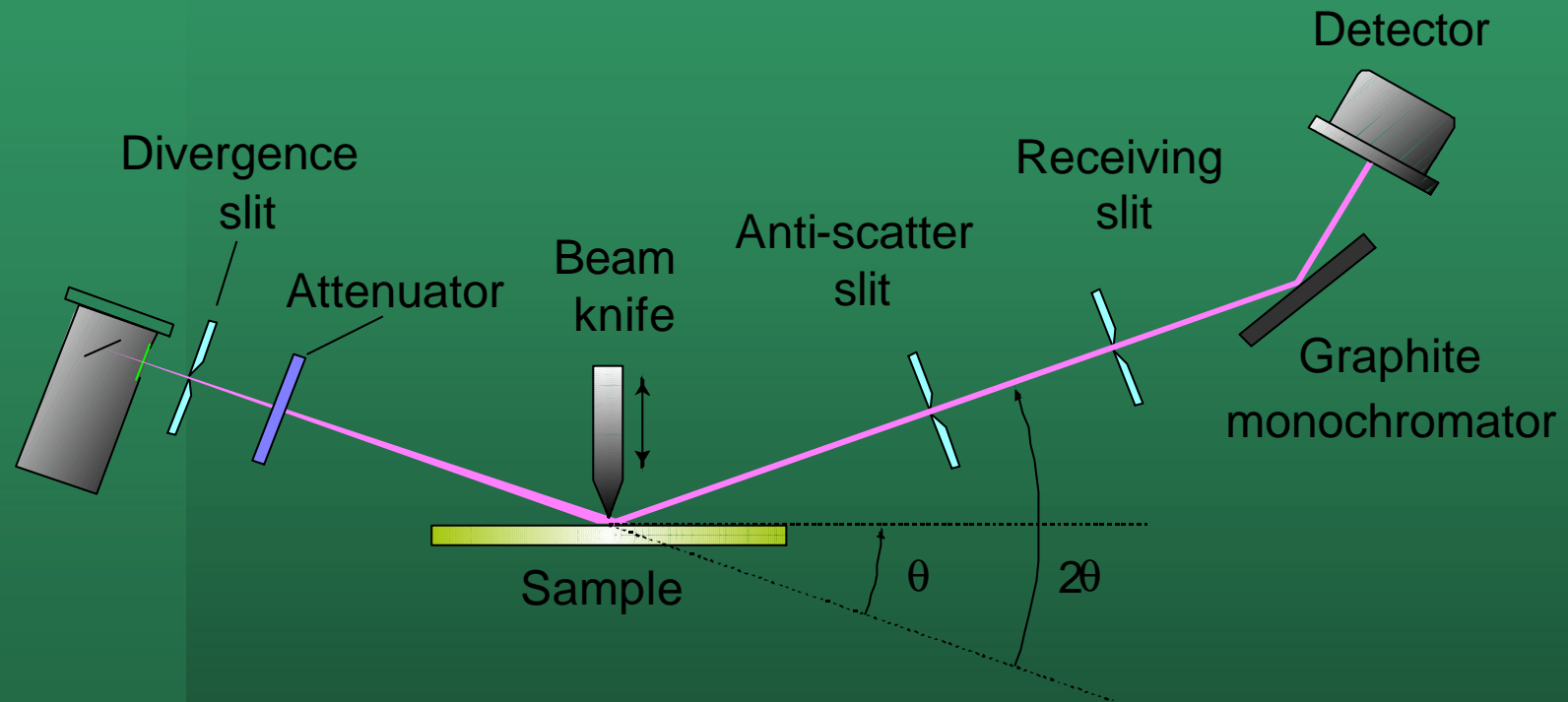
- Nano-layers
- Nano-structures
- In-plane properties

High Resolution Diffraction

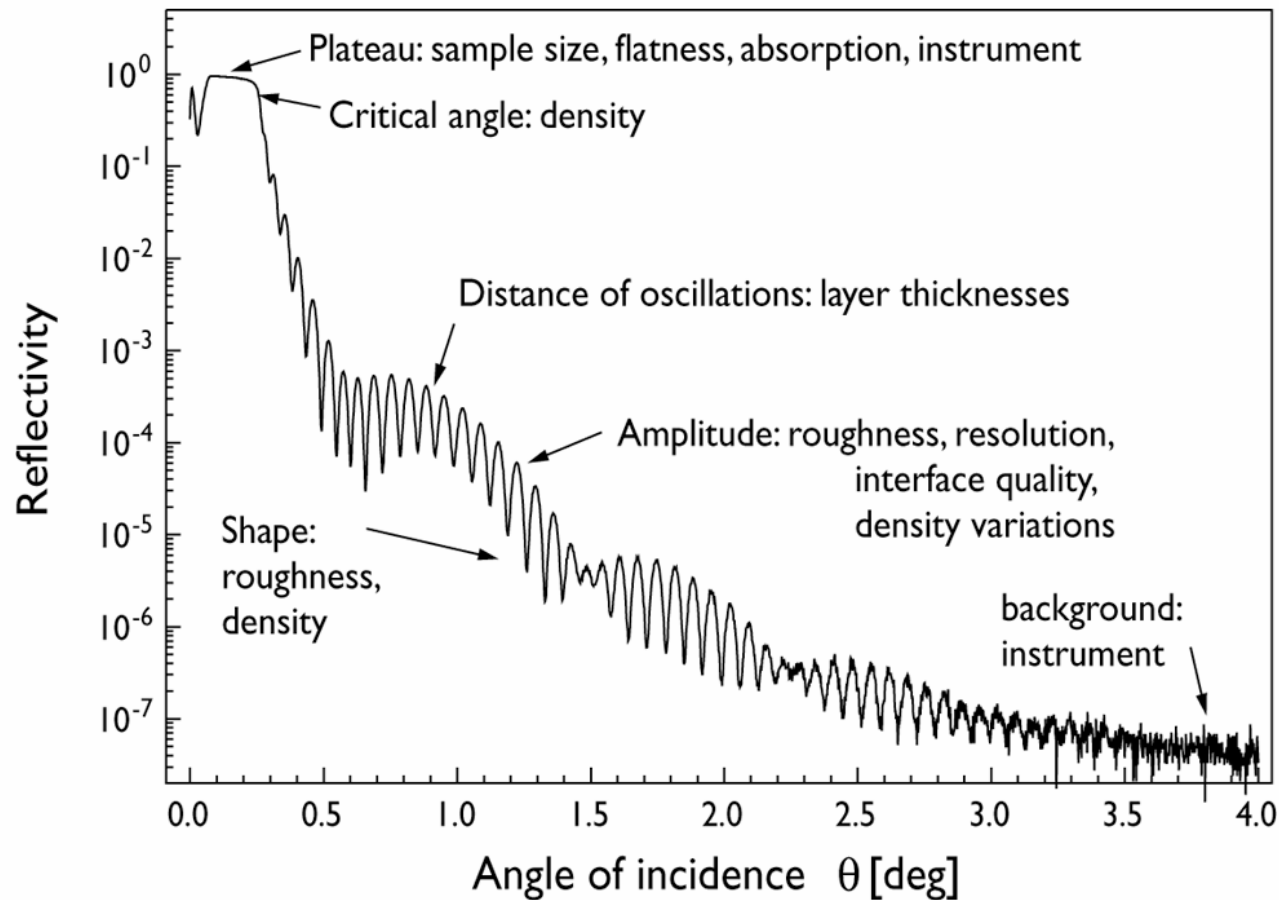
- Orientation
- Quality of Epitaxy, Lattice Mismatch
- Phase Composition
- Thickness, Density, Surface Roughness
- Residual macrostress
- Microstructure



Typical Setup for Reflectivity Measurements



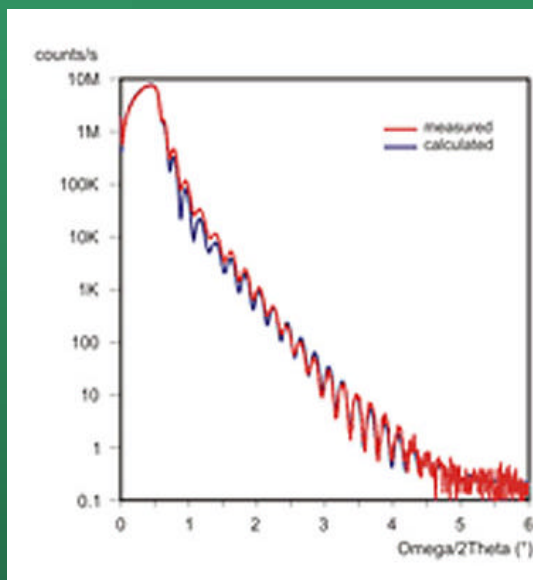
Information from a Reflectivity Curve



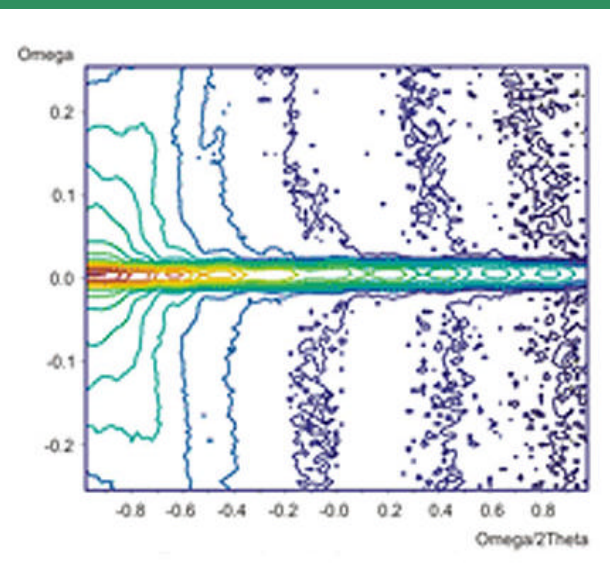
Reflectivity

XRD Study of Self-Assembled Monolayers $C_{18}H_{37}SH$ on Gold

Specular Reflectivity Curve



Reflectivity Map, Diffuse Scattering



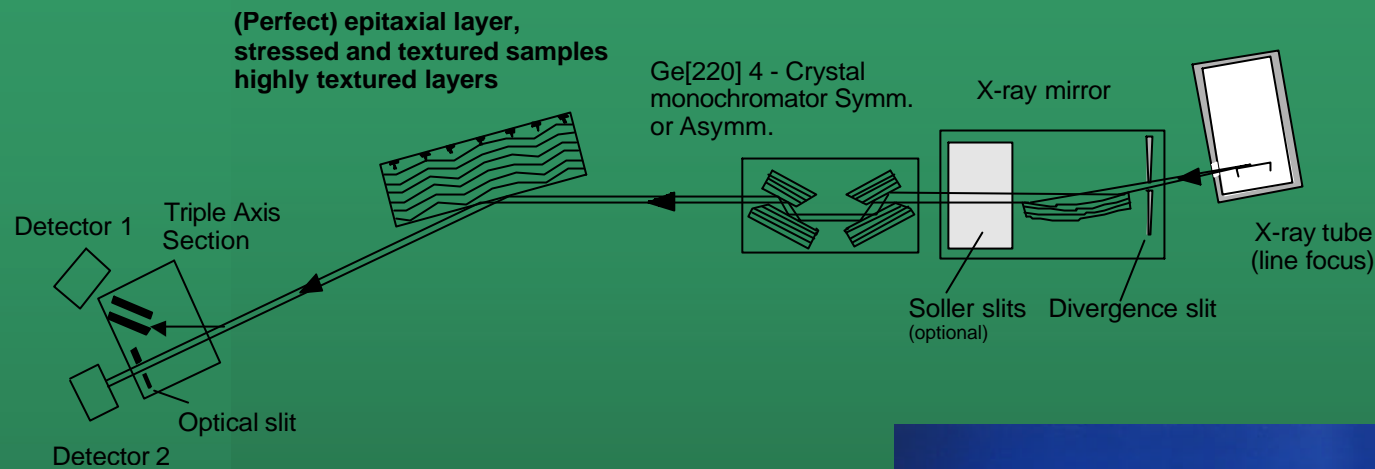
Determined thickness of the layers:

$C_{18}H_{37}SH$	- 1.6nm
Au1	- 0.6nm
Au2	- 19.0nm
Si	> 100000nm

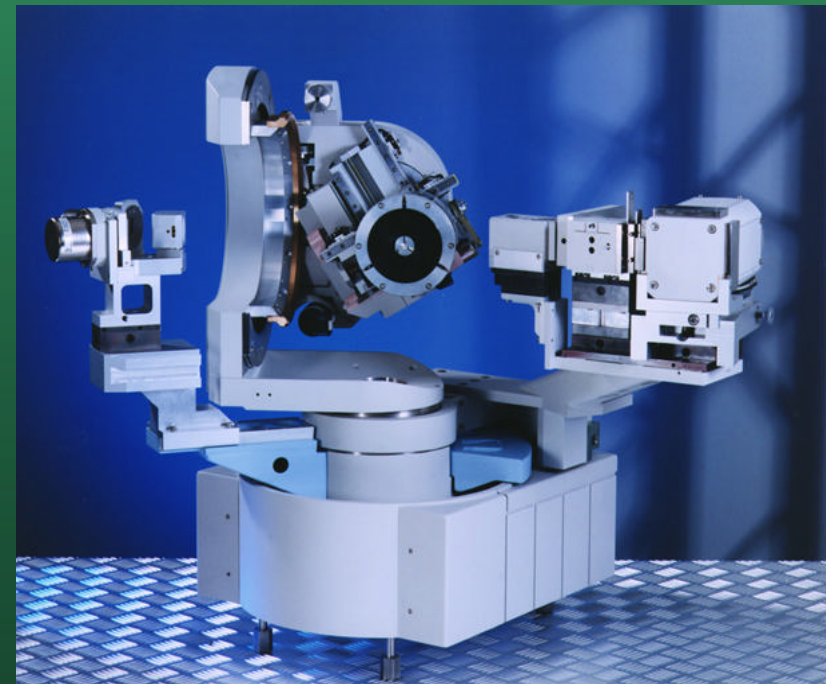
Determined Average Lateral Correlation Length: 2.5nm



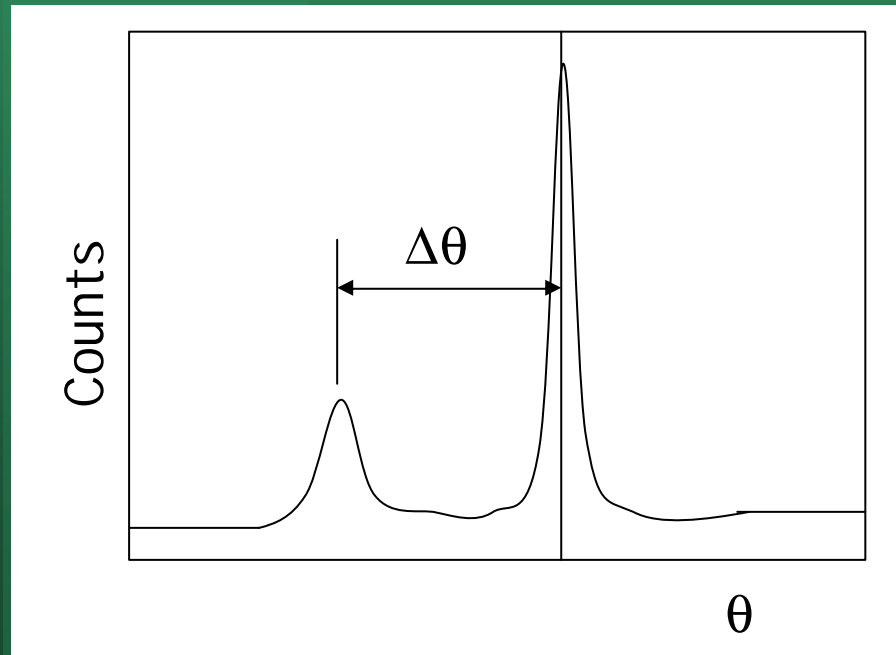
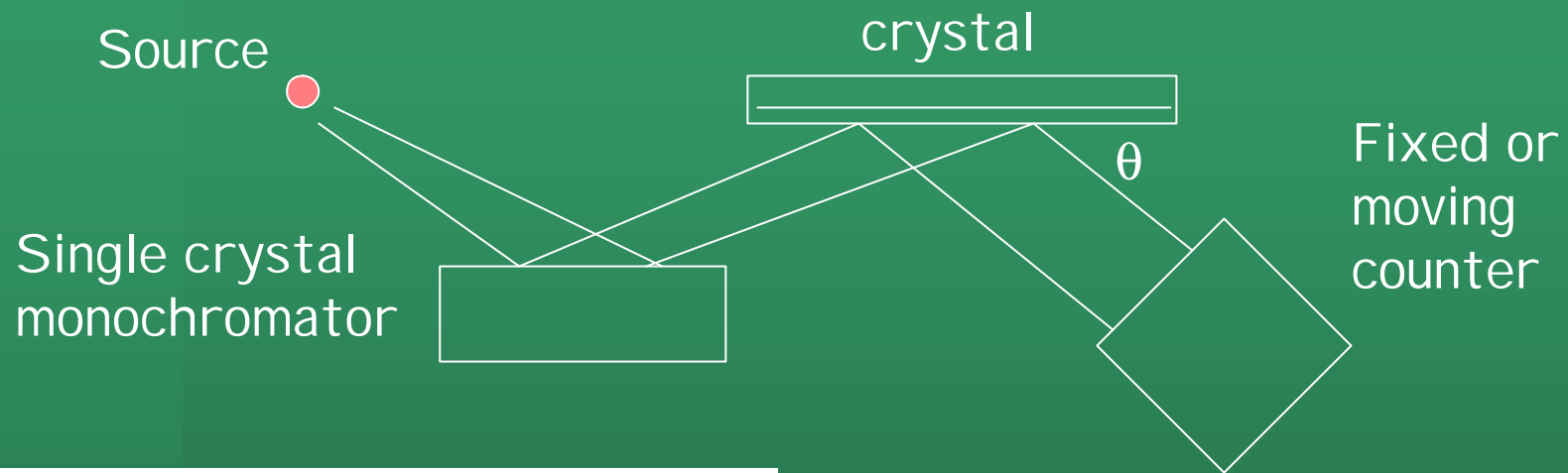
High resolution setup



The highly parallel monochromatic beam should be used to study perfect layers



X-Ray rocking curves



$\Delta\theta$ due to different lattice constant (strains).

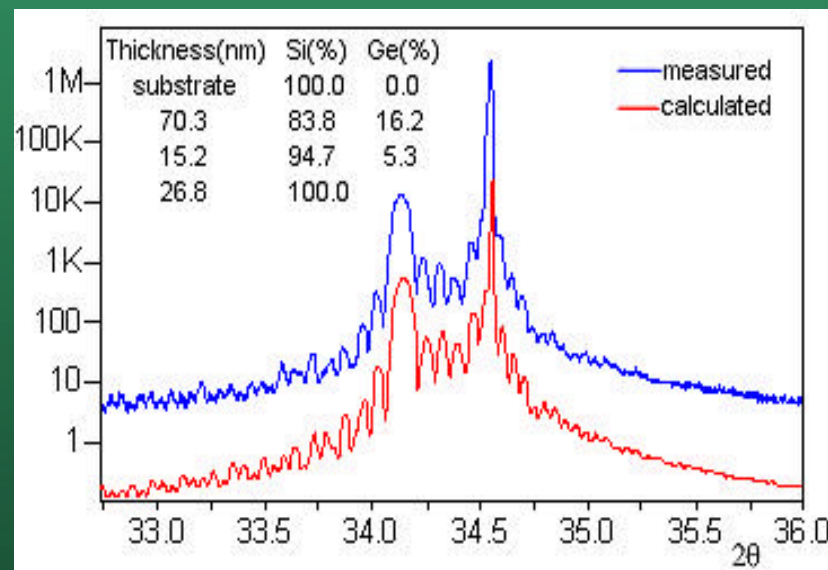
Typically used for epitaxial film study. Principle is the same as θ - 2θ diffractometer.



X-ray Rocking curves

Analysis of SiGe HBT Structure

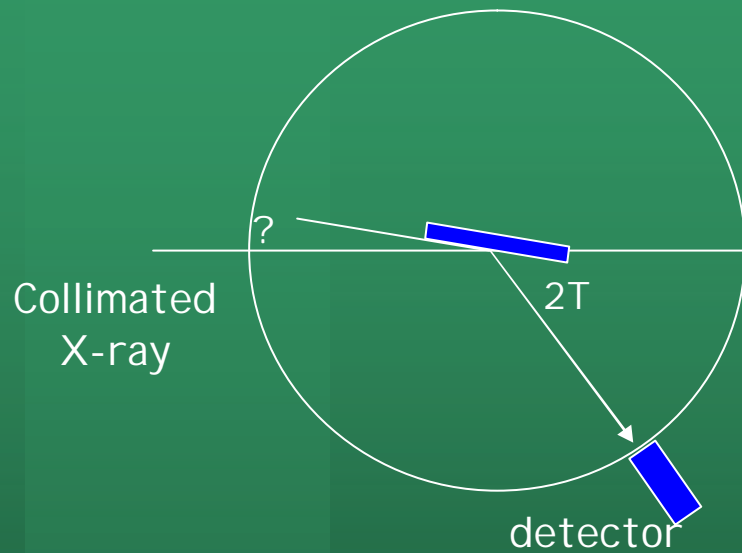
The introduction of a SiGe epitaxial layer in the bipolar transistor (HBT) brings significant gains in speed, challenging GaAs in its traditional application fields. New technological step of introducing Ge requires also an accurate method for the characterization of Ge content and gradients.



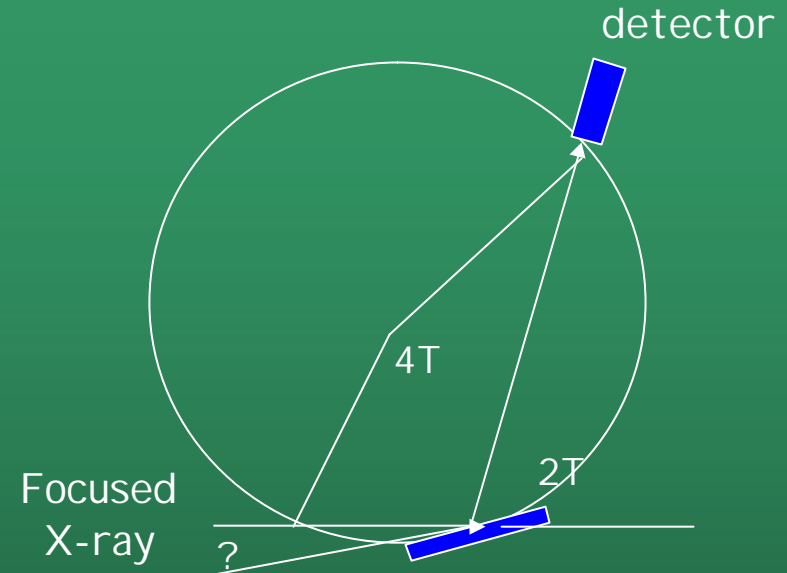
Automatic simulation and refinement of a measured rocking curve helps to identify parameters of individual layers. Method delivers 1 % accuracy for composition and 3 % accuracy for SiGe thickness.



Grazing Incidence XRD (GI XRD)



Bragg-Brentano diffractometer



Seemann-Bohlin diffractometer

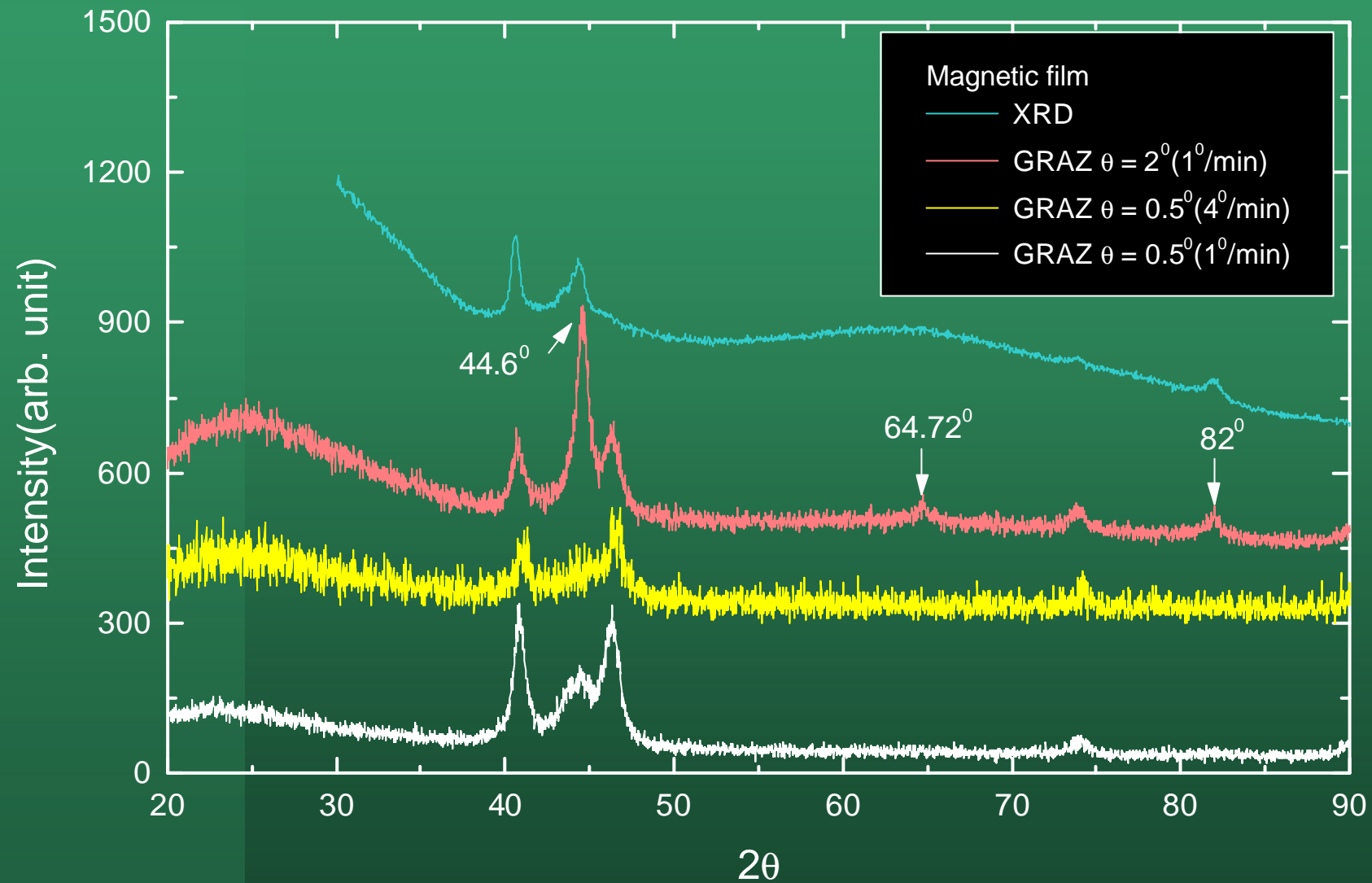
By varying γ



rough idea of the phase distribution,
microstructure or development of
orientation as a function of depth



GI XRD of a magnetic film



Reciprocal space mapping

Relaxed GaInAs/GaAs (224)

